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(54) IMIDAZOLYL OR IMIDAZOYLALKYL SUBSTITUTED WITH A FOUR OR FIVE MEMBERED NITROGEN CONTAINING HETEROCYCLIC RING

IMIDAZOLYL ODER IMIDAZOLYLALKYL SUBSTITUIERT MIT EINEM 4- ODER 5-GLIEDRIGEN STICKSTOFF ENTHALTENDEN HETEROZYKLISCHEN RING

IMIDAZOLYLE OU IMIDAZOLYLALKYLE SUBSTITUE PAR UN ANNEAU A QUATRE OU CINQ MEMBRES CONTENANT UN ATOME AZOTE

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(56) References cited:
EP-A- 0 197 840
US-A- 4 767 778
US-A- 4 925 851

EP 0 618 913 B1

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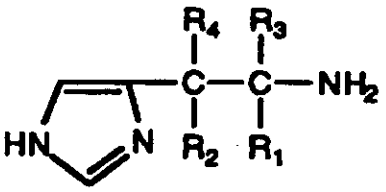
Description

BACKGROUND

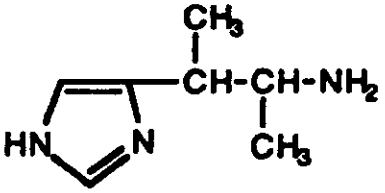
H_3 receptor sites are known and are of current interest to those skilled in the art--for example, see: West, Jr. et al., "Biexponential Kinetics of (R)-α-[^{3}H]Methylhistamine Binding to the Rat Brain H_3 Histamine Receptor", Journal of Neurochemistry, Vol. 55, No. 5, pp. 1612-1616, 1990; West, Jr. et al., "Identification of Two H_3-Histamine Receptor Subtypes", Molecular Pharmacology, 38:610-613; and Korte et al., "Characterization and Tissue Distribution of H_3 Histamine Receptors in Guinea Pigs by N^{α}-Methylhistamine", Biochemical and Biophysical Research Communications, Vol. 168, No. 3, pp. 979-986..

Arrang et al. in U.S. 4,767, 778 (Issued August 30, 1988) disclose a pharmaceutical composition containing a histamine derivative of the formula:

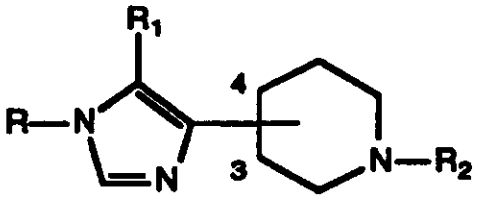


wherein each of R_1, R_2, and R_4, represents a hydrogen or a methyl, or R_1 and R_2 taken together represent a methylene, and R_3 is a hydrogen, a methyl or a carboxy, with the proviso that R_1, R_2, R_3, and R_4 are not simultaneously methyl groups. It is disclosed that the derivatives behave as complete agonists of the H_3 receptors in rat brain and produce a maximal inhibition of release identical to that induced by histamine (approximately 60%). It is also disclosed that the histamine derivatives powerfully inhibit the release and synthesis of histamine by very selectively stimulating the H_3 receptors. Consequently, according to Arrang et al., the derivatives are likely to decrease histaminergic transmission in the digestive tract and in the nervous, cardiovascular and immune systems. Arrang et al. disclose that the derivatives can be used in therapy as a drug having sedative effects, as a sleep regulator, anticonvulsant, regulator of hypothalamo-hypophyseal secretion, antidepressant, and modulator of cerebral circulation. According to Arrang et al., inhibition of the release of inflammation messengers in various allergic conditions (e.g., asthma) is expected to result from stimulation of the H_3 receptors of the lung. It is further disclosed that the inhibition of release of gastric histamine is likely to exert antisecretory and antiulcerative effects. According to Arrang et al., modification of release of the messengers of immune responses is likely to modulate the latter responses.

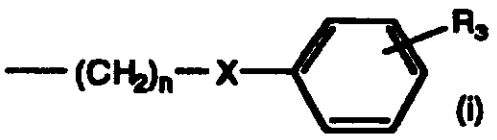
EP 0 338 939 discloses compounds of the formula:



Derwent abstract 86-273706/42 for EP 0 197 840 discloses imidazole derivatives of the formula:

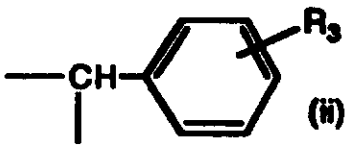


wherein R_1 is H, methyl or ethyl; R is H or R_2; and R_2 is 1-6C alkyl, piperonyl, 3-(benzimidazolon-1-yl)propyl, -CZ-NHR_5 or a group (i):



(i)

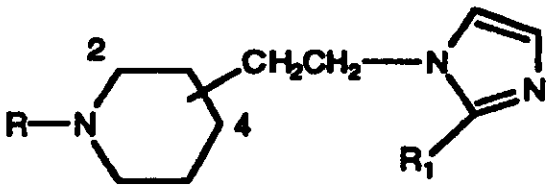
wherein n is 0-3; X is a bond, O, S, NH, CO, CH=CH or a group (ii):



(ii)

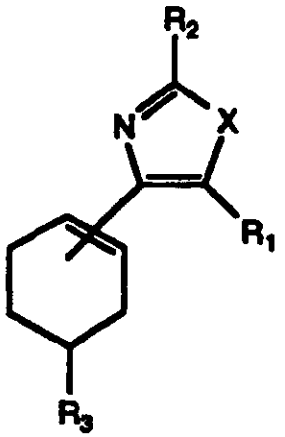
R_3 is H, methyl, halo, CN, CF_3 or COR_4; R_4 is 1-6C alkyl, 3-6C cycloalkyl or phenyl (optionally substituted by methyl or F); Z is O, S, NH, N-methyl or N-CN; and R_5 is 1-8C alkyl, 3-6C cycloakyl (optionally substituted by phenyl), 3-6C cycloalkyl(1-3C)alkyl, phenyl (optionally substituted by methyl, halo or CF_3), phenyl(1-3C)alkyl, naphthyl, adamantyl or p-toluenesulphonyl. It is disclosed that these compounds are psychotropic agents. It is also disclosed that these compounds antagonise the histamine H3 receptors and increase the speed of cerebral histamine renewal.

Derwent abstract 90-184730/24 for U.S. 4,925,851 discloses 2- or 4-(2-(1H-imidazol-1-yl)ethyl) piperidine compounds useful as antitumour agents for inhibiting lymphoma, sarcoma, myeloma and leukaemia. The compounds have the formula:



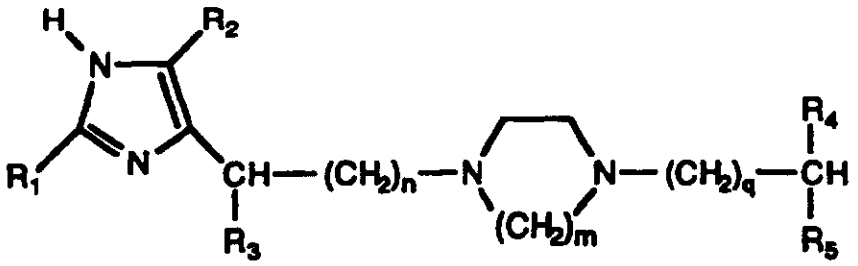
wherein R is $-CH_2(CH_2)_m$-Me, -CO-$(CH_2)_m$-Me or -CO-CMe_2-R_2; m is 2-18; R_2 is H or Me; R_1 is $-(CH_2)_n$-R_3; n is 0-13; R_3 is H, i-Pr or t-Bu; and the floating group is at the 2- or 4- position; with the proviso that (1) the sum of C atoms in R_1 does not exceed 13; and (2) the sum of C atoms in R and R_1 does not exceed 25.

Derwent abstract 90-180087/24 for EP 372125A discloses compounds of the formula:



wherein X is O or S; R_1 is halo, CF_3, CN, NO_2, OH, or 1-6C alkoxy; R_2 is H, 1-6C alkyl, aryl, 7-13C aralkyl, optionally substituted amino or 5- or 6-membered N-containing ring; and R_3 is 1-6C hydrocarbyl, 7-13C aralkyl or 1-13C acyl. It is disclosed that these compounds have alpha2-antagonist activity with no dopamine activity and that they are useful for treating depression and other related illnesses (e.g., anxiety or cognitive disorders).

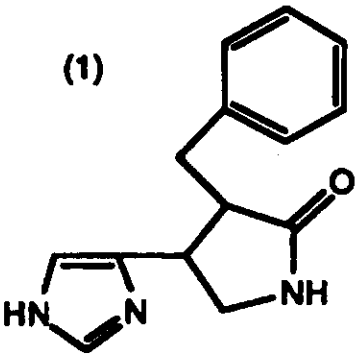
Derwent abstract 88-309195/44 for U.S. 4935417 discloses compounds of the formula:



wherein (according to U.S. 4935417) R^1 is aryl, lower alkyl, cycloalkyl or hydrogen; R^2 is aryl, lower alkyl or hydrogen; R^3 is lower alkyl, hydroxy or hydrogen; R^4 is aryl or hydrogen; R^5 is aryl or hydrogen; m is two or three; n is zero, one or two, provided that when R^3 is hydroxy, n is one or two; and q is zero, one, two or three. U.S. 4935417 discloses that these compounds are calcium channel antagonists useful for treating mammals having a variety of disease states, such as stroke, epilipsy, hypertension, angina, migraine, arrhythmia, thrombosis, embolism and also for treatment of spinal injuries.

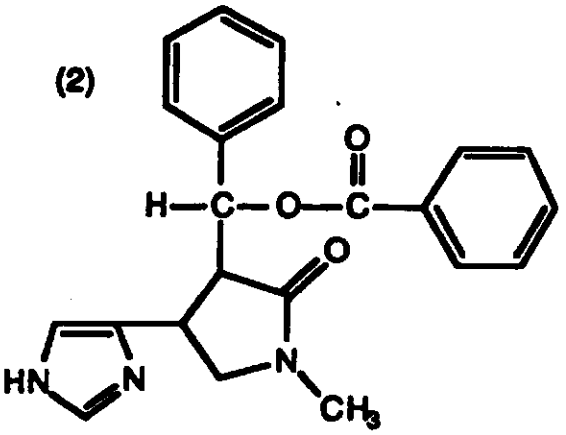
Compounds known in the art include:

(1)



RN 85651-90-7
CA98(23):194919y

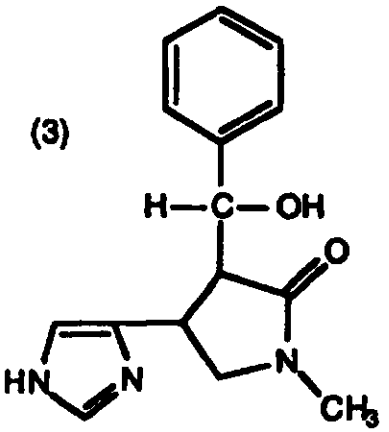
(2)



RN 81345-39-3
CA96(17):139642m

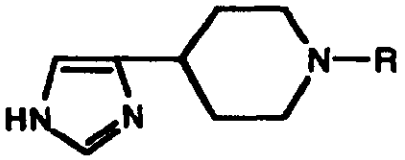
and

(3)



RN 81345-38-2
CA96(17):139642m

Known compounds in the art also include compounds of the formula:



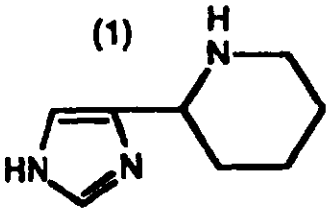
wherein R (Table 1) is:

TABLE 1

NO.	R	RN	CA
1	$-CH_3$	106243-44-1	106(11):84602r
2	$-CH(CH_3)_2$	106243-45-2	106(11):84602r
3	H	106243-23-6	106(11):84602r
4	$-C(S)NHC(CH_3)_2CH_2C(CH_3)$	106243-93-0	106(11):84602r
5	-C(O)NHCH(CH_3)(phenyl)	106243-90-7	---
6	-C(S)NH(p-chlorophenyl)	106243-85-0	---
7	-C(O)NH(phenyl)	106243-77-0	---
8	$-C(NH)N(CH_3)$(cyclopropyl)	106243-73-6	---
9	$-C(S)NHCH_3$	106243-61-2	---
10	$-CH_2CH_2$-phenyl	106243-49-6	---
11	$-CH_2CH_2$-p-fluorophenyl	106243-67-8	---
12	benzyl	106243-25-8	---

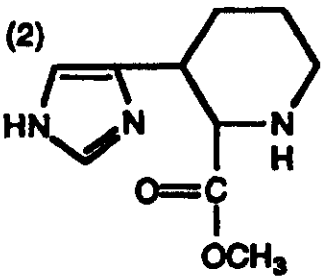
Additionally known compounds include:

(1)



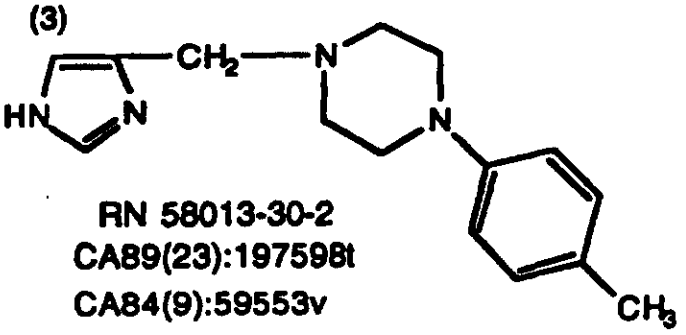
RN 51746-84-0
CA80(15):82601a

(2)



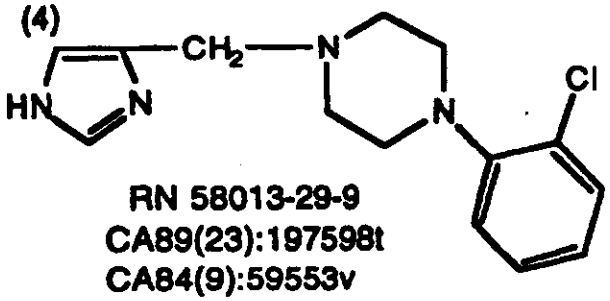
RN 67319-35-1
CA89(13):109229v

(3)



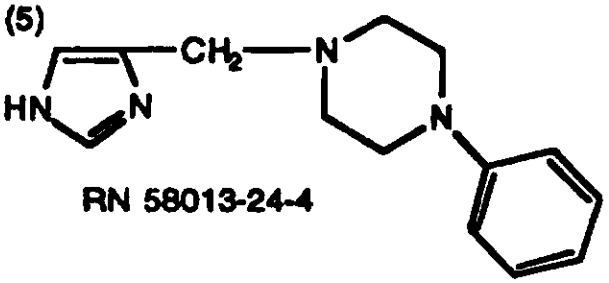
RN 58013-30-2
CA89(23):197598t
CA84(9):59553v

(4)



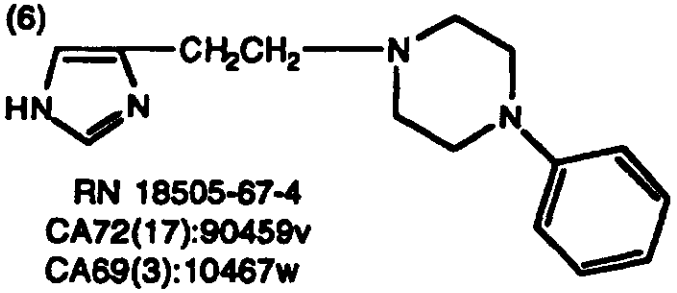
RN 58013-29-9
CA89(23):197598t
CA84(9):59553v

(5)



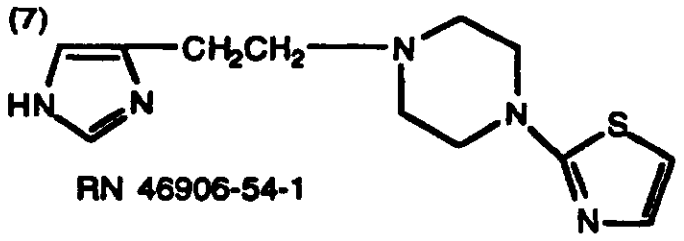
RN 58013-24-4

(6)



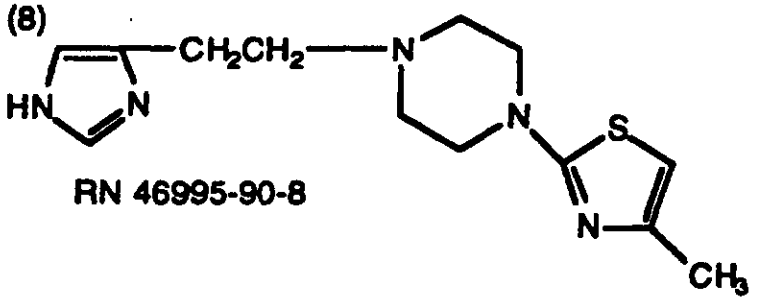
RN 18505-67-4
CA72(17):90459v
CA69(3):10467w

(7)



RN 46906-54-1

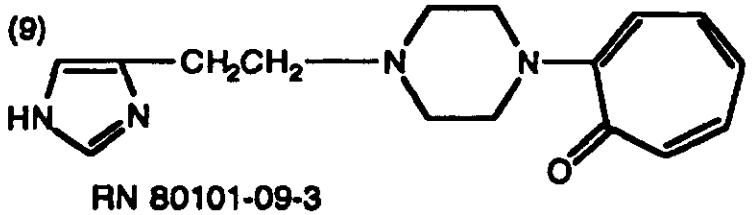
(8)



RN 46995-90-8

and

(9)

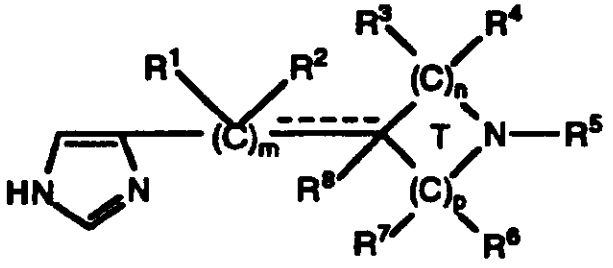


RN 80101-09-3
CA96(1):6760b

In view of the art's interest in compounds which effect the H_3 receptors, novel compounds having agonist or antagonist activity on H_3 receptors would be a welcome contribution to the art. This invention provides just such a contribution by providing novel compounds having H_3 agonist or antagonist activity.

SUMMARY OF THE INVENTION

This invention provides compounds of the formula:



(I)

or a pharmaceutically acceptable salt or solvate thereof, wherein:

(A) m is an integer selected from the group consisting of: 0, 1, and 2;
(B) n and p are integers and are each independently selected from the group consisting of : 0, 1, 2, and 3 such that the sum of n and p is 2 or 3 such that when the sum of n and p is 2, T is a 4-membered ring and when the sum of n and p is 3, T is a 5-membered ring;

(C) each R^1, R^2, R^3, R^4, R^6, R^7, and R^8 is independently selected from the group consisting of:

(1) H;
(2) C_1 to C_6 alkyl;
(3) C_3 to C_6 cycloalkyl; and
(4) $-(CH_2)_q-R^9$ wherein q is an integer of: 1 to 7, and R^9 is selected from the group consisting of: phenyl, substituted phenyl, $-OR^{10}$, $-C(O)OR^{10}$, $-C(O)R^{10}$, $-OC(O)R^{10}$, $-C(O)NR^{10}R^{11}$, CN and $-SR^{10}$ wherein R^{10} and R^{11} are as defined below, and wherein the substituents on said substituted phenyl are each independently selected from the group consisting of: -OH, $-O-(C_1$ to $C_6)$alkyl, halogen, C_1 to C_6 alkyl, $-CF_3$, -CN, and $-NO_2$, and wherein said substituted phenyl contains from 1 to 3 substituents; examples of $-(CH_2)_q-R^9$ include benzyl, substituted benzyl and the like, wherein the substituents on the substituted benzyl are as defined above for said substituted phenyl;

(D) R^5 is selected from the group consisting of:

(1) H;
(2) C_1 to C_{20} alkyl;
(3) C_3 to C_6 cycloalkyl;
(4) $-C(O)OR^{10'}$; wherein $R^{10'}$ is the same as R^{10} defined below except that $R^{10'}$ is not H;
(5) $-C(O)R^{10}$;
(6) $-C(O)NR^{10}R^{11}$;
(7) allyl;
(8) propargyl; and
(9) $-(CH_2)_q-R^9$, wherein q and R^9 are as defined above with the proviso that when q is 1 then R^9 is not -OH or -SH;

(E) R^{10} and R^{11} are each independently selected from the group consisting of: H, C_1 to C_6 alkyl, and C_3 to C_6 cycloalkyl; and, for the substituent $-C(O)NR^{10}R^{11}$, R^{10} and R^{11}, together with the nitrogen to which they are bound, can form a ring having 5, 6, or 7 atoms;
(F) the dotted line (------) represents a double bond that is optionally present when m is 1, and T is a 5-membered ring, and n is not 0, and p is not 0 (i.e., the nitrogen in the ring is not bound directly to the carbon atom bearing the double bond), and when said double bond is present then R^2 and R^8 are absent;
(G) when m is 2, each R^1 is the same or different substituent for each m, and each R^2 is the same or different substituent for each m;
(H) when n is 2 or 3, each R^3 is the same or different substituent for each n, and each R^4 is the same or different substituent for each n; and
(I) when p is 2 or 3, each R^6 is the same or different substituent for each p, and each R^7 is the same or different substituent for each p.

This invention also provides pharmaceutical compositions comprising a pharmaceutically acceptable carrier and an effective amount of a Compound of Formula I.

This invention further provides a method of treating allergy, (for example asthma), inflammation, hypertension, raised intraocular pressure (such as glaucoma)--i.e., a method of lowering intraocular pressure, sleeping disorders (e.g., hypersomnia, somnolence, narcolepsy and sleeplessness, such as insomnia), states of hyper and hypo motility and acidic secretion of the gastrointestinal tract, hypo and hyperactivity of the central nervous system (for example, agitation and depression) and other CNS disorders (such as Alzheimers, Schizophrenia, and migraine) comprising administering an effective amount of a compound of Formula I to a patient in need of such treatment.

DETAILED DESCRIPTION OF THE INVENTION

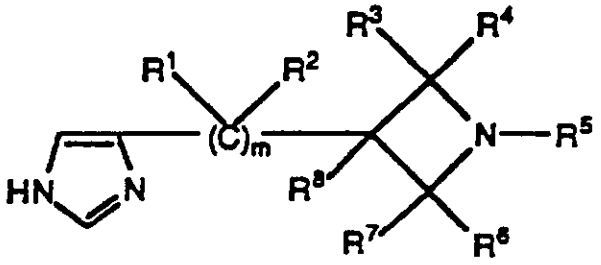
As used herein the following terms have the following meanings unless indicated otherwise:

alkyl - represents a straight or branched, saturated hydrocarbon chain having from 1 to 20 carbon atoms;
cycloalkyl - represents a saturated carbocydic ring having from 3 to 6 carbon atoms; and
halogen (halo) - represents fluoro, chloro, bromo or iodo.

Preferably, for compounds of Formula I, m is 0 or 1; R^5 is selected from the group consisting of H and C_1 to C_{20} alkyl and $(CH_2)_q-R^9$ wherein R^9 is phenyl; and R^1 to R^4 and R^6 to R^8 are each independently selected from the group

consisting of: H, C_1 to C_6 alkyl, and -$(CH_2)_q$-R^9 wherein R^9 is phenyl. Most preferably, R^5 is selected from the group consisting of H and methyl; and R^1, R^2, R^3, R^4, R^6, R^7, and R^8 are each independently selected from the group consisting of: H, methyl, ethyl, pentyl, benzyl, and 2-phenylethyl.

Representative compounds of this invention include compounds of the formula:



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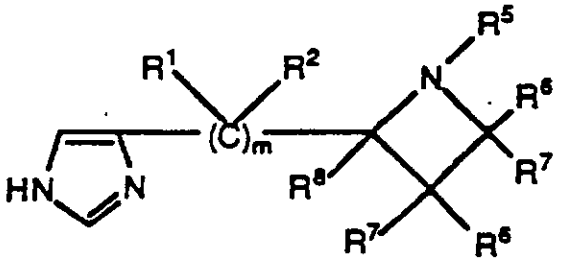

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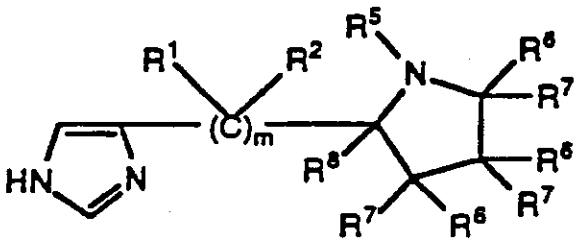

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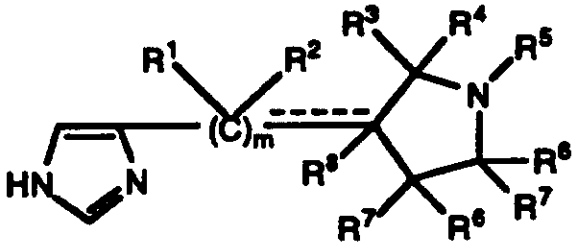
and



(IV)

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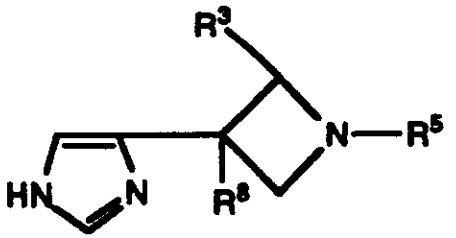
wherein m and R^1 to R^8 are as defined for Formula I.

Representative compounds of Formula II include compounds of Formulas II-1, II.2 and II-3: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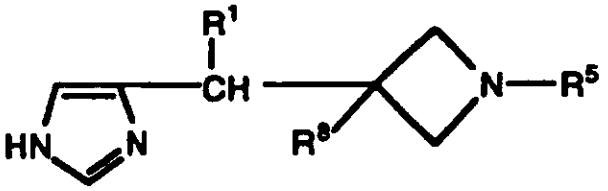
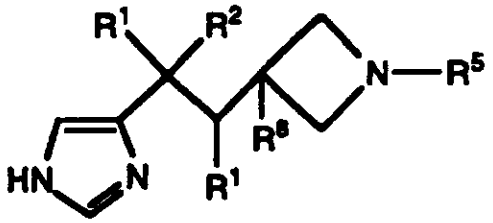

(II-2)

;

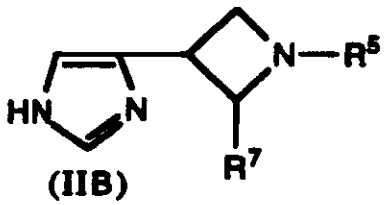
and


(II-3)

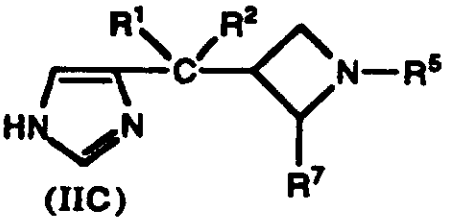
;

wherein R^1, R^2, R^3, R^5, and R^8 are as defined for Formula I.

Preferably, for compounds of Formula II, R^3, R^4, R^6, and R^8 are H. Preferred compounds of Formula II are represented by compounds of Formulas IIB and IIC:

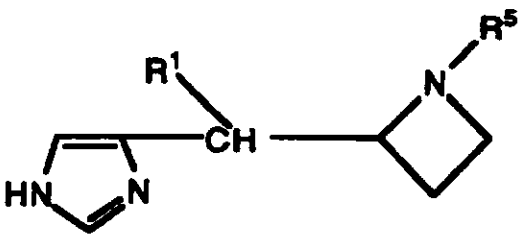

(IIB)

and


(IIC)

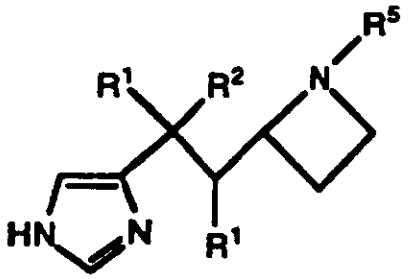
wherein R^1 and R^2 are as defined for Formula I with H being preferred, R^5 is as defined for Formula I with H and methyl being preferred and R^7 is selected from the group consisting of H, C_1 to C_6 alkyl, and $-(CH_2)_q-R^9$ wherein R^9 is phenyl. Preferably, R^7 is C_1 to C_6 alkyl, and most preferably methyl.

Representative compounds of Formula IIA include compounds of Formulas IIA-1 and IIA-2:


(IIA-1)

;

and

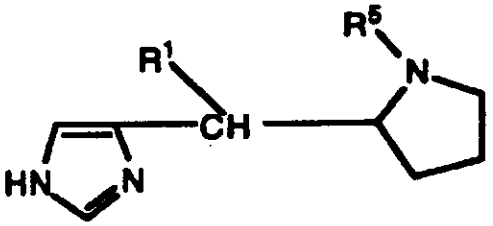


(IIA-2)

;

wherein R^1, R^2, and R^5 are as defined for Formula I.

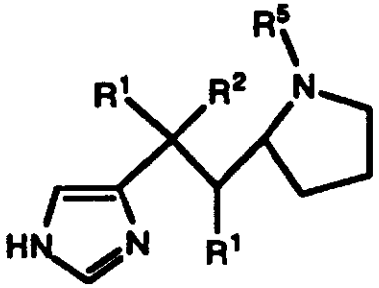
Representative compounds of Formula III include compounds of Formulas III-1 and III-2:



(III-1)

;

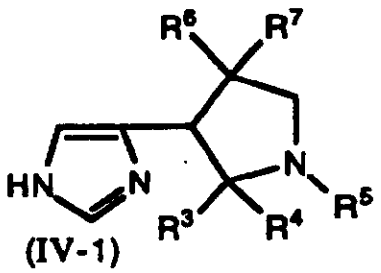
and



(III-2)

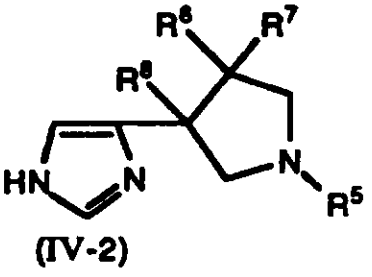
wherein R^1, R^2, and R^5 are as defined for Formula I.

Representative compounds of Formula IV include compounds of Formulas IV-1, IV-2, IV-3, IV-4, IV-5, IV-6 and IV-7:



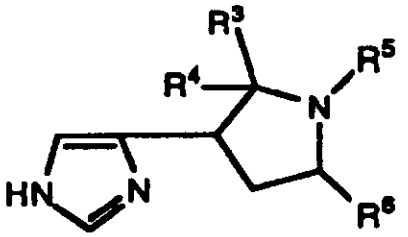
(IV-1)

;

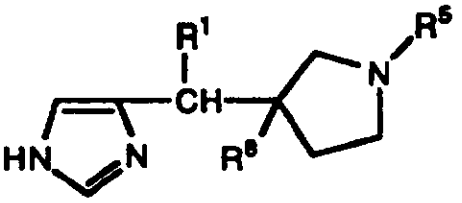


(IV-2)

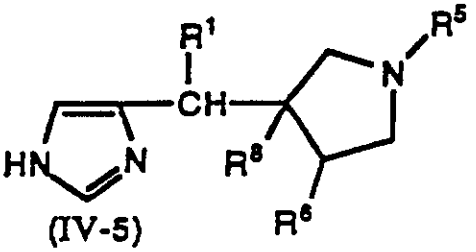
;



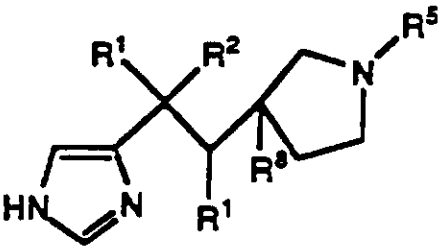
(IV-3) ;



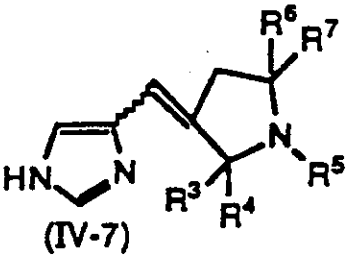
(IV-4) ;



(IV-5) ;



(IV-6) ;

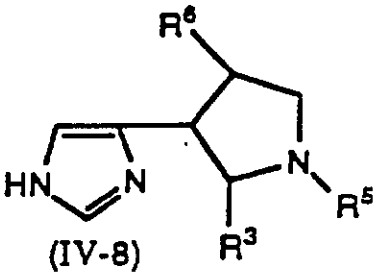


(IV-7)

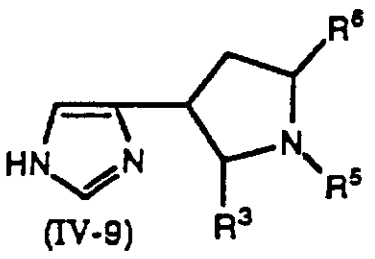
and

wherein R^1, R^2, R^3, R^4, R^5, R^6, R^7, and R^8 are as defined for Formula I.

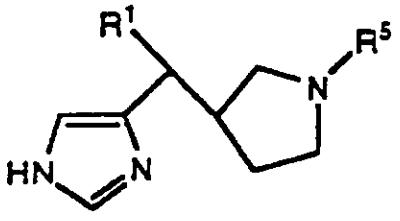
Representative compounds of Formula IV also include compounds of Formulas IV-8, IV.9, and IV-10:



(IV-8) ;



(IV-9) and

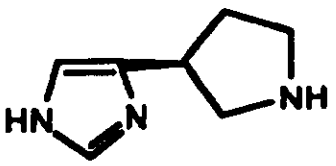


(IV-10)

wherein R^1, R^3, R^5, and R^6 are as defined for formula I, especially such compounds wherein R^5 is H or methyl, with R^1 preferably being hydrogen.

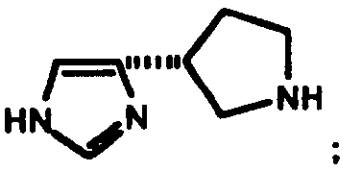
Representative compounds of Formula I include

(A1)



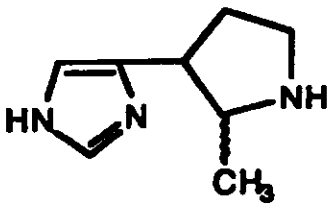
;

(A2)



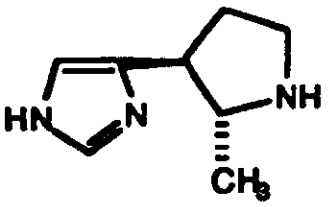
;

(B)



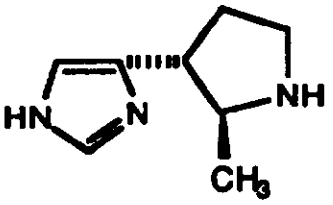
;

(B1)



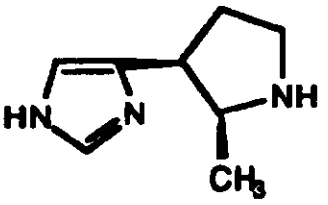
;

(B2)



;

(B3)



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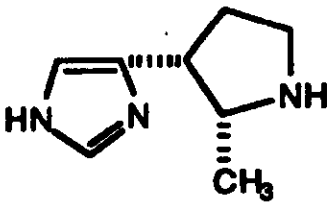
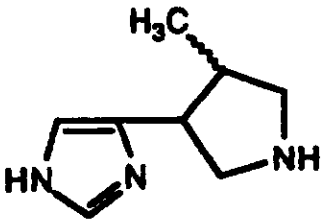
(B4)



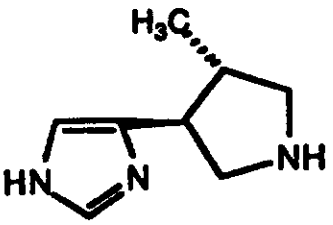
;

(C)



;

(C1)



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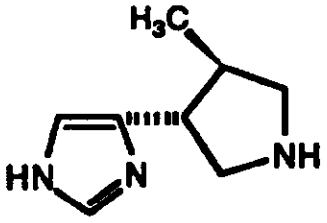
(C2)



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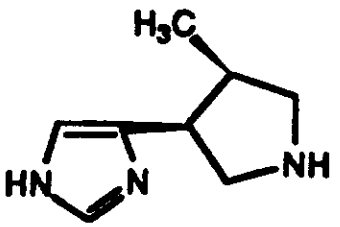
(C3)



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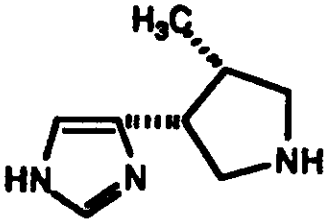
(C4)



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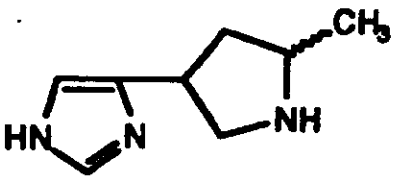
(D)



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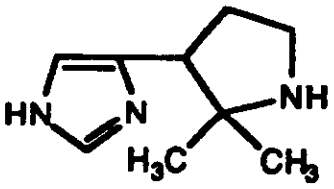
(E)



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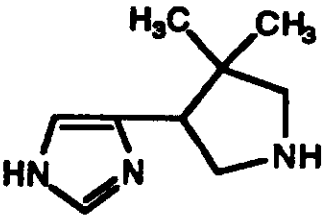
(F)



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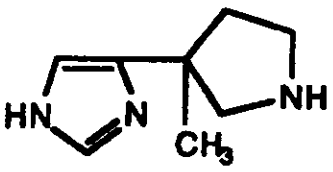
(G)



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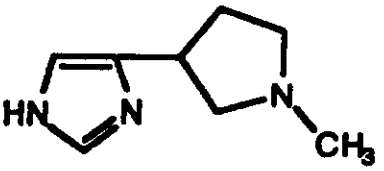
(H)



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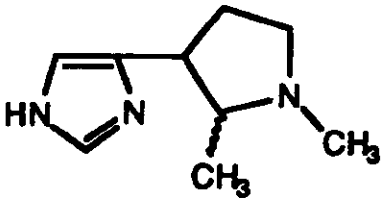
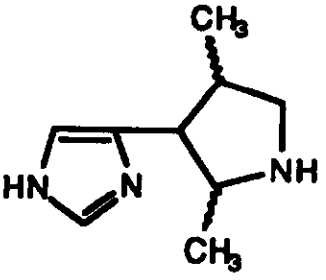
(I)



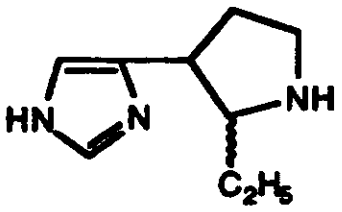
;

(J)



;

(K)



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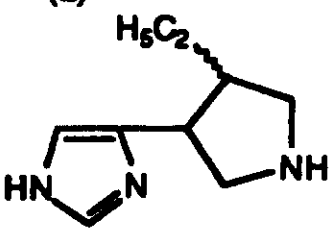
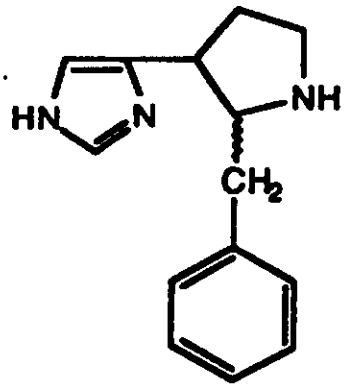
(L)



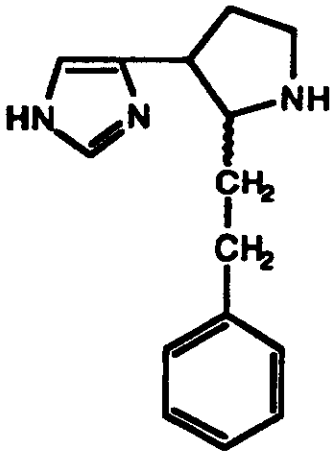
;

(M)



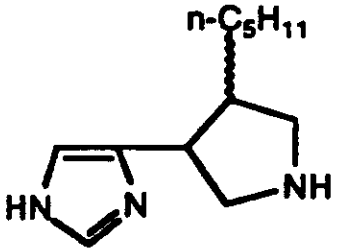
;

(N)



;

(O)



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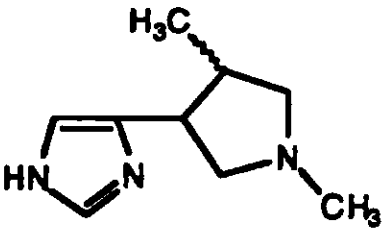
(P)



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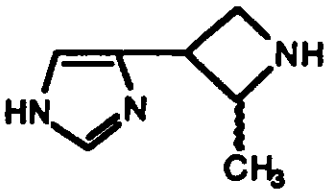
(Q)



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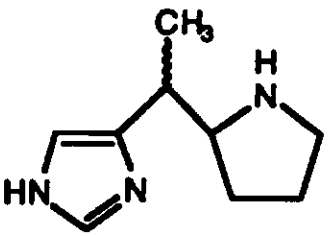
(R)



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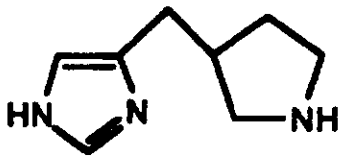
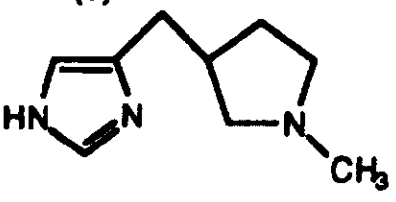
(S)



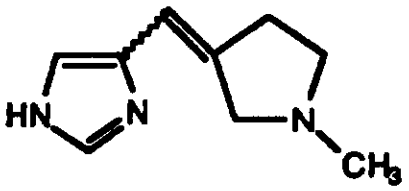
;

(T)



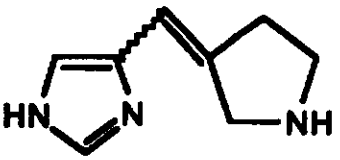
;

(U)



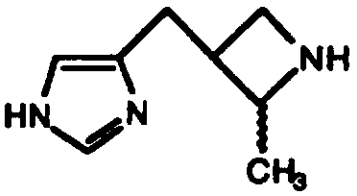
;

(V)



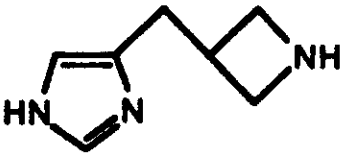
;

(W)



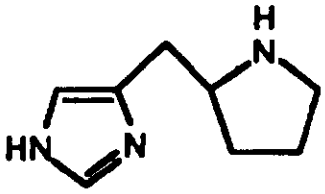
;

(X)



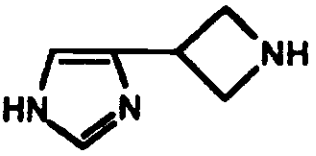
;

(Y)



; and

(Z)



.

Certain compounds of the invention may exist in different isomeric (e.g., enantiomers and diastereoisomers) forms. The invention contemplates all such isomers both in pure form and in admixture, including racemic mixtures. Enol forms are also included.

The compounds of Formula I can exist in unsolvated as well as solvated forms, including hydrated forms, e.g., hemi-hydrate. In general, the solvated forms, with pharmaceutically acceptable solvents such as water, ethanol and the like are equivalent to the unsolvated forms for purposes of the invention.

Certain compounds of the invention will be acidic in nature, e.g. those compounds which possess a carboxyl or phenolic hydroxyl group. These compounds may form pharmaceutically acceptable salts. Examples of such salts may include sodium, potassium, calcium, aluminum, gold and silver salts. Also contemplated are salts formed with pharmaceutically acceptable amines such as ammonia, alkyl amines, hydroxyalkylamines, N-methylglucamine and the like.

Certain basic compounds of the invention also form pharmaceutically acceptable salts, e.g., acid addition salts. For example, the nitrogen atoms may form salts with acids. Examples of suitable acids for salt formation are hydrochloric, sulfuric, phosphoric, acetic, citric, oxalic, malonic, salicylic, malic, fumaric, succinic, ascorbic, maleic, methanesulfonic and other mineral and carboxylic acids well known to those in the art. The salts are prepared by contacting the free base form with a sufficient amount of the desired acid to produce a salt in the conventional manner. The free base forms may be regenerated by treating the salt with a suitable dilute aqueous base solution such as dilute aqueous sodium hydroxide, potassium carbonate, ammonia and sodium bicarbonate. The free base forms differ from their re-

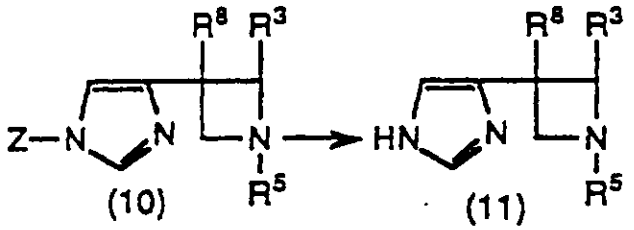
spective salt forms somewhat in certain physical properties, such as solubility in polar solvents, but the acid and base salts are otherwise equivalent to their respective free base forms for purposes of the invention.

All such acid and base salts are intended to be pharmaceutically acceptable salts within the scope of the invention and all acid and base salts are considered equivalent to the free forms of the corresponding compounds for purposes of the invention.

The following processes may be employed to produce compounds of Formula I. Unless stated otherwise, reactions are conducted at an appropriate temperature which allows the reaction to proceed at a reasonable rate to completion. Also, unless indicated otherwise, the substituent groups referred to in the following processes are as defined above for Formula I.

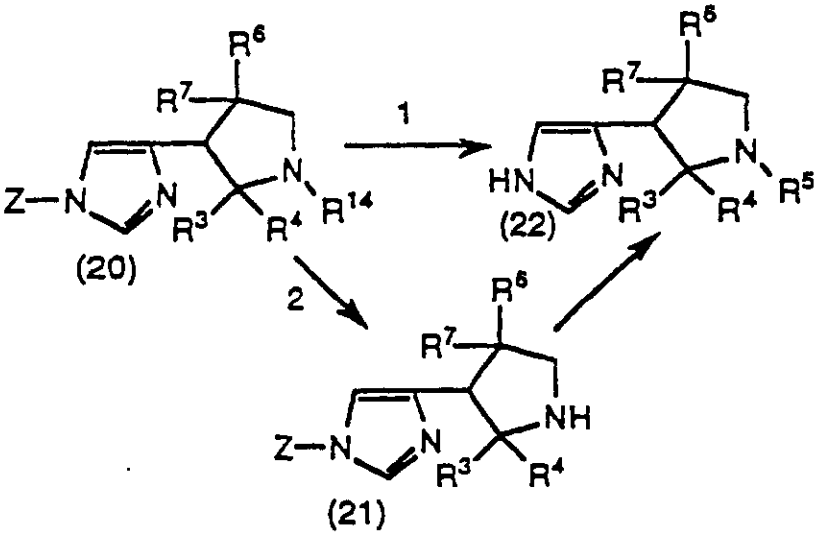
The following Processes (I) to (XI) form further aspects of the invention for producing the compounds of Formula I indicated.

(I)



1) deprotecting compound (10) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (11);

(II)



1) deprotecting compound (20) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (22), said reaction following reaction path 1 when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or

2)

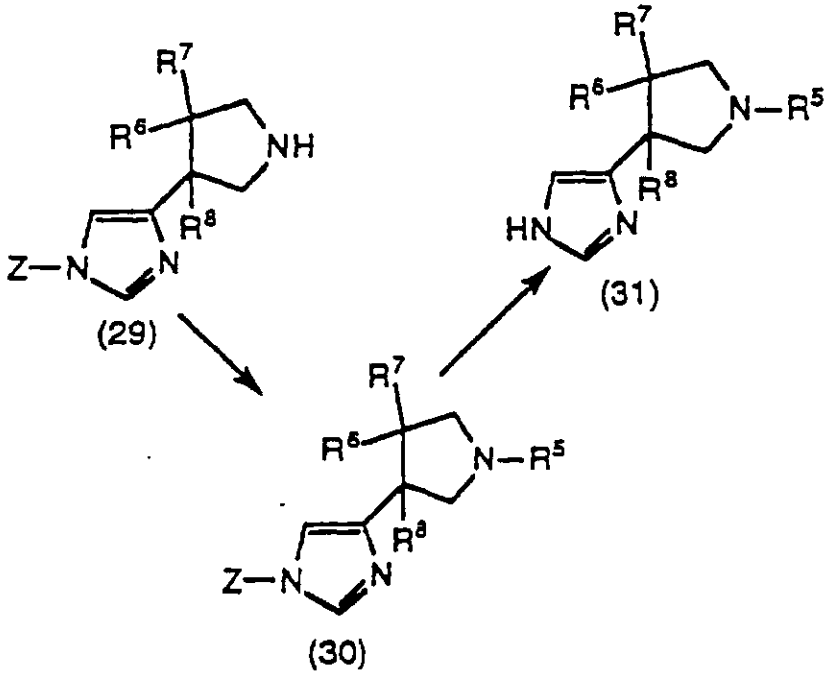
(a) treating compound (20), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C to produce compound (21); or treating compound (20), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid to produce compound (21);

(b) reacting compound (21) with (i) R^5-X when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

(c) deprotecting the compound produced in 2)(b) by treatment with dilute aqueous acid at a temperature of

25 to 90°C to produce compound (22);

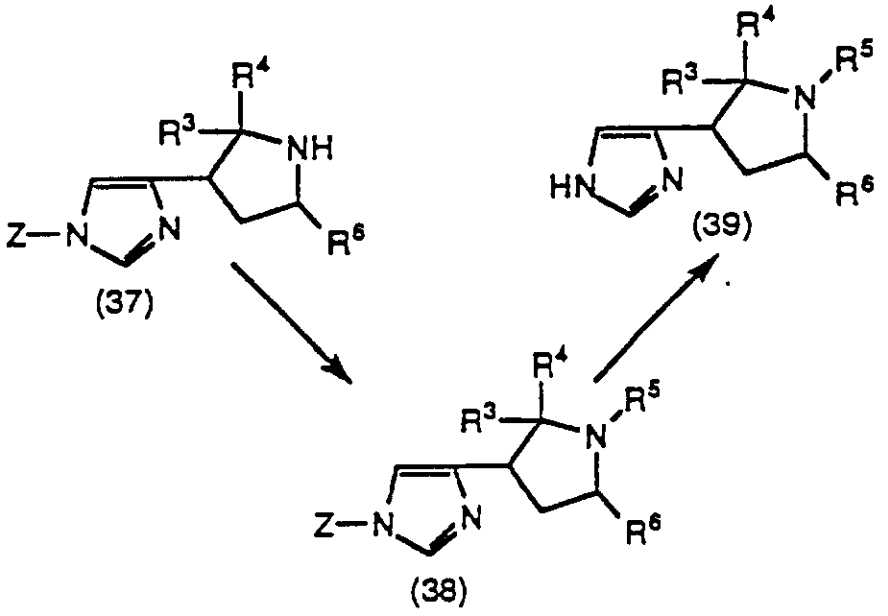
(III)



1) reacting compound (29) with (i) R^5-X,when R^5 is -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C, to produce compound (30); and

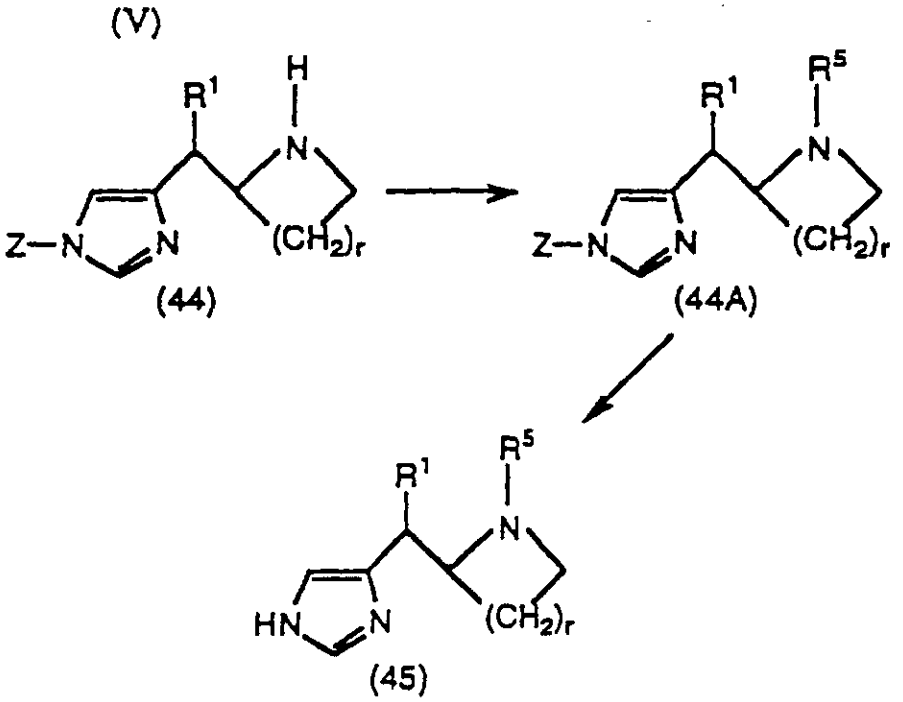
2) deprotecting compound (30) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (31);

(IV)



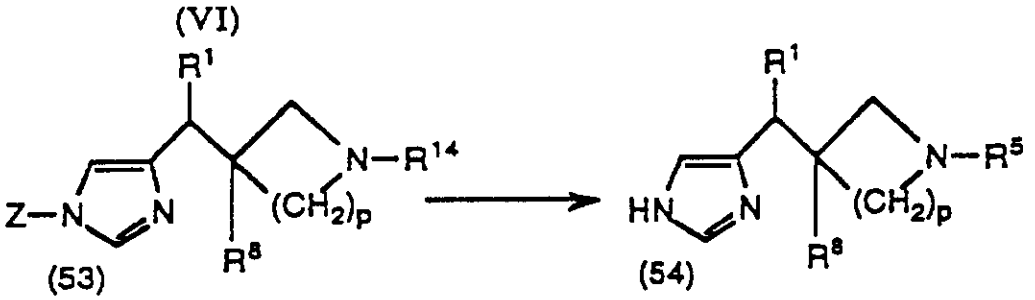
1) reacting compound (37) with (i) R^5-X ,when R^5 is -(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C, to produce compound (38); and

2) deprotecting compound (38) by treatment with dilute aqueous acid at a temperature of 25 to 100°C to produce compound (39);



1) reacting compound (44), wherein r is 1 or 2, with (i) R^5-X, when R^5 is -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C, to produce compound (44A); and

2) deprotecting compound (44A) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (45);



1) deprotecting compound (53), wherein p is 1 or 2, by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (54), said reaction being used when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or

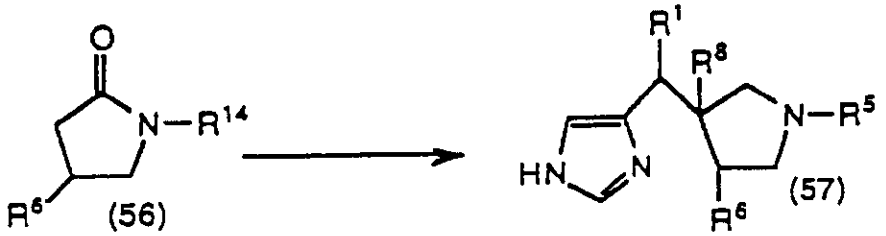
2)

(a) treating compound (53), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C; or treating compound (53), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid;

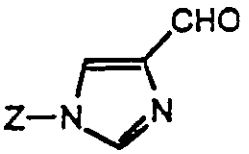
(b) reacting the compound produced in 2)(a) with (i) R^5-X ,when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a sutable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

(c) deprotecting the compound produced in 2)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (54);

(VII)



1) preparing the anion of compound (56) by reacting compound (56) with a suitable base at a temperature of -20 to 20°C, and reacting said anion with compound (32)



(32)

in an organic solvent at a temperature of -78 to 25°C;

2) reacting the product of 1) with R^1-Q, wherein Q is Li or MgBr, in a suitable solvent containing CuCN and a Lewis acid, said reaction is conducted at a temperature of -78 to 20°C;

3) reacting the enolate of the product of 2) with R^8-L, wherein L represents a suitable leaving group, in an organic solvent, said reaction is conducted at a temperature of 0 to 50°C;

4) reducing the resulting R^8 substituted compound from 3) with $LiAlH_4$ at a temperature of 25 to 65°C in an organic solvent;

5) deprotecting the reaction product of 4) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (57), said reaction being used when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or

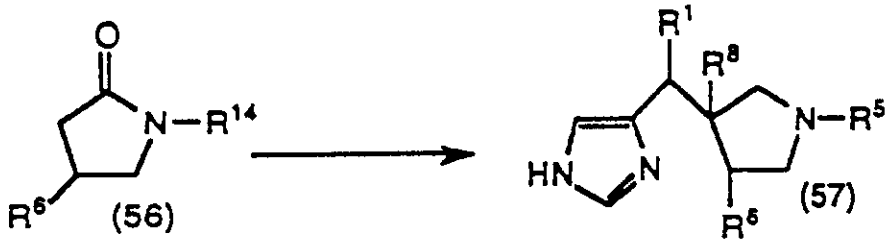
6)

(a) treating the reaction product of 4), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C; or treating the reaction product of 4), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid;

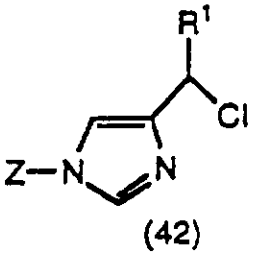
(b) reacting the compound produced in 6)(a) with (i) R^5-X, when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions. or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

(c) deprotecting the compound produced in 6)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (57);

(VIII)



1) preparing the anion of compound (56) by reacting compound (56) with a suitable base at a temperature of -20 to 20°C, and reacting said anion with compound 42



in a suitable solvent at a temperature of -78 to 25°C

2) reacting the enolate of the product of 1) with R^8-L, wherein L represents a suitable leaving group, in an organic solvent, said reaction is conducted at a temperature of 0 to 50°C;

3) reducing the resulting R^8 substituted compound from 2) with $LiAlH_4$ at a temperature of 25 to 65°C in an organic solvent;

4) deprotecting the reaction product of 3) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (57), said reaction being used when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or

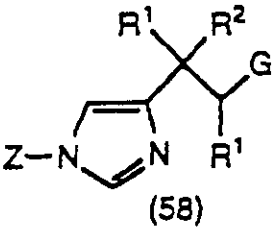
5)

(a) treating the reaction product of 3), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C; or treating the reaction product of 3), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid;

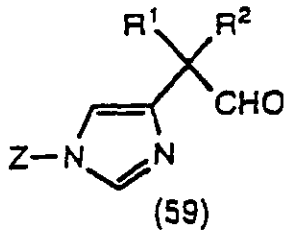
(b) reacting the compound produced in 5)(a) with (i) R^5-X ,when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

(c) deprotecting the compound produced in 5)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (57);

(IX) using compound (58):

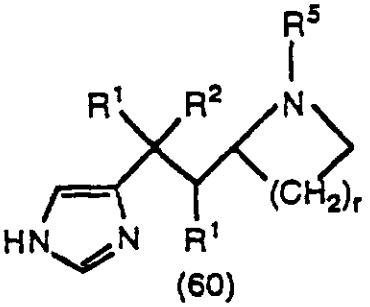


in place of compound (42) and compound (59):



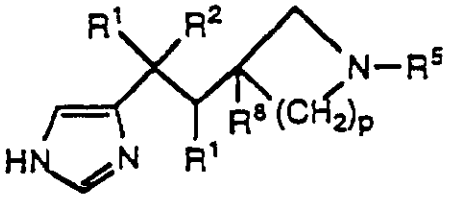
(59)

in place of compound (32) to produce compound (60):



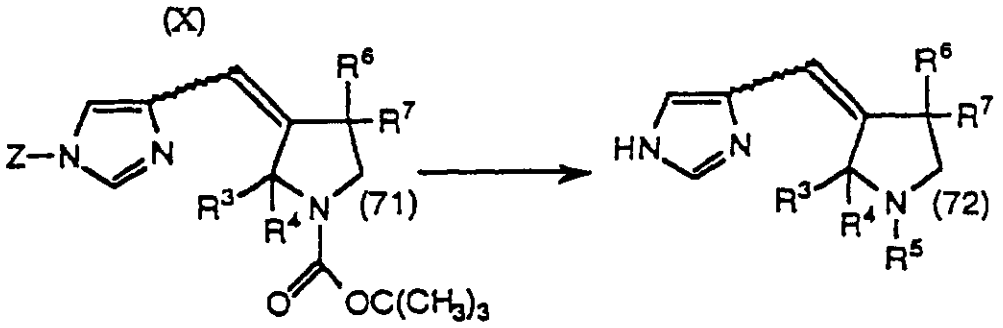
(60)

by following the steps in (V) above, or to produce compound (61)



(61)

by following the steps in (VI) above, wherein for compound (60) r is 1 or 2 and for compound (61) p is 1 or 2, and wherein G in compound (58) represents a suitable leaving group;



1) treating compound (71) with acid in an inert organic solvent at a temperature of 0°C to cause selective deprotection of the pyrrolidine ring;

2) reacting the reaction product of 1) with (i) R^5-X, when R^5 is -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

2) deprotecting the reaction product of 2) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (72); or

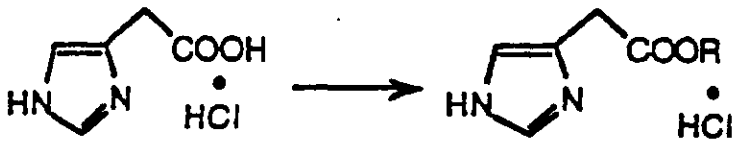
(XI) Preparing compounds of Claim 1, wherein R^5 is H, by reacting an intermediate compound of one of the above

process steps (I), (II), (III), (IV), (V), (VI), (VII), (VII), (VIII), (IX), or (X), with aqueous acid, at a temperature of 25 to 100°C, said intermediate compound having the imidazole nitrogen protected by Z and having the nitrogen of the cyclic four or five membered amine substituted with -C(O)O(t-butyl) or unsubstituted.

In greater detail, compounds of Formula I may be prepared as follows:

A. PREPARATION OF COMPOUNDS WHEREIN m is 0, n is 1 and p is 1 PRODUCING COMPOUNDS OF FORMULA II

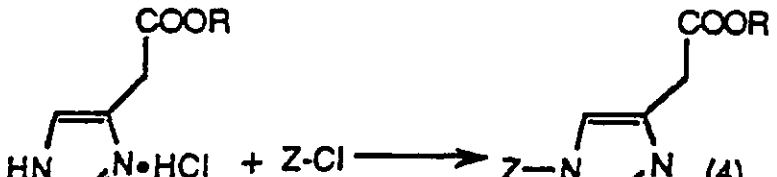
STEP 1-Preparation A:



(1) (2)

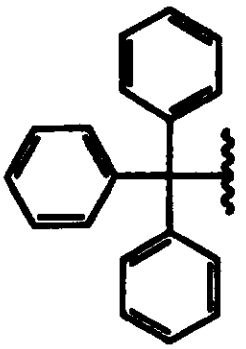
In Step 1, commercially available compound (1) is dissolved in a suitable alcohol, ROH wherein R is a lower alkyl such as a C_1 to C_6 alkyl (e.g., methyl, ethyl, isopropyl and the like), preferably methanol, containing a catalytic amount of concentrated hydrochloric acid or similar acid. The reaction mixture is heated at a temperature of about 50 to about 70°C to produce compound (2). There are many other esterification methods known in the art that may also be employed.

STEP 2-Preparation A:



(2)

In Step 2, compound (2) is reacted with compound (3) in a polar organic solvent at a temperature of about 0 to about 50°C in the presence of an organic base to produce compound (4). In compounds (3) and (4), Z represents the protecting group:

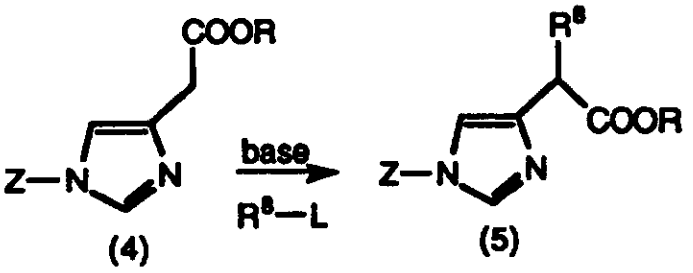


(trityl group). Z can be other protecting groups, such as 2-(trimethylsilyl)ethoxymethyl, benzyloxycarbonyl, and the like; however, unless stated otherwise, Z preferably represents the trityl group in the processes described below for making the compounds of this invention. Suitable organic solvents include: DMF (N, N-dimethylformamide), CH_2Cl_2 and the like. DMF is preferred. Preferably, triethylamine is used as the base. Other suitable bases include N,N-diisopropylethylamine and the like.

Those skilled in the art will appreciate that other protecting groups known in the art may be used--such as, for example, base sensitive groups wherein the protected compounds would be deprotected using basic conditions (e.g., NaOH). The processes described herein wherein the protected compound is deprotected under acidic conditions may

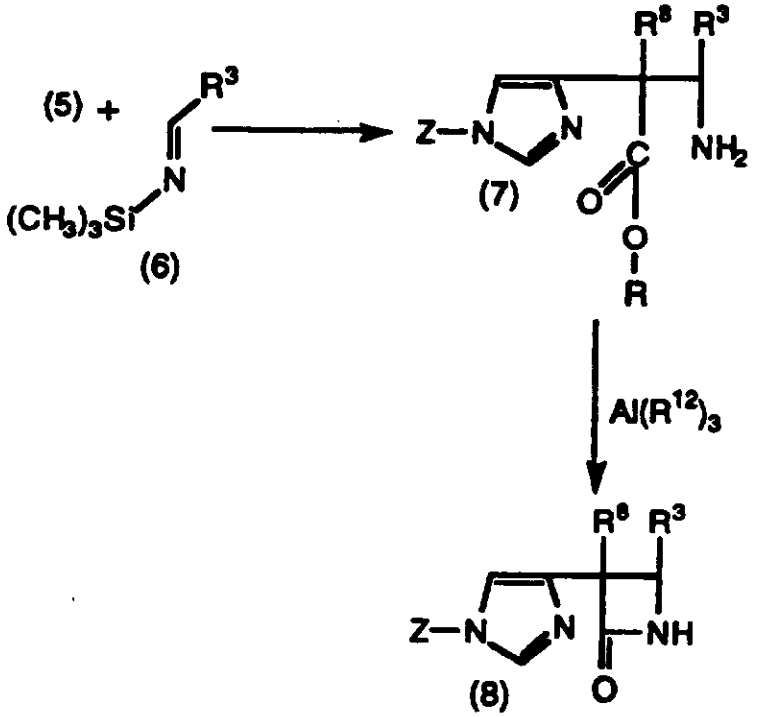
also be carried out under basic conditions when a base sensitive protecting group is used.

STEP 3-Preparation A:



In Step 3, the enolate of compound (4) reacts with R^8-L in an organic solvent to produce compound (5). The reaction is conducted at a temperature in the range of about 0 to about 50°C. L is a suitable leaving group such as Cl, Br, I and the like. Preferably, LDA (lithium diisopropylamide) is used as the organic base to form the enolate, but other suitable bases include sodium hydride and the like. Suitable organic solvents include tetrahydrofuran, 1,4-dioxane and the like. Preferably, THF (tetrahydrofuran) is used.

STEP 4-Preparation A:



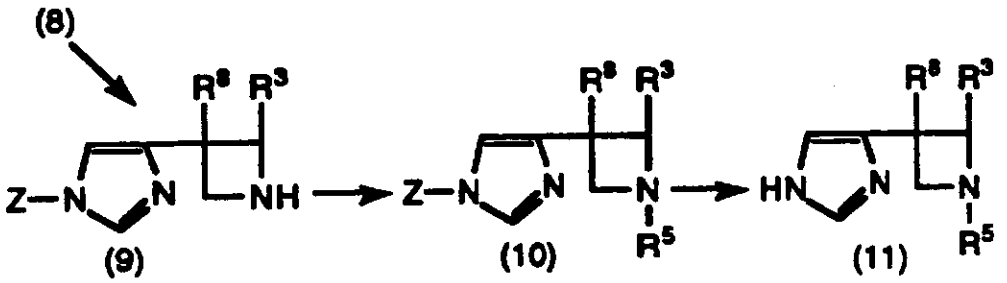
In Step 4, the enolate of compound (5) is reacted with compound (6) in an organic solvent in the presence of a Lewis acid to produce compound (7). Suitable organic solvents include tetrahydrofuran, diethyl ether, 1,4-dioxane and the like. Preferably, tetrahydrofuran or diethyl ether is used. Suitable organic bases used to generate the anion of (5) include lithium diisopropylamide, $LiN(Si(CH_3)_3)_2$, and NaH. Preferably, $LiN(Si(CH_3)_3)_2$ is used. Representative Lewis acids include $BF_3•(C_2H_5)_2O$, $(CH_3)_3SiCl$ and the like, with $BF_3•(C_2H_5)_2O$ being preferred. The reaction is conducted at a temperature within the range of about -78 to about 0°C.

Compound (7) is converted to compound (8) by reacting compound (7) with $Al(R^{12})_3$ in an organic solvent at a temperature of about 50°C. R^{12} is a suitable alkyl group such as methyl, ethyl, isopropyl, butyl, and the like. Methylene chloride is a preferred solvent for this reaction, but others, such as 1,2-dichloroethane, can be employed.

Compound (6) in Step 4 is prepared according to known in the art procedures-for example: Cainelli et al., Tetrahedron Letters, Vol. 28, No. 44, p. 5369 (1987); and Uyehara et al., Tetrahedron Letters, Vol. 30, No.32, p. 4275 (1989).

In compound (6), R^3 is as defined above.

STEPS 5, 6 AND 7-Preparation A:



In Step 5, compound (8) is reduced to compound (9). The reaction is conducted in an organic solvent at a temperature within the range of about 20 to about 70°C using a known reducing agent. Examples of suitable reducing agents include DIBALH (diisobutyl aluminum hydride) and AlH_3. Preferably tetrahydrofuran is used as the organic solvent, but other suitable solvents include 1,4-dioxane and the like.

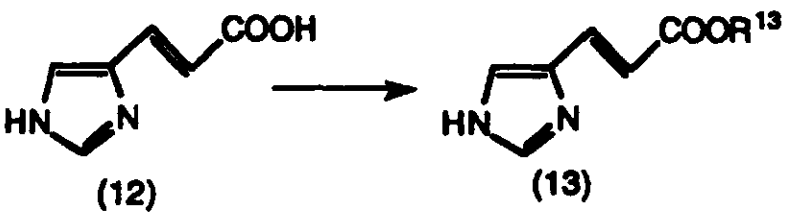
In Step 6, compound (9) is reacted with (i) R^5-X (when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl) in an organic solvent optionally in the presence of a siutable base (e.g., triethylamine); or (ii) R^{5A}-CHO (when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl) in the presence of $NaBH_3(CN)$ (sodium cyanoborohydride) or other hydrogenating conditions (e.g. H_2/Pd/ROH) in an organic solvent; to produce compound (10). R^{5A} represents an R^5 group that has one less $-CH_2-$ group. Preferably, CH_2Cl_2 is used as the solvent when R^5-X is used, and tetrahydrofuran or an alcohol is used as the solvent when R^{5A}-CHO is used. X represents a suitable leaving group such as Cl, Br, I, or $-OCH_3$. The reaction ((i) or (ii)) can be performed at a temperature within the range of about -30 to about 80°C. Compound (10), when R^5 is $-C(O)NR^{10}H$, is prepared by reacting compound (9) with $O=C=N-R^{10}$ in an organic solvent, such as CH_3CN or toluene. The reaction is performed at a temperature in the range of about 20 to about 110°C. Alternatively, compounds wherein R^5 is $-C(O)NR^{10}R^{11}$ may be made from compounds wherein R^5 is $-C(O)OR^{10'}$ by reacting such compounds with $NHR^{10}R^{11}$ in an organic solvent (e.g., THF) at a temperature of about 25 to about 100°C. Compound (9), or compound (10) wherein R^5 is -C(O)O(t-butyl), can be reacted with aqueous acid (e.g., HCl, HBr, and the like), at a temperature of about 25 to about 100°C, to produce compound (11) wherein R^5 is H.

In Step 7, compound (10) is deprotected by treatment with dilute aqueous acid, such as HCl or HBr, at a temperature of about 25 to about 90°C to produce compound (11). Other protecting groups are removed by methods well known in the art.

In all the preparations that follow, intermediate compounds wherein the imidazole nitrogen is protected by Z and the nitrogen of the cyclic four or five membered amine is substituted with -C(O)C(t-butyl) or unsubstituted, i.e., hydrogen is bound to the amine nitrogen, such as in compounds (10) or (9), respectively, such intermediate compounds can be reacted with aqueous acid (e.g., HCl, HBr, and the like), at a temperature of about 25 to about 100°C, to produce deprotected final products wherein R^5 is H, e.g., compound (11).

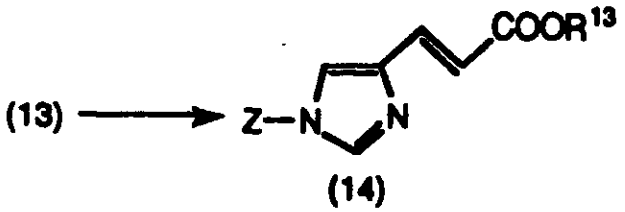
B. PREPARATION OF COMPOUNDS WHEREIN m IS 0, n is 1 and p is 2 PRODUCING COMPOUNDS OF FORMULA IV

STEP 1-Preparation B:



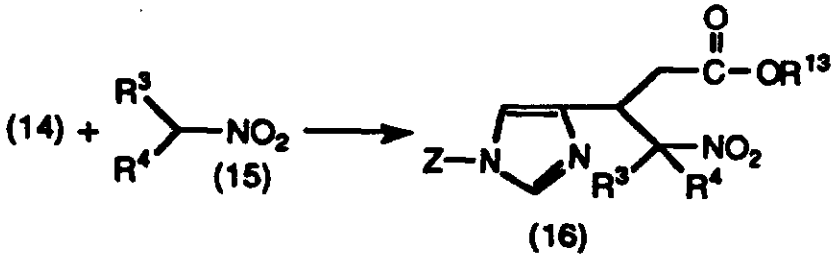
In Step 1, urocanic acid (12) is heated with a catalytic amount of concentrated sulfuric acid in a solvent $R^{13}OH$ to produce a compound (13). R^{13} is an alkyl group such as methyl, ethyl, and the like. The reaction is conducted at a temperature equivalent to the boiling point of the solvent ($R^{13}OH$), for example 65°C for methanol.

STEP 2-Preparation B:



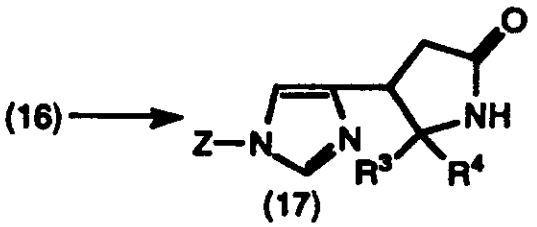
In Step 2, compound (13) is reacted with trityl chloride (see compound (3) in Preparation A above) to produce compound (14), wherein Z represents the trityl group. Other suitable compounds which provide protecting groups (Z) which can be used instead of trityl chloride include SEM (2-(trimethylsilyl)ethoxymethyl) chloride.

STEP 3-Preparation B:



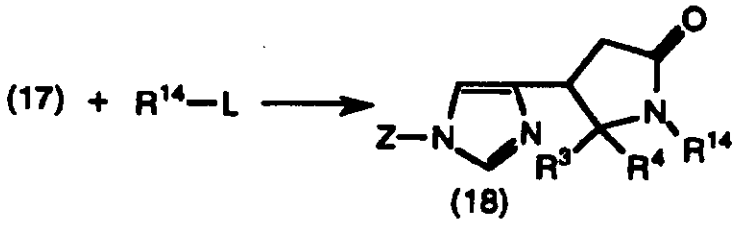
In Step 3, compound (14) (from Step 2) is reacted with compound (15) to produce compound (16). The reaction takes place at a temperature within the range of about 20 to about 100°C in an organic solvent containing an organic base. Suitable organic bases include DBU (1, 8-diazabicyclo[5.4.0]undec-7-ene), and TMG (1, 1, 3, 3-tetramethylguanidine). Suitable solvents include acetonitrile, tetrahydrofuran, N, N-dimethylformamide and the like.

STEP 4-Preparation B:



In Step 4, compound (16) (from Step 3) is hydrogenated to produce compound (17). The hydrogenation takes place in an organic solvent, using Raney-Nickel, at a temperature of about 20 to about 60°C. Preferably ethanol is used as the organic solvent. Under these conditions cyclization occurs in situ to provide the desired lactam (17).

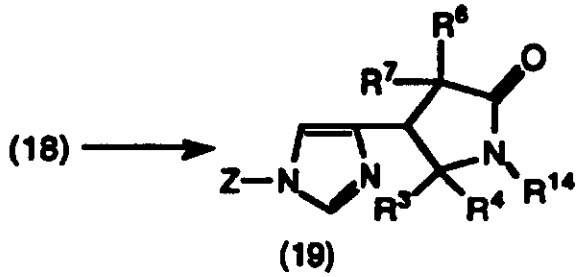
STEP 5-Preparation B:



In Step 5, the anion of compound (17) is reacted with R^{14}-L to place the R^{14} on the indicated nitrogen atom in compound (18). R^{14} can be a suitable protecting group such as $Si(CH_3)_2C(CH_3)_3$ or -C(O)O(t-butyl), or R^{14} can be an alkyl, cycloalkyl, benzyl, substitued benzyl, allyl, or propargyl group. L is a leaving group, such as Cl, Br, I or $-OSO_2CF_3$.

The reaction is conducted in an organic solvent such as THF, diethyl ether, 1,4-dioxane or DMSO in the presence of a suitable base, such as lithium diisopropylamide or NaH. The reaction takes place at a temperature within the range of about -78 to about 80°C.

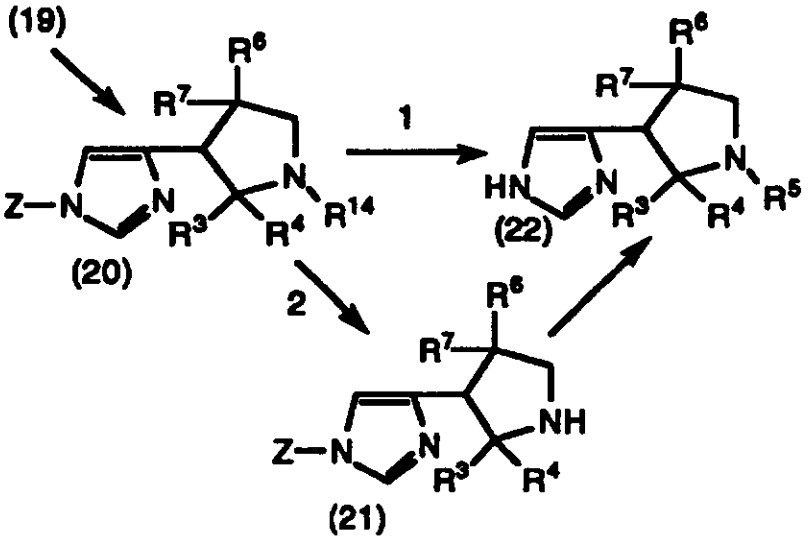
STEP 6-Preparation B:



(19)

In Step 6, the enolate of compound (18) reacts with R^6-X and then with R^7-X to produce compound (19). X represents a suitable leaving group, such as Cl, Br, I or $-OSO_2CF_3$. Each reaction to place each substituent group on the ring takes place in an organic solvent using an organic base. Tetrahydrofuran is the solvent usually used; however, other suitable solvents include 1,4-dioxane, diethyl ether and the like. Examples of organic bases include lithium diisopropylamide, $M^+N[Si(CH_3)_3]_2$, KH and the like. M^+ represents a suitable metal cation such as Na, Li, K, and the like. The reaction is usually conducted at a temperature of about -78 to about 80 °C.

STEPS 7, 8 AND 9-Preparation B:



In Step 7, compound (19) is reduced to compound (20) with a reducing agent in an organic solvent at a suitable temperature. Preferably, $LiAlH_4$ (lithium aluminium hydride) is used with tetrahydrofuran at a temperature of about 0 to about 70°C. Other suitable reducing agents include BH_3 (borane) and the like. Other organic solvents which may be used include 1,4-dioxane and the like.

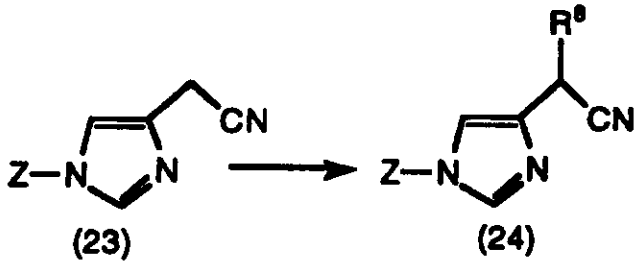
In reaction path 1 (compound (20) to (22)), R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl, or propargyl. In reaction path 2 (compound (20) to (21)), R^{14} is $-Si(CH_3)_2C(CH_3)_3$ or -C(O)O(t-butyl),

In Step 8, following reaction path 1, compound (20) is deprotected by following the procedure in Step 7 of Preparation A to produce compound (22). Alternatively, following reaction path 2, when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, compound (20) is treated with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of about 0 to about 50°C to produce compound (21), or compound (20), when R^{14} is -C(O)O(t-butyl), is treated with dilute aqueous acid (e.g., HCl, HBr and the like).

In Step 9, the procedures in Steps 6 and 7 of Preparation A are followed so that compound (21) may be converted to compound (22).

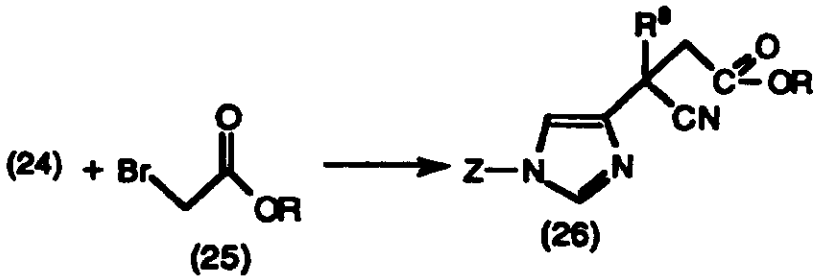
C. PREPARATION OF COMPOUNDS WHEREIN m IS 0, n is 1 and p is 2 PRODUCING COMPOUNDS OF FORMULA IV

STEP 1-Preparation C:



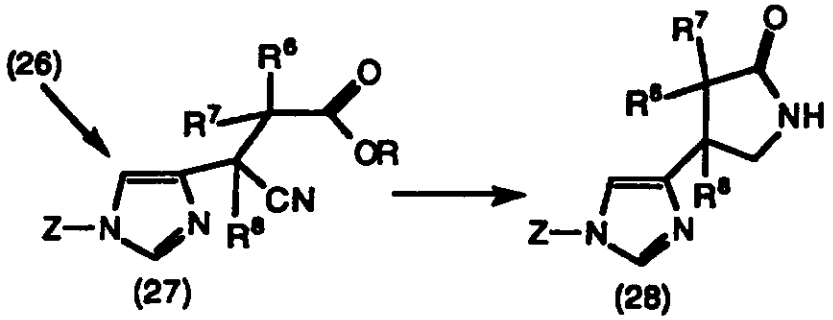
In Step 1, compound (23), synthesized according to Degraw et al. J. Med. Chem., 1977, 20, 1671, wherein Z is the trityl group, is reacted with R^8-L in an organic solvent, in the presence of an organic base, at a temperature of about 0 to about 50°C to produce compound (24). L is a suitable leaving group such as, for example, halogen (halides) selected from the group consisting of: Cl, Br, and I; $-OSO_2-C_6H_4-CH_3$ (wherein C_6H_4 is phenyl); $-OSO_2-CH_3$; and the like. Suitable organic bases include lithium diisopropylamide, $LiN[Si(CH_3)_3]_2$, and the like. Preferably, the organic solvent is tetrahydrofuran. Other suitable solvents which may be used include 1,4-dioxane and the like.

STEP 2-PREPARATION C:

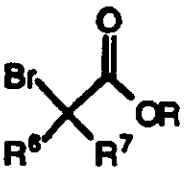


In Step 2, the anion of compound (24) is reacted with compound (25) (wherein R is alkyl) to produce compound (26). The reaction is conducted at a temperature of about -78 to about 50°C in an organic solvent containing an organic base. Suitable organic bases include lithium diisopropylamide, $LiN(Si(CH_3)_3)_2$, and the like. Preferably, the organic solvent is tetrahydrofuran. Other suitable solvents which may be used include DMF and the like.

STEPS 3 AND 4-PREPARATION C:



In Step 3, following the procedure set forth in Step 6 of Preparation B, compound (26) is substituted with substituent groups R^6 and R^7 to produce compound (27). Alternatively, compound (27) is prepared by the reaction of compound (24) with compound (26A)

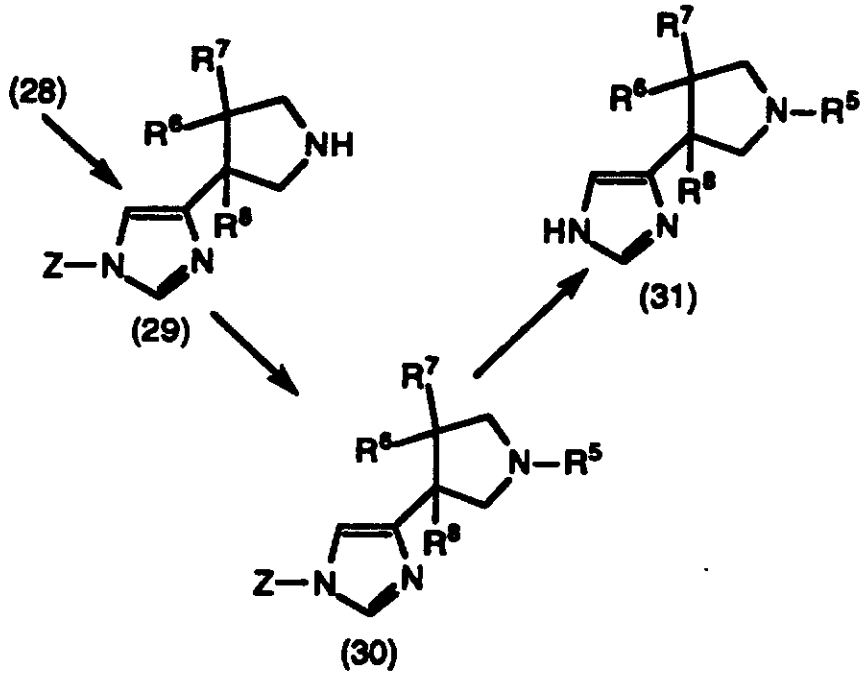


(26A)

under similar conditions for the reaction of compound (24) with compound (25).

In Step 4, compound (27) is reduced using H_2 and Raney-Nickel. The reduction takes place in ethanol at a temperature of about 25 (room temperature) to about 80°C. Other reducing agents can be used such as $NaBH_4/CoCl_2$ wherein the reduction takes place in ethanol at about room temperature. Subsequent cyclization in situ provides compound (28).

STEPS 5, 6 AND 7-PREPARATION C:



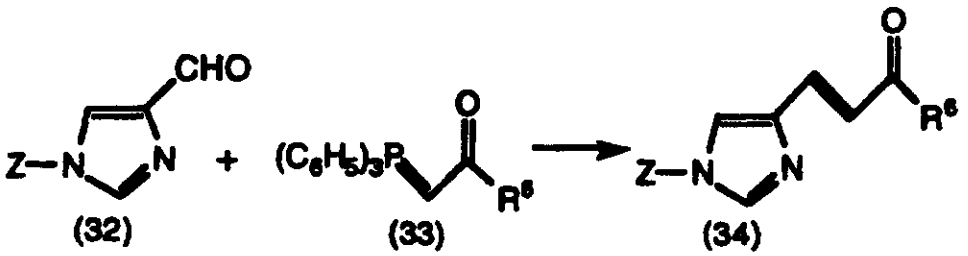
In Step 5, compound (28) is reduced to compound (29) in tetrahydrofuran using $LiAlH_4$ and a reaction temperature of about 0 to about 70°C. Another suitable reducing agent is BH_3.

In Step 6, compound (29) is converted to compound (30) according to the procedure described in Step 6 of Preparation A.

In Step 7, compound (30) is deprotected to produce compound (31) by following the procedure described in Step 7 of Preparation A.

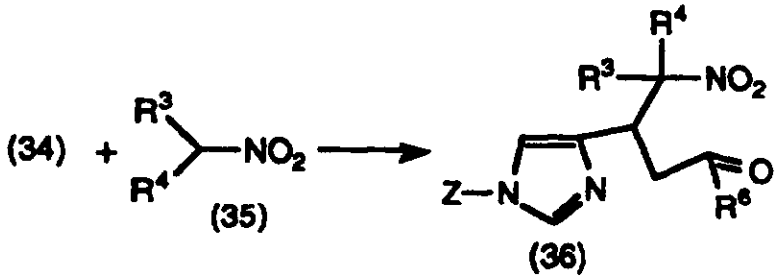
D. PREPARATION OF COMPOUNDS WHEREIN m is 0, n is 1 and p is 2 PRODUCING COMPOUNDS OF FORMULA IV

STEP 1-PREPARATION D



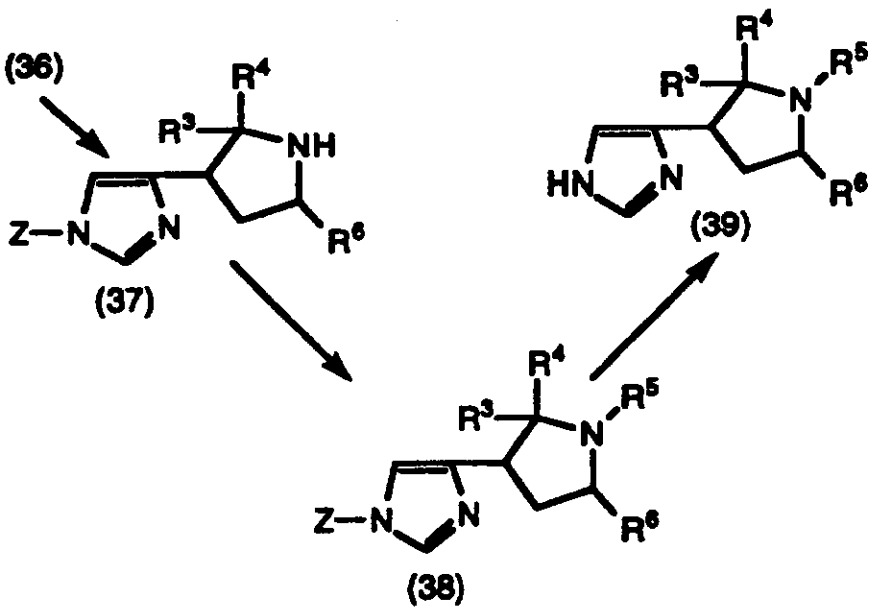
In Step 1, compound (32) is reacted with compound (33) to produce compound (34). The reaction is conducted in tetrahydrofuran at a temperature of about 25 to about 70°C. Other usable organic solvents besides tetrahydrofuran include DMF and the like. Compound (32) is prepared following the literature procedure set forth in J. L. Kelley et al., J. Med. Chem., 20, 721(1977). The Wittig reagent, compound (33), is either commercially available or may be prepared from the corresponding α-halo ketone and triphenylphosphine using standard reaction conditions known in the art.

STEP 2-PREPARATION D:



In Step 2, compound (34) is reacted with compound (35) to produce compound (36). The reaction is carried out according to the procedure set forth in Step 3 of Preparation B.

STEPS 3, 4 AND 5-PREPARATION D:



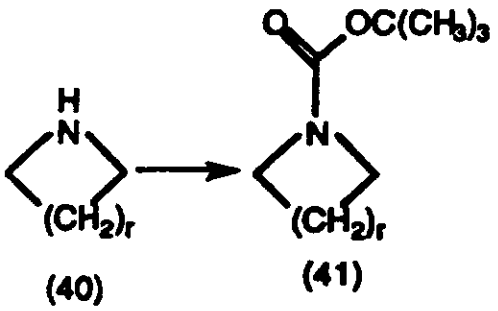
In Step 3, compound (36) is hydrogenated at a temperature of about 25 to about 70°C using H_2 and Raney-Nickel. The reaction is conducted in ethanol in similar fashion to the reaction described in Step 4 of Preparation C.

In Step 4, following the procedure in Step 6 of Preparation A, compound (37) is reacted with R^5-X or R^{5A}-CHO to produce compound (38).

In Step 5, compound (38) is deprotected at a temperature of about 50 to about 100°C using aqueous acid such as 10 % aqueous hydrochloric acid to produce compound (39).

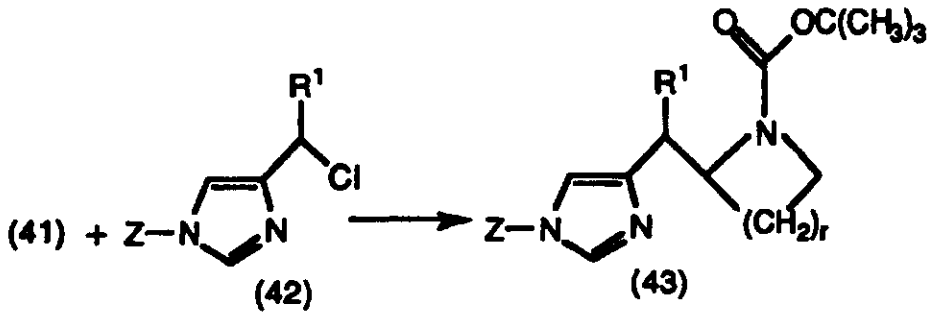
E. PREPARATION OF COMPOUNDS WHEREIN m IS 1, n is 0 and p is 2 or 3 PRODUCING COMPOUNDS OF FORMULAS IIA AND III

STEP 1-PREPARATION E:



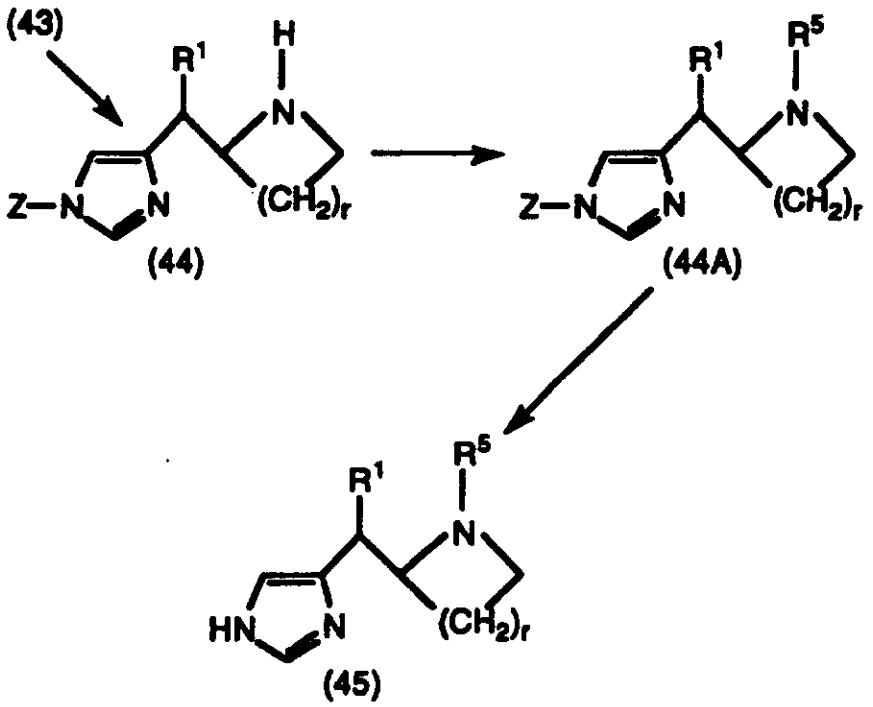
In Step 1, compound (40) is reacted with di-tert-butyl dicarbonate ($(tBOC)_2O$) in an organic solvent in the presence of an organic base. The reaction is conducted at a temperature of about 0 to about 30°C. Preferably, methylene chloride is used as the organic solvent, but other suitable organic solvents include DMF and the like. Triethylamine is used as the organic base. Other bases which can be used include 4-dimethylaminopyridine and the like. In compounds (40) and (41) r represents 1 or 2. The desired starting reactant (40) can be obtained commercially. In compound (41), the BOC group is chosen as an activating group on nitrogen which increases the kinetic acidity of the α-proton such that a lithio salt would result (for example, Step 2). Other activating groups on nitrogen, known in the art that can also be employed include nitroso, phosphoryl, hindered acyl, and formamidyl. (see Aldrichimica Acta, Vol. 8, No. 3, 1985).

STEP 2-PREPARATION E



In Step 2, the anion of compound (41) is reacted with compound (42), to produce compound (43). The reaction is conducted in an organic solvent containing an organic base and TMEDA (tetramethylethylenediamine). The reaction is conducted at a temperature of about -78 to about 25°C (room temperature). Tetrahydrofuran is preferably used as the solvent, other suitable solvents include diethyl ether and the like. The anion of (41) is prepared by metalation of (41) with sec-butyllithium in THF at -78°C. Compound (42) is obtained by reacting compound (32) with an organometallic reagent R^1M, wherein M is Li or MgBr, and then with thionyl chloride ($SOCl_2$).

STEPS 3 TO 5-PREPARATION E:



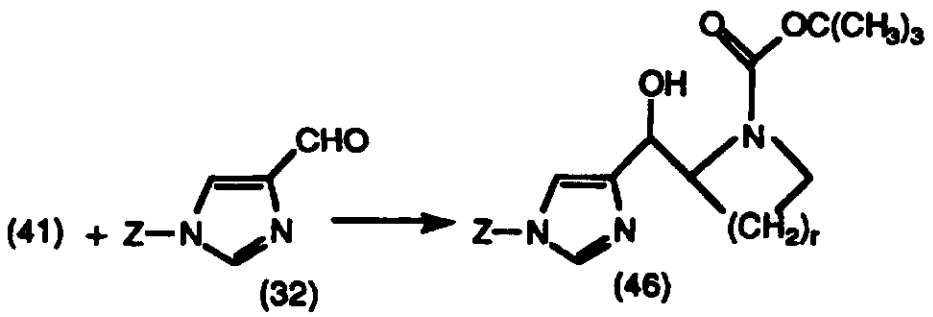
In Step 3, compound (43) is treated with HCl or similar acid in an inert organic solvent such as ethyl acetate or dioxane, at a temperature of about 0°C to selectively deprotect (43) thus producing compound (44).

In Step 4, compound (44) is reacted with R^5-X or R^{5A}-CHO in accordance with the procedure set forth in Step 6 of Preparation A to produce compound (44A).

In Step 5, compound (44A) is then deprotected to produce compound (45) by following the procedure set forth in Step 7 of Preparation A.

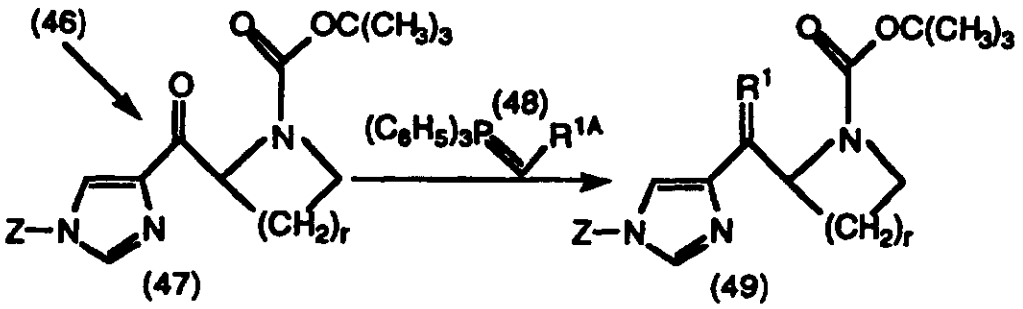
F. PREPARATION OF COMPOUNDS WHEREIN m IS 1, n is 0 and p is 2 or 3 PRODUCING COMPOUNDS OF FORMULAS IIA AND III

STEP 1-PREPARATION F:



In Step 1, compound (41)--see Step 1 of Preparation E--is reacted with compound (32) in accordance with the procedure set forth in Step 2 of Preparation E. r is 1 or 2.

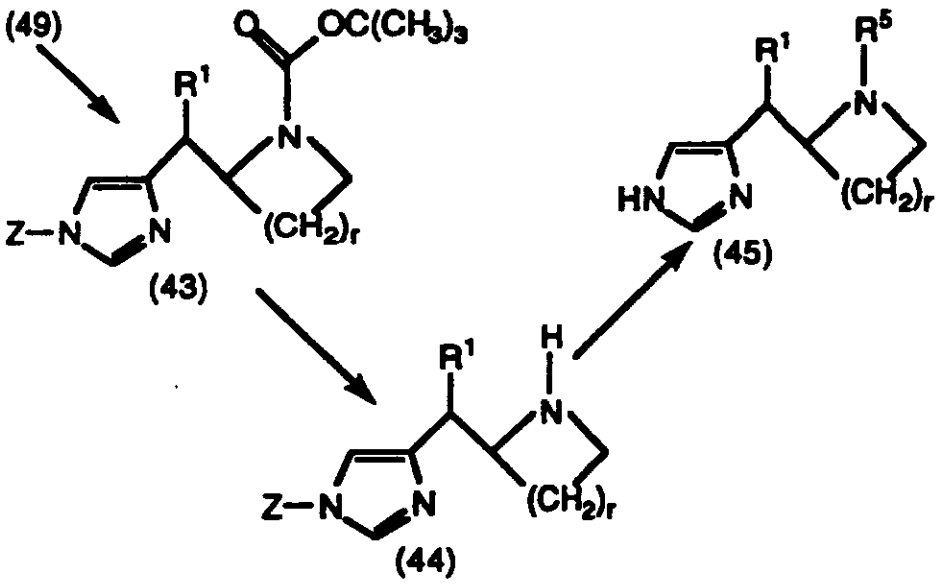
STEPS 2 AND 3-PREPARATION F:



In Step 2, compound (46) is oxidized to produce compound (47). The oxidation is accomplished by treating compound (46) with an oxidizing agent, such as MnO_2 or PDC (pyridinium dichromate), in an inert organic solvent, such as tetrahydrofuran or methylene chloride, at a temperature of about 20 to about 70°C.

In Step 3, compound (47) reacts, under usual Wittig reaction conditions, with compound (48) in an organic solvent at a temperature of about 25 to about 70°C to produce compound (49). In compound (48), R^{1A} represents an R^1 group which has one less $-CH_2-$ group. Preferably, the organic solvent is tetrahydrofuran; however, other suitable solvents, such as 1,4-dioxane and the like, can be used.

STEPS 4 AND 5-PREPARATION F:

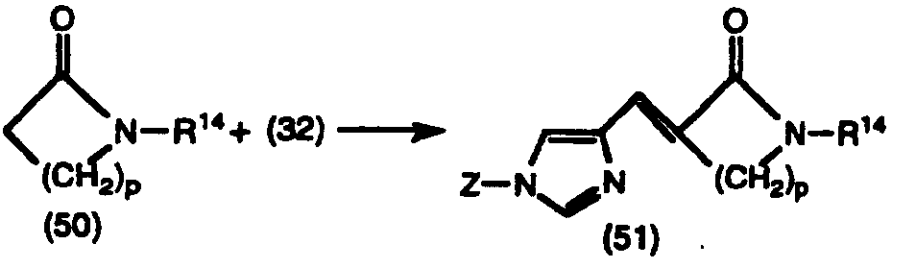


In Step 4, compound (43) is produced when compound (49) is hydrogenated in tetrahydrofuran with H_2 using a Pd-C (palladium/carbon) catalyst. Other organic solvents which can be used include ethyl acetate, methanol and the like. Other suitable metal catalysts such as Pt, Pd-Al_2O_3, Ra-Ni, NiB, and Pd-$CaCO_3$ can also be employed as the hydrogenation catalyst.

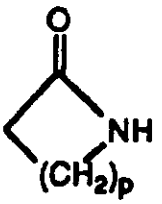
In Step 5, conversion of compound (43) to compound (44) and then to compound (45) is accomplished by following the same process described in Steps 3, 4, and 5 of Preparation E.

G. PREPARATION OF COMPOUNDS WHEREIN m IS 1, n is 1 and p is 1 or 2 PRODUCING COMPOUNDS OF FORMULAS II AND IV

STEP 1-PREPARATION G:

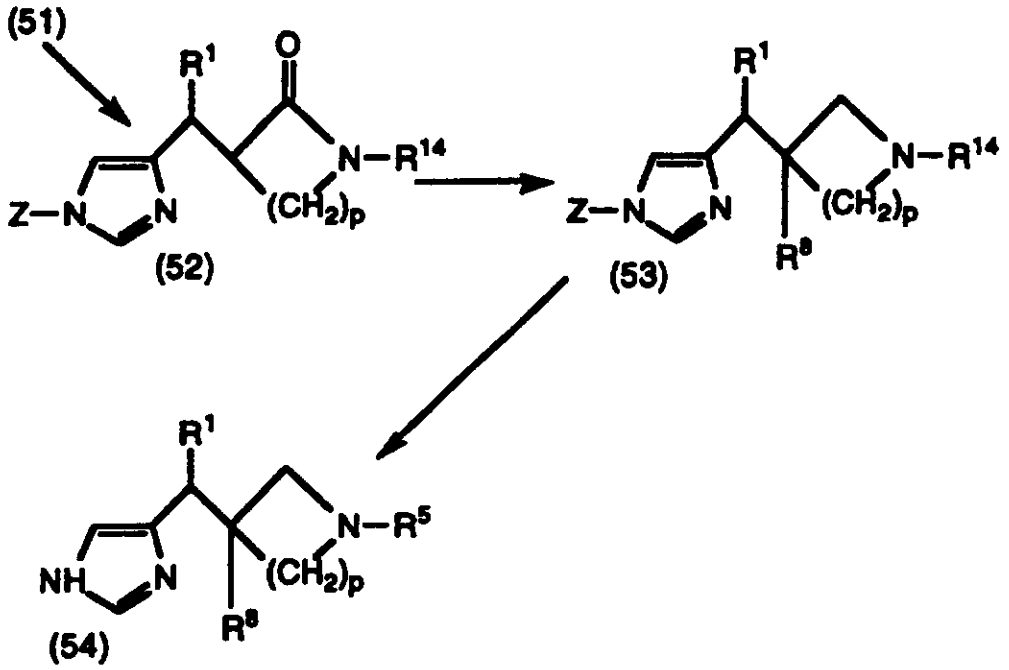


In Step 1, the anion of compound (50) reacts with compound (32) in an organic solvent at a temperature of about -78 to about 25°C to produce compound (51) wherein p is 1 or 2. Suitable organic solvents include tetrahydrofuran and the like. Preferably, the organic base used to generate the anion of (50) is lithium diisopropylamide or $M^+N[Si(CH_3)_3]_2$ wherein M^+ is a metal cation such as Li, Na, or K. Z is trityl. Compound (50) is obtained from the commercially available unprotected precursor



according to known methods--see, for example, Step 5 of Preparation B.

STEPS 2-4-PREPARATION G:



In Step 2, compound (51) is reacted with R^1-Q, wherein Q is Li or MgBr, in tetrahydrofuran containing CuCN and a Lewis acid, such as BF_3, $(CH_3)_3SiCl$ and the like, to produce compound (52). The reaction is conducted at a temperature of about -78 to about 20°C. Tetrahydrofuran is the preferred organic solvent; however, other suitable solvents include diethyl ether and the like.

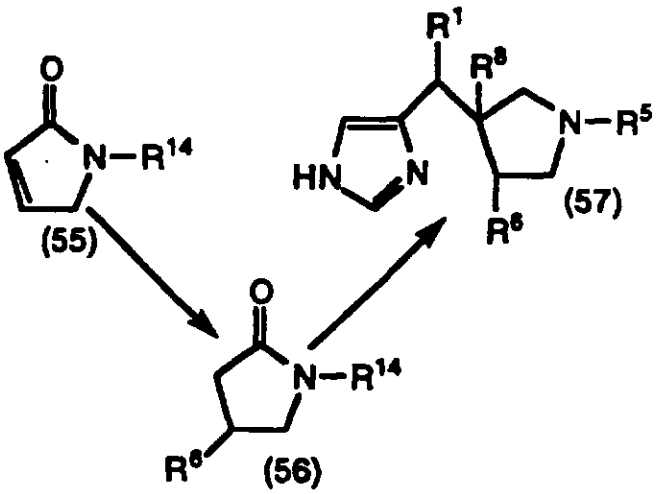
In Step (3), compound (52) is reacted with R^8-L according to the procedure set forth in Step 3 of Preparation A. Then the resulting R^8 substituted compound is reduced with either AlH_3 or DIBALH (when p = 1); or with $LiAlH_4$ (when p = 2) at a temperature of about 25 to about 65°C to produce compound (53). The reduction is conducted in tetrahydrofuran; however, other organic solvents, such as 1,4-dioxane and the like, can be used.

In Step 4, compound (53) is converted to compound (54) according to the processes described in Steps 8 and 9 of Preparation B for the conversion of compound (20) to compound (22).

H. PREPARATION OF COMPOUNDS WHEREIN m IS 1, n is 1 and p is 1 or 2 PRODUCING COMPOUNDS OF FORMULAS II AND IV

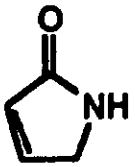
The anion of compound (50), which is prepared by reacting compound (50) with lithium diisopropylamide at a temperature of about -20°C to about 20°C in THF (see Step 1 of Preparation G) reacts with compound (42)--see Step 2 of Preparation E- in tetrahydrofuran at a temperature of about -78 to about 25°C to produce compound (52)--see Step 2 Preparation G. Other suitable solvents besides tetrahydrofuran can also be used, such as DMF and the like. Other suitable bases which can be used to generate the anion of (50) include $NaN[Si(CH_3)_3]_2$, $KN[Si(CH_3)_3]_2$, KH and the like. Compound (52) is converted to compound (54) following the procedures in Steps 3 and 4 of Preparation G.

I. PREPARATION OF COMPOUNDS WHEREIN m IS 1, n is 1 and p is 2



Compound (55) reacts with R^6-M (wherein M is Li, ZnBr or MgBr) in tetrahydrofuran containing $BF_3 \cdot (C_2H_5)_2O$ and CuCN at a temperature of about -78 to about 20°C to produce compound (56). Other suitable solvents such as diethyl ether can be used. Compound (56) is converted to compound (57) in accordance with the reaction steps set forth in Preparation G or Preparation H.

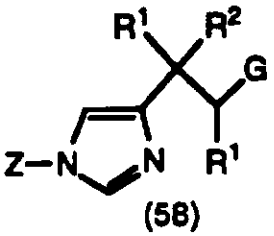
Compound (55) is obtained by reacting the commercially available unprotected precursor



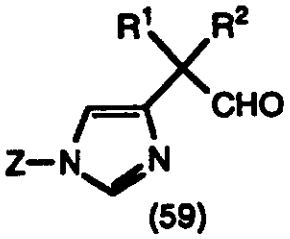
with R^{14}-L according to known methods--see, for example, Step 5 of Preparation B.

J. PREPARATION OF COMPOUNDS WHEREIN m IS 2, n IS 0 AND p is 2 or 3; OR m IS 2, n IS 1 AND p IS 1 OR 2

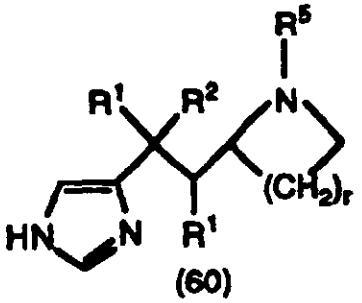
By following the steps in Preparations E, F, G or H with the exception that compound (58)



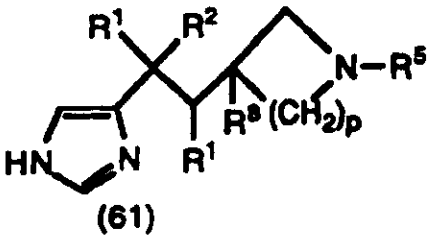
is used instead of compound (42) and compound (59)



is used in place of compound (32), compounds (60) and/or (61)



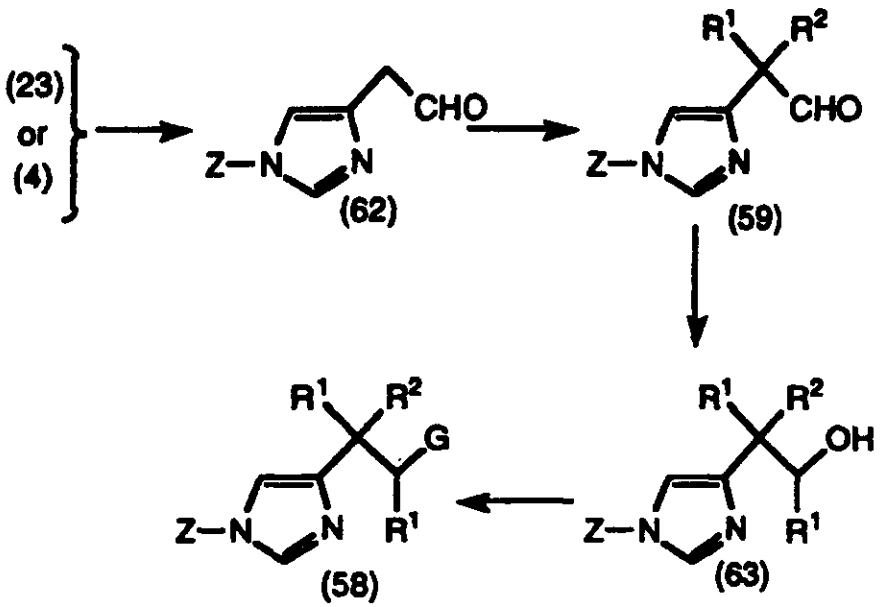
(60)



(61)

are produced. Compound (60) is produced following Preparation E or Preparation F, and compound (61) is produced following Preparation G or Preparation H. In compound (60), r is 1 or 2 and therefore p is 2 or 3, and in compound (61), p is 1 or 2. In compound (58), G represents a suitable leaving group such as Br, I, $-OSO_2-C_6H_4-CH_3$, $-OSO_2-CH_3$, $-OSO_2-CF_3$ and the like. The preparation of compound (58) is described below.

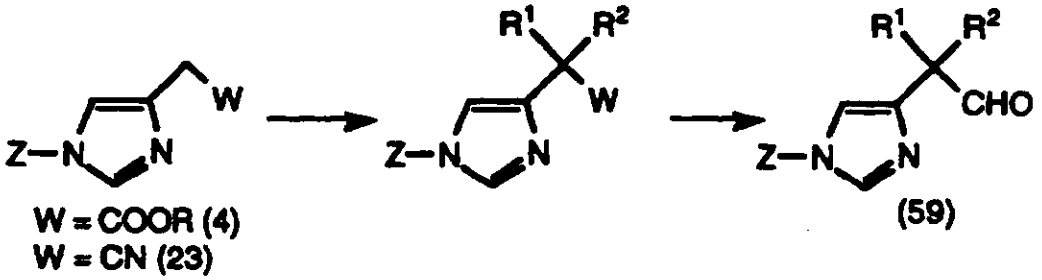
K. PREPARATION OF COMPOUND (58):



(58)

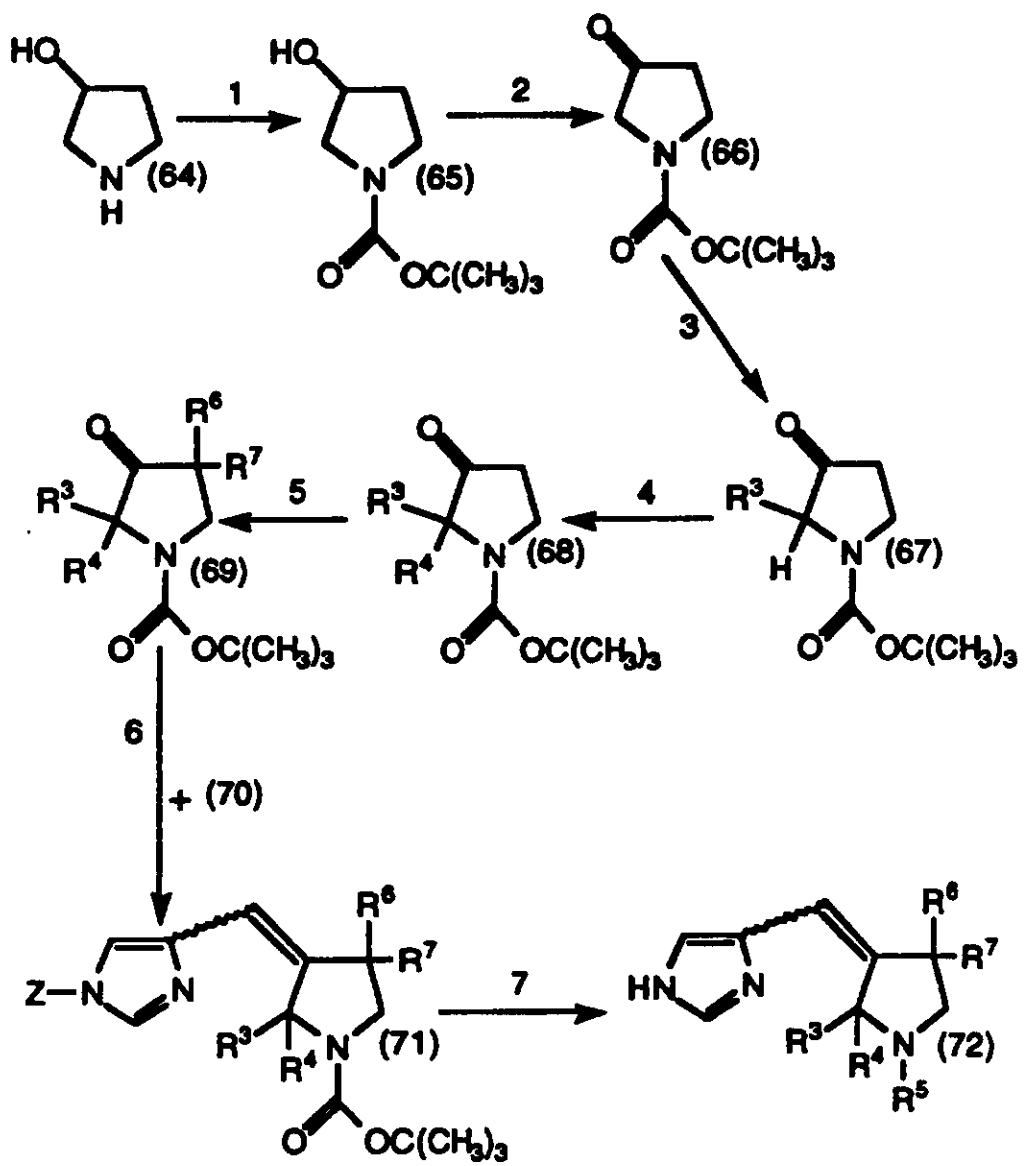
Compound (62) is produced by the reduction of compound (23) in tetrahydrofuran at a temperature of about 0 to about 70°C using diisobutylaluminum hydride as the reducing agent followed by an aqueous work up. Alternatively, reduction of compound (4) by bis(2-methoxyethoxy)aluminum hydride also can produce compound (62), see for example R. Kanazawa & T. Tokoroyama, Synthesis, 526(1976). Compound (59) is produced by reacting compound (62) in an organic solvent containing an organic base with R^1-L and then with R^2-L in accordance with the method set forth in Step 3 of Preparation A. Preferably, the organic solvent is tetrahydrofuran and the organic base is lithium diisopropylamide. L is a suitable leaving group such as Cl, Br, I, $-OSO_2-CF_3$ and the like.

Alternatively, the sequence of the preparation of compound (59), from compound (4) or (23), can be switched, i. e., alkylation first to introduce R^1 and R^2 and then reduction.



Compound (59) then reacts with either lithium aluminum hydride (when R^1 = H) or R^1-Q (R^1 is not H) in tetrahydrofuran at a temperature of about -78 to about 0°C to produce compound (63). Q represents Li or MgBr. When G represents a halide (i.e., Cl, Br, or I), then compound (58) is produced by either reacting compound (63) with $(H_5C_6)_3P/CG_4$ or $(H_5C_6)_3PG_2$ (see Fiser & Fiser, Reagents for Organic Synthesis, Vol. 1, p1247(1967)). When G represents -OSO_2-C_6H_4-CH_3, -OSO_2-CH_3 or -OSO_2-CF_3, then compound (58) is produced by reacting compound (63) with Cl-SO_2-C_6H_4-CH_3, Cl-SO_2-CH_3 or Cl-SO_2-CF_3, respectively, in methylene chloride containing triethylamine (as base) at a temperature of about -78 to about 0°C.

L. PREPARATION OF COMPOUNDS WHEREIN m is 1, n is 1 AND p is 2 AND WHEREIN THE DOUBLE BOND INDICATED IN FORMULA I IS PRESENT



In Step 1, compound (65) is produced when compound (64) is reacted with $(t\text{-BOC})_2O$ and triethylamine. The reaction is conducted in an organic solvent, such as methylene chloride or DMF, using a temperature within the range of about 0 to about 25°C (room temperature).

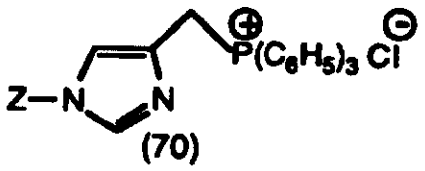
In Step 2, compound (66) is produced by treating compound (65) with an oxidizing agent such as pyridinium dichromate. The oxidation reaction is conducted in an organic solvent, such as methylene chloride, using a temperature of about 25 to about 50°C.

In Step 3, compound (67) is produced when the enolate of compound (66) is reacted with R^3-L wherein L is a suitable leaving group, such as halogen (e.g., Cl, Br, or I), $-OSO_2CF_3$ and the like. The reaction takes place in an organic solvent, such as tetrahydrofuran or benzene, containing a suitable base, such as NaH, LDA, or $LiN(Si(CH_3)_3)_2$. Preferably, tetrahydrofuran is used as the solvent and LDA is used as the base. The reaction is conducted at a temperature of about 0 to about 80°C.

In Step 4, compound (67) is reacted with R^4-L using the same procedure set forth in Step 3 in order to produce compound (68).

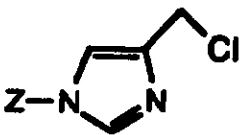
In Step 5, compound (69) is produced When compound (68) is first reacted with R^6-L and then reacted with R^7-L Each reaction is conducted using the same procedure set forth in Step 3.

In Step 6, compound (71) is obtained When compound (69) is reacted with compound (70)



(70)

The reaction takes place in an organic solvent, such as tetrahydrofuran, DMF or benzene, containing a suitable base, such as NaH, LDA, or $LiN(Si(CH_3)_3)_2$. Preferably, tetrahydrofuran is used as the solvent and LDA is used as the base. The reaction is conducted at a temperature of about 0 to about 80°C. Compound (70) is obtained by reacting



(70A)

with $P(C_6H_5)_3$ in an organic solvent, such as methylene chloride, CH_3CN, tetrahydrofuran and the like, using a temperature of about 25 to about 50°C. In compounds (70) and (70A), Z represents trityl or SEM.

In Step 7, compound (72) is produced by using compound (71) and following the same procedures set forth in Steps 3, 4 and 5 of Preparation E.

In the steps of Preparation L alkylations (i.e., Steps 3, 4 and 5) are only if desired and R^3, R^4, R^5, R^6, and R^7 are as defined for Formula I.

In the above processes, certain functional groups may be incompatable with some transformations described herein and consequently it is sometimes desirable and/or necessary to protect certain groups during the reactions. Certain protecting groups are employed in the above processes but, as those skilled in the art will recognize, other protecting groups may be used in their place. Conventional protecting groups are operable as described in Greene, T. W., and Wuts, P.G.M., "Protective Groups In Organic Synthesis," John Wiley & Sons, New York, 1991; the disclosure of which is incorporated herein by reference thereto. After the reaction or reactions, the protecting groups may be removed by standard procedures.

The compounds of this invention are either agonists or antagonists of the histamine H_3 receptor. The binding affinity of the compounds of the invention to the H_3 receptor may be demonstrated by the procedure described below:

H_3 Receptor Binding Assay

The source of the H_3 receptors in this experiment was guinea pig brain. The animals used weighed 400-600 g. The tissue was homogenized using a Polytron in a solution of 50 mM Tris, pH 7.5. The final concentration of tissue in the homogenization buffer was 10% w/v. The homogenates were centrifuged at 1000 x g for 10 min. in order to remove clumps of tissue and debris. The resulting supernatants were then centrifuged at 50,000 x g for 20 min. in order to sediment the membranes, which were next washed 3 times in homogenization buffer (50,000 x g for 20 min. each). The membranes were frozen and stored at -70°C until needed.

All compounds to be tested were dissolved in DMSO and then diluted into the binding buffer (50 mM Tris, pH 7.5) such that the final concentration was 2 µg/mL with 0.1% DMSO. Membranes were then added (400 µg of protein) to the reaction tubes. The reaction was started by the addition of 3 nM [^{3}H]R-α-methylhistamine (8.8 Ci/mmol) or [^{3}H]-N-methylhistamine (80 Ci/mmol) and incubated at 30° for 30 min. Bound ligand was separated from unbound ligand by filtration, and the amount of radioactive ligand bound to the membranes was quantitiated by liquid scintillation spectrometry. All incubations were performed in duplicate and the standard error was less than 10% in all instances. Compounds that inhibited greater than 70% of the specific binding of radioactive ligand to the receptor were serially diluted to determine a K_i (µM). The results are given in Table 2.

In Table 2, the compound represented by (a*) is known in the art.

TABLE 2

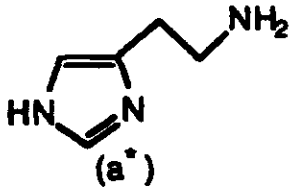
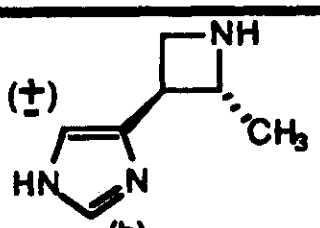
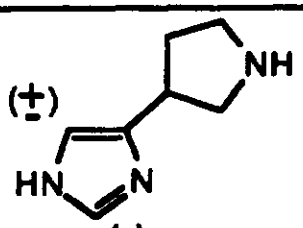
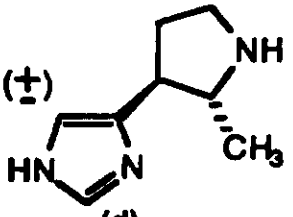
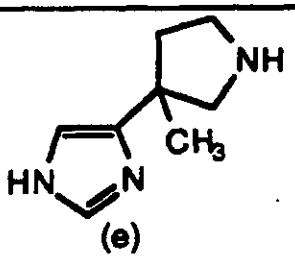
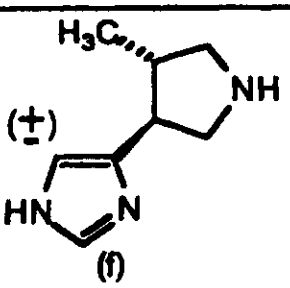
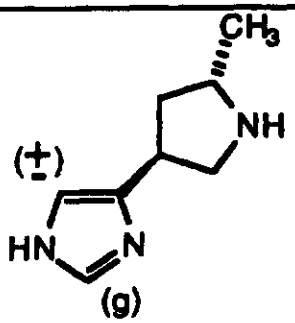
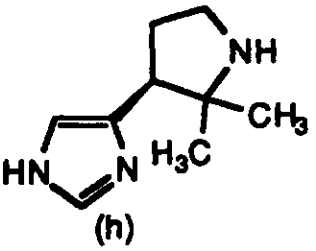
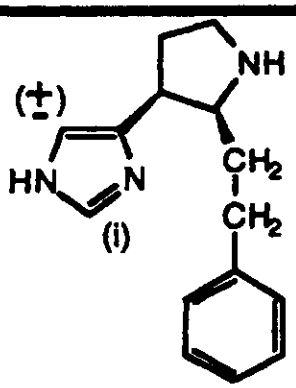
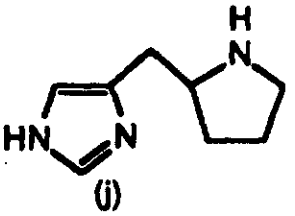
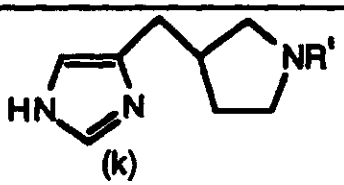
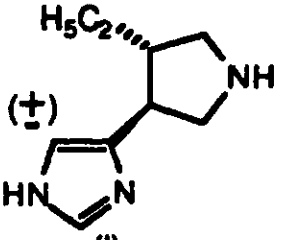
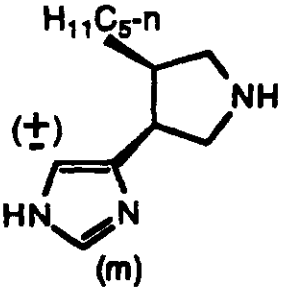
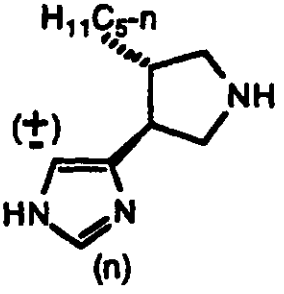
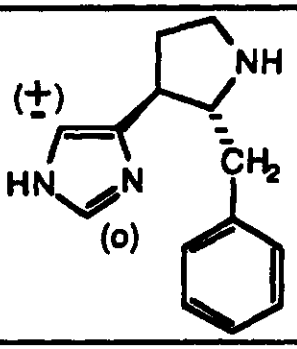
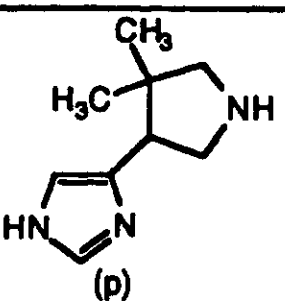
COMPOUND	H_3 Binding $K_i(\mu M)$	COMPOUND	H_3 Binding $K_i(\mu M)$
 (a*)	0.014	 (b)	0.007
 (c)	0.003	 (d)	0.006
 (e)	0.17	 (f)	0.008
 (g)	0.076	 (h)	0.066

TABLE 2-CONTINUED

COMPOUND	H_3 Binding K_i(μM)	COMPOUND	H_3 Binding K_i(μM)
 (i)	0.60	 (j)	0.11
 (k) R' is methyl	0.003	 (l)	0.15
 (m)	0.077	 (n)	0.45
 (o)	7%**	 (p)	68%**

In Table 2, the **** values for compounds (o) and (p) represent the % inhibition at a concentration of 2 μg/mL. It is expected that at higher concentrations higher activities will be obtained.

For preparing pharmaceutical compositions from the compounds described by this invention, inert, pharmaceuti-

cally acceptable carriers can be either solid or liquid. Solid form preparations include powders, tablets, dispersible granules, capsules, cachets and suppositories. The powders and tablets may be comprised of from about 5 to about 70 percent active ingredient. Suitable solid carriers are known in the art, e.g. magnesium carbonate, magnesium stearate, talc, sugar, lactose. Tablets, powders, cachets and capsules can be used as solid dosage forms suitable for oral administration.

For preparing suppositories, a low melting wax such as a mixture of fatty acid glycerides or cocoa butter is first melted, and the active ingredient is dispersed homogeneously therein as by stirring. The molten homogeneous mixture is then poured into convenient sized molds, allowed to cool and thereby solidify.

Liquid form preparations include solutions, suspensions and emulsions. As an example may be mentioned water or water-propylene glycol solutions for parenteral injection.

Liquid form preparations may also include solutions for intranasal administration.

Aerosol preparations suitable for inhalation may include solutions and solids in powder form, which may be in combination with a pharmaceutically acceptable carrier, such as an inert compressed gas.

Also included are solid form preparations which are intended to be converted, shortly before use, to liquid form preparations for either oral or parenteral administration. Such liquid forms include solutions, suspensions and emulsions.

The compounds of the invention may also be deliverable transdermally. The transdermal compositions can take the form of creams, lotions, aerosols and/or emulsions and can be included in a transdermal patch of the matrix or reservoir type as are conventional in the art for this purpose.

Preferably the compound is administered orally.

Preferably, the pharmaceutical preparation is in unit dosage form. In such form, the preparation is subdivided into unit doses containing appropriate quantities of the active component, e.g., an effective amount to achieve the desired purpose.

The quantity of active compound in a unit dose of preparation may be varied or adjusted from about 0.1 mg to 1000 mg, more preferably from about 1 mg to 500 mg, according to the particular application.

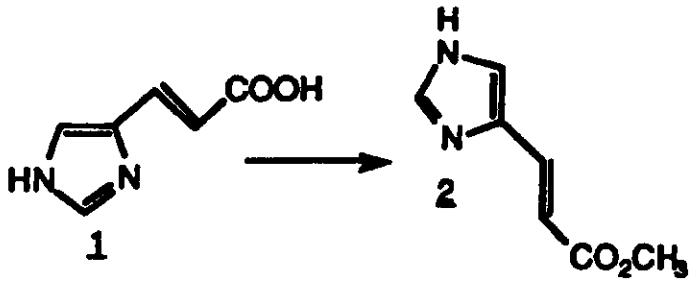
The actual dosage employed may be varied depending upon the requirements of the patient and the severity of the condition being treated. Determination of the proper dosage for a particular situation is within the skill of the art. Generally, treatment is initiated with smaller dosages which are less than the optimum dose of the compound. Thereafter, the dosage is increased by small increments until the optimum effect under the circumstances is reached. For convenience, the total daily dosage may be divided and administered in portions during the day if desired.

The amount and frequency of administration of the compounds of the invention and the pharmaceutically acceptable salts thereof will be regulated according to the judgment of the attending clinician considering such factors as age, condition and size of the patient as well as severity of the symptoms being treated. A typical recommended dosage regimen is oral administration of from 1 mg to 2000 mg/day preferably 10 to 1000 mg/day, in one to four divided doses to achieve relief of the symptoms. The compounds are non-toxic when administered within this dosage range.

The invention disclosed herein is exemplified by the following preparative examples, which should not be construed to limit the scope of the disclosure. Alternative mechanistic pathways and analogous structures within the scope of the invention may be apparent to those skilled in the art.

EXAMPLE 1

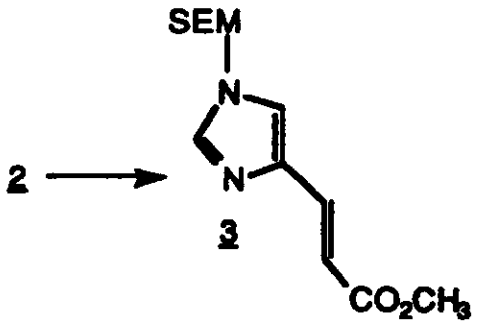
A. Preparation of Methyl Ester (2).



To a suspension of urocanic acid 1 (13-8 g, 100 mmol) in methanol (250 mL) was added concentrated sulfuric acid (10 mL) and the mixture was heated to reflux for 24 h. The mixture was cooled to 5°C and concentrated ammonium hydroxide (25 mL) was added slowly. The solvents were removed by rotary evaporation and to the residue was added water (50 mL) and ethyl acetate (750 mL). The mixture was shaken, the layers separated, and the aqueous layer was extracted with ethyl acetate (500 mL). The combined organic layers were dried over anhydrous sodium sulfate, filtered

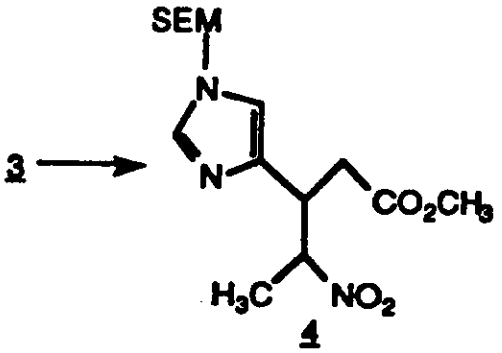
and evaporated to give 2 as a white solid (14.9 g, 98%).

B. Preparation of (2-Trimethylsilyl)ethoxymethyl-imidazole (3).



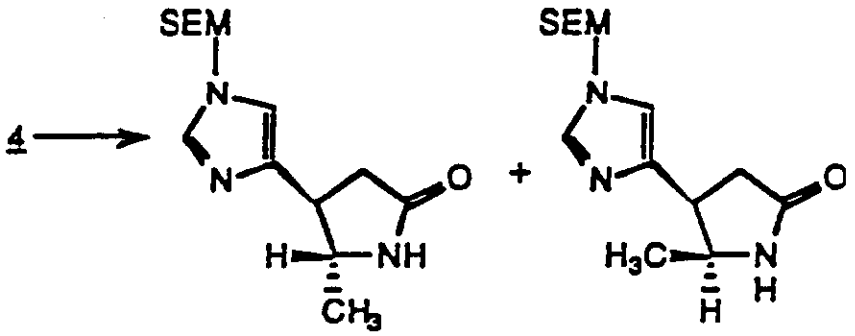
To a suspension of the methyl ester 2 (12.2 g, 80.0 mmol) in tetrahydrofuran (80 mL) was added triethylamine (28 mL, 200 mmol) and then (2-trimethylsilyl)ethoxymethyl chloride (30 mL, 170 mmol). The mixture was stirred at room temperature for 1 h and then to this mixture was added 5% aqueous sodium hydroxide (200 mL) and methylene chloride (1200 mL). The mixture was shaken vigorously, the layers separated, and the aqueous layer was extracted with methylene chloride (1200 mL). The combined organic layers were dried over anhydrous sodium sulfate, filtered, and evaporated to give an orange, oily residue which was purified by flash chromatography (ethyl acetate) to give 3 as a slightly yellow solid (10.8 g, 48%).

C. Preparation of Nitro-Ester (4).



To a solution of unsaturated ester 3 (10.8 g, 38 mmol) in acetonitrile (25 mL) was added nitroethane (15 mL, 209 mmol) and then 1,8-diazabicyclo[5.4.0]undec-7-ene (6 mL, 40 mmol). The mixture was stirred at room temperature for 72 h, the solvents were removed by rotary evaporation and the dark, oily residue was purified by flash chromatography (ethyl acetate) to give the nitro-ester 4 as a mixture of diastereomers (13.3 g, 97%).

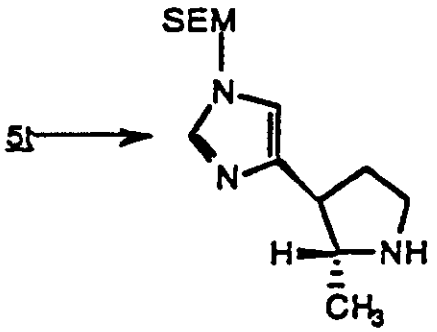
D. Preparation of Lactams (5t) and (5c).



5t 5c

A mixture of the nitro-ester 4 (8.3 g, 23 mmol) and Raney nickel (8 g) in absolute ethanol (60 mL) was shaken under 60 psi 413 KPa of hydrogen at 55°C in a Parr apparatus for 6 h. The mixture was filtered and the filtrate was evaporated to give an oily residue which was purified by flash chromatography (a: 5% MeOH/NH_3 in CH_2Cl_2, b: 7% MeOH/NH_3 in THF:Hexane, 2:1) to give two compounds; the first compound to elute was the *trans*-diastereomer 5t (2.64 g, 39%). The second compound to elute was the *cis*-diastereomer 5c (1.67 g, 26%).

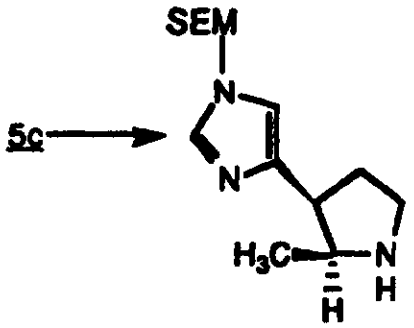
E. Preparation of pyrrolidine (6t).



6t

To a solution of the *trans*-lactam 5t (2.60 g, 8.8 mmol) in tetrahydrofuran (175 mL) was added a solution of lithium aluminum hydride in diethyl ether (1.0 M, 44.0 mL, 44 mmol). The mixture was stirred at room temperature for 4 h and to the reaction mixture was added diethyl ether (440 mL) and saturated aqueous sodium sulfate (7 mL) dropwise. The mixture was dried over anhydrous sodium sulfate, filtered, and evaporated to give an oily residue which was purified by flash chromatography (gradient elution; CH_2Cl_2: MeOH/NH_3, 7:1 to 5:1) to give 6t as a colorless oil (1.15 g, 46%).

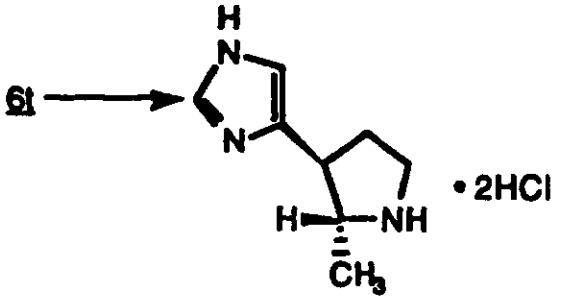
F. Preparation of pyrrolidine (6c).



6c

The *cis*-lactam 5c (0.60 g, 2.0 mmol) was treated in the same manner as described for the preparation of pyrrolidine 6t. The crude reaction product was purified by Rash chromatography (gradient elution; CH_2Cl_2:. MeOH/NH_3, 6:1 to 4:1) to give 6c as a colorless oil (0.36 g, 63%).

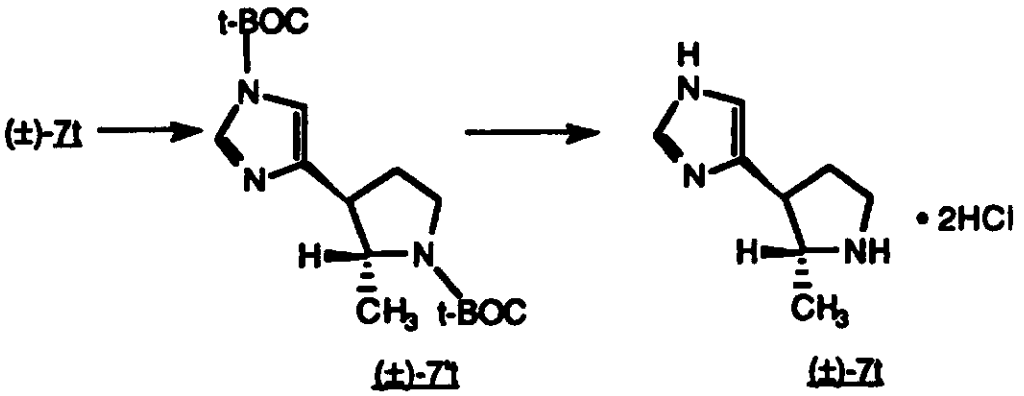
G. Preparation of ((±)-7t).



(±)-7t

To a solution of the pyrrolidine 6t (563 mg, 2.0 mmol) in 95% ethanol (3 mL) was added concentrated hydrochloric acid (1 mL) and the mixture was heated to reflux for 16 h. The solvents were removed by rotary evaporation and to the residue was added 1 N aqueous hydrochloric acid (8 mL). This solution was extracted with ethyl acetate (3 x 4 mL) and the aqueous layer was concentrated by rotary evaporation. To the residue was added distilled water (15 mL) and the resulting solution was filtered through a glass wool plug. The filtrate was concentrated by rotrary evaporation to give (±)-7t as a cream-colored solid (395 mg, 88%).

H. Purification of ((±)-7t).



(±)-7t (±)-7t

To a solution of (±)-7t (336 mg, 1.5 mmol) in dimethylformamide (5.0 mL) was added triethylamine (1.05 mL, 7.53

mmol) and then a solution of di-*tert*-butyl dicarbonate (t-BOC)$_2$O (720 mg, 3.3 mmol) in dimethylformamide (1 mL). The mixture was stirred at room temperature for 2 h, the solvents were removed by vacuum distillation (1.0 mm Hg) and the resulting residue was purified by flash chromatography (gradient elution; EtOAc: hexane, 1:1 to 2:1) to give the corresponding di-*t*-BOC derivative (±)-7't (488 mg) as a white solid. This material was dissolved in ethyl acetate (3 mL), cooled to 5°C, and to this solution was added a saturated solution of hydrogen chloride in ethyl acetate (14 mL). The mixture was gradually warmed to room temperature (30 min) and stirred at this temperature for 16 h. The ethyl acetate was removed from the precipitated product by pipet and the precipitate was dried under high vacuum (0.1 mm Hg) to give (±)-7t as a white solid (286 mg, 85% recovery); MS (CI) 152 (M + 1).

I. Resolution of ((±)-7t.

The racemic (±)-7't was resolved by High Performance Liquid Chromatography using a Daicel Chiralcel OJ chiral chromatography column (2.0 cm x 50.0 cm, 4 % isopropanol in hexane). Multiple injections (13 injections of about 150 mg each) provided the levorotatory enantiomer (-)-7't :

$$950 \text{ mg; } [\alpha]_D^{26} = -12.8°, c = 0.50, CHCl_3,$$

and
the dextrorotatory enantiomer (+)-7't:

$$904 \text{ mg; } [\alpha]_D^{26} = +12.0°, c = 0.50, CHCl_3.$$

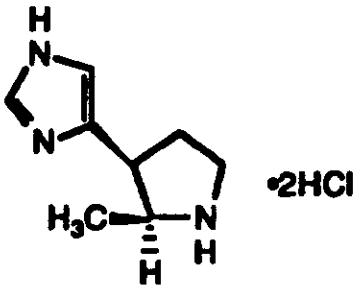
Treatment of (-)-7't with a saturated solution of hydrogen chloride in ethyl acetate as described above for the purification of (±)-7t provided (-)-7t:

$$[\alpha]_D^{26} = -34.6°, c = 1.00, H_2O.$$

Similar treatment of (+)-7't gave (+)-7t:

$$[\alpha]_D^{26} = +39.4°, c = 1.00, H_2O.$$

J. Preparation of ((±)-7c).



(±)-7c

The *cis*-pyrrolidine 6c (394 mg, 1.4 mmol) was treated as described for the preparation (±)-7t to give (±)-7c as a cream-colored solid (288 mg, 95%). Compound (±)-7c (224 mg, 1.0 mmol) was purified as described for the purification of (±)-7t to give (±)-7c as a white solid (177 mg, 79% recovery); MS (CI) 152 (M + 1).

Compounds 8, 9, 10t, 10c, 11t, 11c, 12t and 12c were prepared using the procedure described above for (±)-7t and 7c. The procedure is summarized below, A and B, and hence the compounds produced, are defined in Table 3.

K. Resolution of (±)-(7c).

In a manner similar to that described in Example 1, Steps H and I, racemic (±)-7c was resolved by High Performance Liquid Chromatography using a Daicel Chiralcel OD chiral chromatography column (5.0 cm x 50.0 cm, 1% isopropanol in hexane) followed by deprotection with a saturated solution of hydrogen chloride in ethyl acetate to give the levorotatory enantiomer (-)-7c:

$$[\alpha]_D^{26} = -35.7°, c = 1.00, H_2O$$

and the dextrorotatory enantiomer (+)-7c:

$[\alpha]_D^{26}$ =+33.2°, c = 1.00, H_2O.

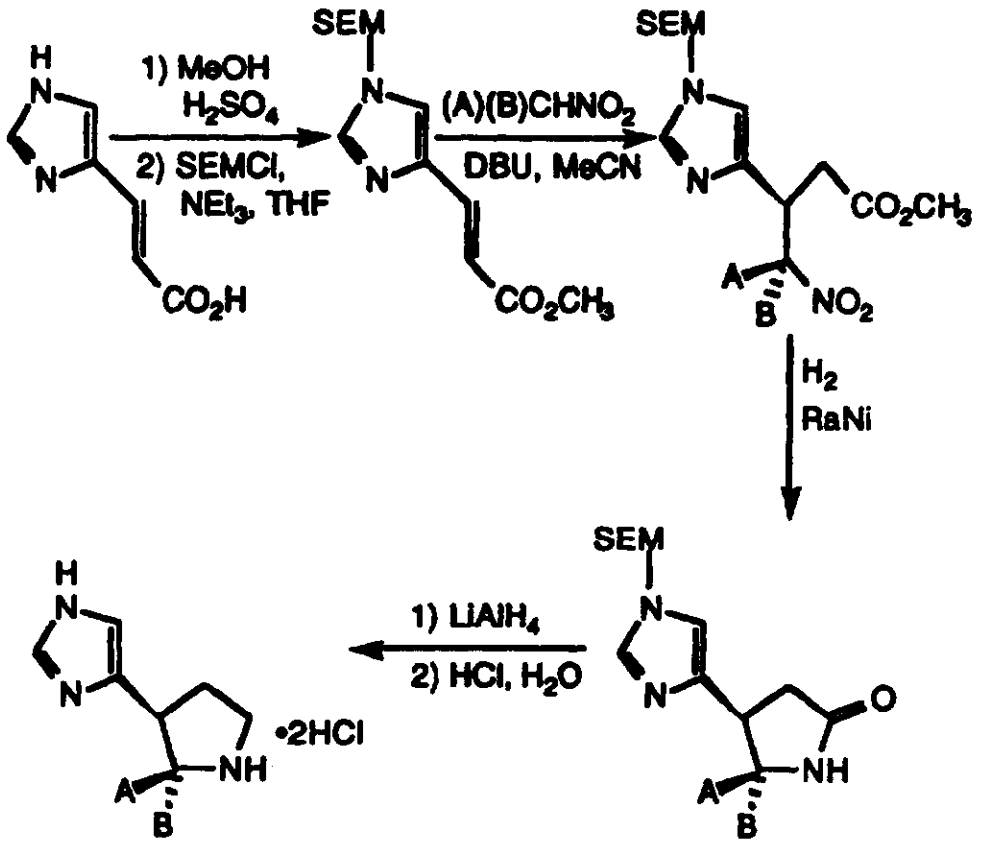
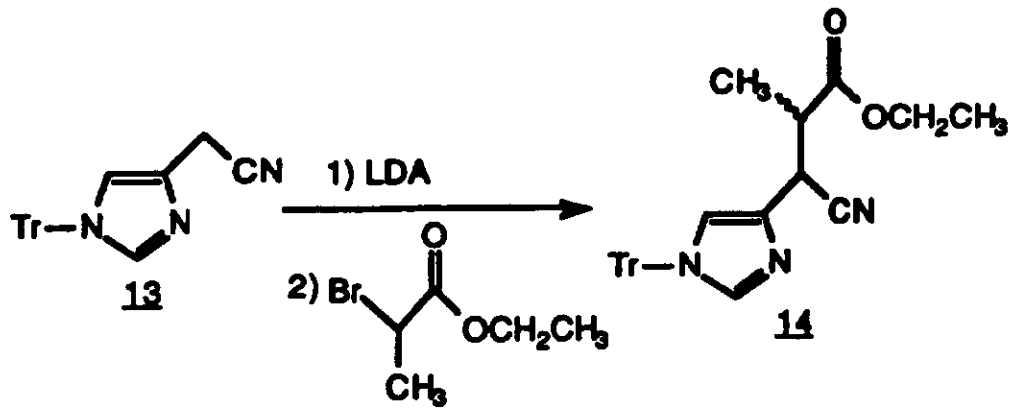


TABLE 3

COMPOUND	A	B	MS(CI)(M + 1)
8	H	H	138
9	$-CH_3$	$-CH_3$	166
10t	H	$-CH_2CH_3$	166
10c	$-CH_2CH_3$	H	166
11t	H	$-CH_2C_6H_5$	228
11c	$-CH_2C_6H_5$	H	228
12t	H	$-CH_2CH_2C_6H_5$	242
12c	$-CH_2CH_2C_6H_5$	H	242

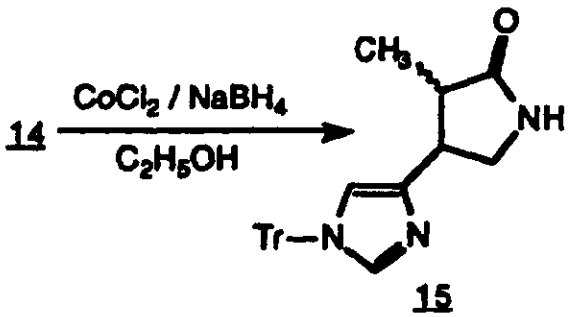
EXAMPLE 2

A.



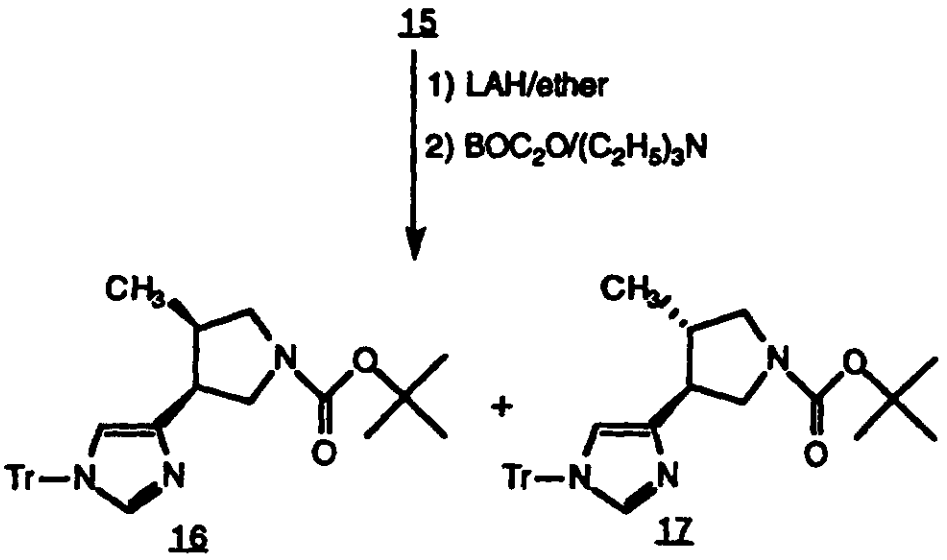
To a cooled (0°C) solution of diisopropylamine (4 mmol, 561 µL) in dry THF (7 mL) was added n-BuLi (n-butyllithium) (2.5 mL of a 1.6 M solution in hexane) dropwise. After 10 minutes at this temperature, the solution of LDA was cooled to -30°C and a solution of 1 trityl-4-cyanomethyl imidazole 13 (4 mmol, 1.4 g, Tr = trityl)) in THF (6 mL) was added dropwise. After an additional 30 minutes at this temperature, a solution of ethyl-2-bromopropionate (4 mmol; 520 µL) in THF (5 mL) was added dropwise. The reaction was slowly warmed to RT (room temperature) (45 minutes) and quenched with 15 mL H_2O. The reaction was extracted with diethyl ether (3 x 25 mL) and the combined organic fractions were washed with brine, dried with $MgSO_4$, and filtered. Concentration on the rotovap yielded 1.65 g of an oil which was purified via column chromatography (75:25 hexane:ethyl acetate). 0.75 g (42%) of 14 was obtained as a mixture of diastereomers. MS (CI) 450 (M+1).

B.



To a solution of 14 (6.23 mmol; 2.8g) and $CoCl_2$•6 H_2O (6.23 mmol; 1.48 g) in absolute ethanol (150 mL) was added $NaBH_4$ (31.2 mmol; 1.18g) portionwise over 30 minutes. After 4 hours, the black reaction mixture was concentrated to 1/3 the volume, shaken with ice-cold 3N HCl (50 mL) to dissolve the solids and rapidly basified to pH=9 with concentrated NH_4OH. The crude reaction was extracted with ethyl acetate (3 x 150 mL), and the combined organic layers were washed with brine, and dried ($MgSO_4$). Purification on a flash column (250 g SiO_2; 93:7 CH_2Cl_2: MeOH/ NH_3) yielded 1.53 g (60%) of 15 as a white solid.

C.

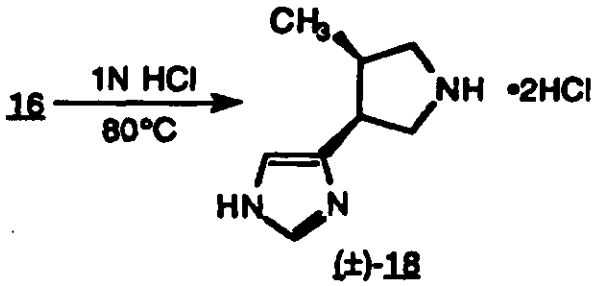


16 17

To a solution of lactam 15 (2.46 mmol; 1 g) in THF (30 mL) was added lithium aluminum hydride in diethyl ether (1M; 12.3 mL). The reaction was heated to 50°C for 5.5h, cooled to room temperature, diluted with diethyl ether, and quenched by careful dropwise addition of saturated aqueous Na_2SO_4. When H_2 evolution ceased, an additional 50 mL diethyl ether and solid Na_2SO_4 was added. The organic layer was filtered and concentrated to obtain 870 mg of a solid.

To a solution of the solid from the previous step in THF (20 mL) was added triethylamine (4.4 mmol; 614 µL) followed by di-t-butyl dicarbonate (2.75 mmol; 600 mg). After 2.5h, brine was added and the reaction was extracted into EtOAC (100 mL). The combined organic layers were dried (Na_2SO_4), filtered, and concentrated. 600 mg (48%) of 16 and 660 mg (52%) of 17 were obtained after chromatography on a flash column (150 g SiO_2; 65:35 EtOAc:Hexane).

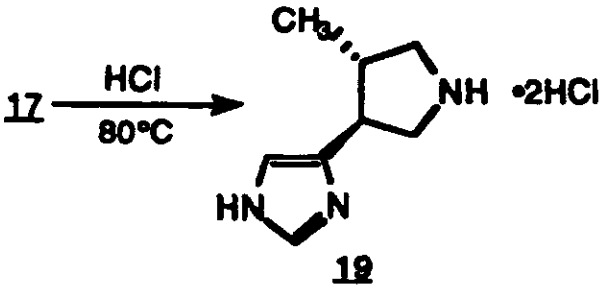
D.



(±)-18

A suspension of 16 (1.2 mmol; 600 mg) in 1NHCl (30 mL) was heated to 80°C for 1 hour. Compound 16 slowly dissolved and was replaced by a new solid. The reaction was cooled, filtered, and the aqueous layer was concentrated. Compound (±)-18, 170 mg, was obtained as a clear glass (64%) MS (EI) 151 (M^+).

In a similar manner, 17 yielded (±)-19 (175 mg, 60%) MS (EI) 151 (M^+).



E. Resolution of (±)18 and (±)19.

In a manner similar to that described in Example 1, Steps H and I, racemic (±)18 and (±)19 were resolved by High Performance Liquid Chromatography on a Chiralcel OD preparative column (2 x 50 cm) and gave after deprotection:

(+)-18 $[\alpha]_D^{21.5}$ = +37.6°, c = 0.43, MeOH

(-)-18 $[\alpha]_D^{22}$ = -32.2°, c = 0.43, MeOH

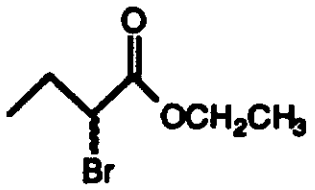
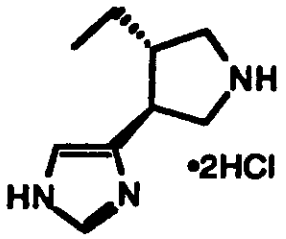
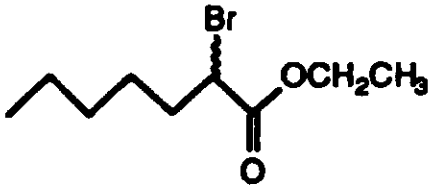
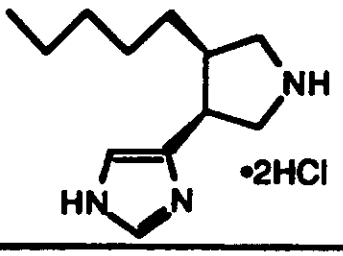
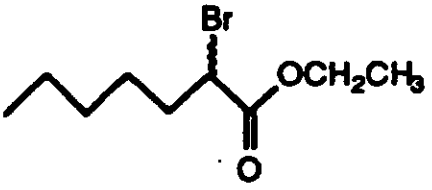
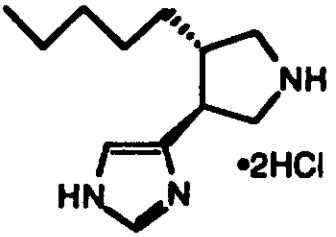
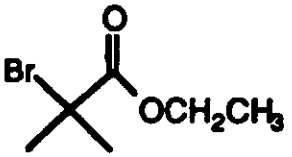
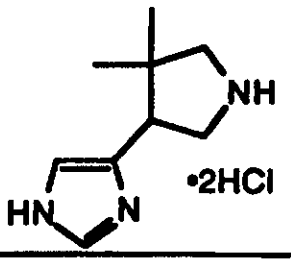
(+)-19 $[\alpha]_D^{22}$ = +39.0°, c = 0.18, MeOH

and

(-)-19 $[\alpha]_D^{22}$ = -36,0°, c = 0.20, MeOH.

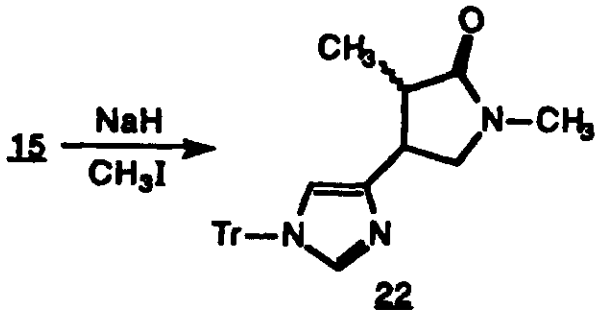
By using the route described above for preparing (±)-18, the compounds listed in Table 4 were prepared:

TABLE 4

STARTING MATERIAL	PRODUCT	MS
		166 (M+1) (CI)
		207 (M+) (EI)
		207 (M+) (EI)
		166 (M+1) (CI)

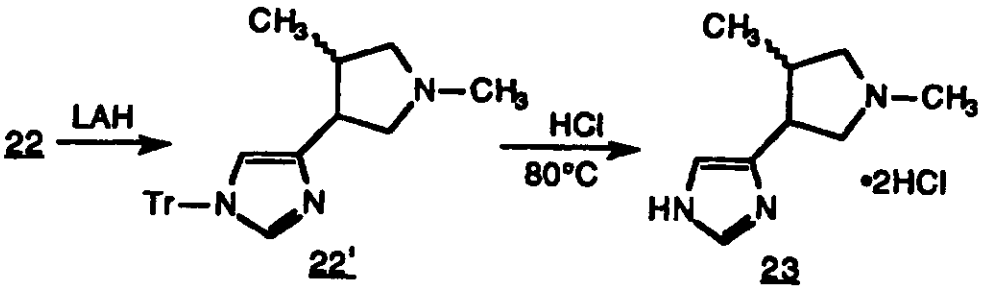
EXAMPLE 3

A.



To a solution of 15 (1.4 mmol; 570 mg; see Step B of Example 2) in DMSO (10 mL) at room temperature was added NaH (1.4 mmol; 56 mg of a 60% dispersion in mineral oil). After 1.5 hours, CH_3I (1.4 mmol 87 µL) was added, and the reaction was stirred overnight. The reaction was diluted with H_2O and extracted into diethyl ether (3 x 25 mL). The combined organic extracts were washed with brine, dried (Na_2SO_4), filtered, and concentrated. The crude product was purified on a flash column (100 g SiO_2; 95:5 CH_2Cl_2: CH_3OH/NH_3). Compound 22, 290 mg (49%), was obtained.

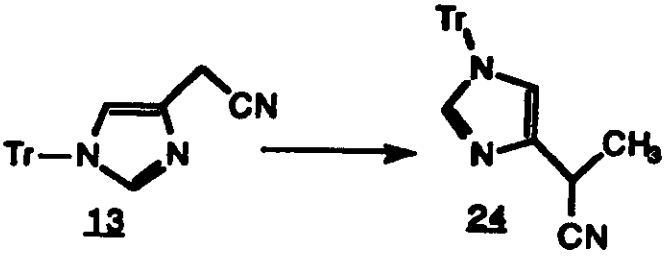
B.



By using the route described in Example 2, Steps C and D, compound 22 was converted to 23 (62 mg, 67%); MS (CI) 166 (M + 1).

EXAMPLE 4

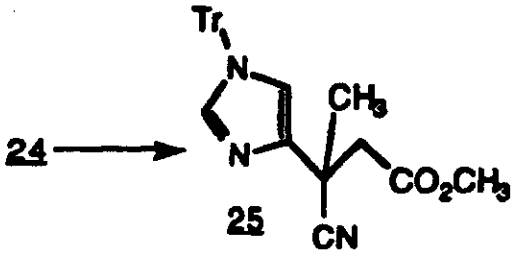
A. Preparation of α-methyl-nitrile (24).



To a solution of diisopropylamine (0.775 mL 5.5 mmol) in tetrahydrofuran (15 mL) at -78°C was added a solution of n-butyllithium in hexane (2.5 M, 2.1 mL, 5.25 mmol) and the mixture was stirred at -78°C for 1 h. To this was added a solution of the nitrile 13 (1.75 g, 5.0 mmol, see Step A of Example 2) in tetrahydrofuran (10 mL) and the mixture was stirred at -78°C for 1 h. To this solution was added a solution of methyl iodide (325 µL, 5.2 mmol) in tetrahydrofuran (2.5 mL), the mixture was stirred at -78°C for 30 min and then warmed to 0°C (1 h). To the mixture was added saturated aqueous ammonium chloride (2 mL), the solvents were removed by rotary evaporation and to the residue was added

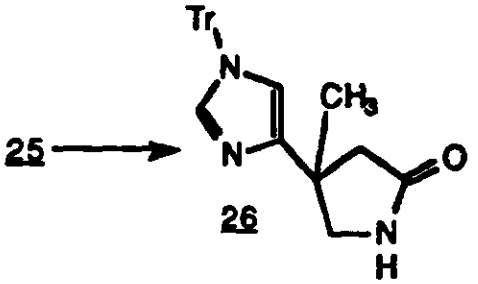
methylene chloride (200 mL), water (25 mL) and saturated aqueous sodium bicarbonate (25 mL). The mixture was shaken vigorously, the layers separated and the organic layer was dried over anhydrous sodium sulfate, filtered and evaporated to give a yellow solid residue. This crude product was purified by flash chromatography (hexane:isopropanol, 4:1) to give the α-methyl-nitrile 24 as an off-white solid (1.33 g, 73%).

B. Preparation of nitrile-ester (25).



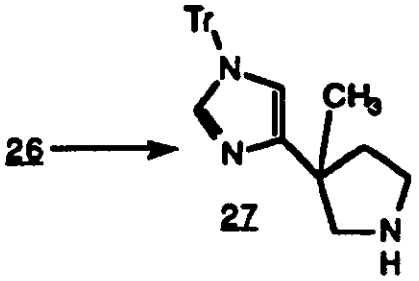
To a solution of diisopropylamine (0.550 mL, 3.9 mmol) in tetrahydrofuran (12 mL) at -78°C was added a solution of n-butyllithium in hexane (2.5 M, 1.50 mL, 3.75 mmol) and the mixture was stirred at -78°C for 1 h. To this was added a solution of the α-methyl-nitrile 24 (1.27 g, 3.5 mmol) in tetrahydrofuran (10 mL) and the mixture was stirred at -78°C for 1 h. To this solution was added a solution of ethyl bromoacetate (420 µL, 3.79 mmol) in tetrahydrofuran (2.0 mL), the mixture was stirred at -78°C for 1 h and then warmed to 0°C (1 h). To the mixture was added saturated aqueous ammonium chloride (1.5 mL), the solvents were removed by rotary evaporation and to the residue was added methylene chloride (200 mL) and saturated aqueous sodium chloride (40 mL). The mixture was shaken vigorously, the layers separated and the organic layer was dried over anhydrous sodium sulfate, filtered and evaporated to give a yellow oily residue. This crude product was purified by flash chromatography (hexane:acetone, 3:1 to 2:1) to give the nitrile-ester 25 as a colorless glass (1.44 g, 90%).

C. Preparation of Lactam (26).



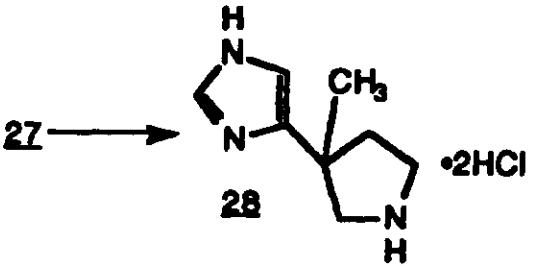
To a solution of the nitrile-ester 25 (1.39 g, 3.1 mmol) in absolute ethanol (70 mL) was added a solution of cobalt dichloride hexahydrate (736 mg, 3.1 mmol) in absolute ethanol (10 mL) and then portionwise (5 min) sodium borohydride (700 mg, 18.5 mmol). The mixture was stirred at room temperature for 2 h, the solvents were removed by rotary evaporation and to the black residue was added cold (5°C) 3 M aqueous hydrochloric acid (34 mL). The mixture was shaken until the black precipitate dissolved (5 min) and then to this mixture was added concentrated ammonium hydroxide (10 mL). This solution was extracted with ethyl acetate (2 x 250 mL) and the combined organic layers were dried over anhydrous sodium sulfate, filtered and evaporated to give an off-white solid residue which was purified by flash chromatography (gradient elution: 8% to 10% CH_3OH/NH_3 in CH_2Cl_2) to give the lactam 26 as a white solid (1.05 g, 83%).

D. Preparation of the Pyrrolidine (27).



The lactam 26 (1.05 g, 2.58 mmol) was treated with a solution of lithium aluminum hydride in diethyl ether (1.0 M, 13.0 mL, 13.0 mmol) as described for the preparation of the pyrrolidine 6t (see Example 1, Step E). The crude product was purified by flash chromatography (gradient elution: CH_2Cl_2: CH_3OH/NH_3, 8:1 to 7:1 to 6:1) to give the pyrrolidine 27 as a colorless glass (720 mg, 71%).

E. Preparation of Compound (28).



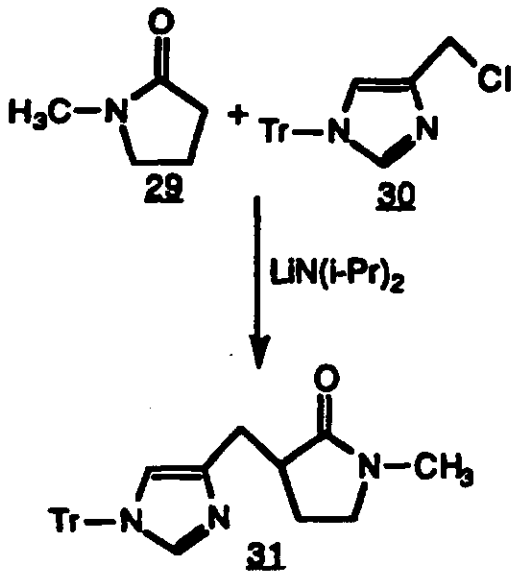
A suspension of the pyrrolidine 27 (750 mg, 1.91 mmol) in 1 N aqueous hydrochloric acid (15 mL) was heated to reflux for 1 h. The white precipitate that formed during the course of the reaction was removed by fitration and the aqueous filtrate was extracted with ethyl acetate (2 x 5 mL). The aqueous layer was concentrated by rotary evaporation to give compound 28 as an off-white solid (390 mg, 91%).

F. Purification of Compound (28).

Compound 28 (75 mg, 0.33 mmol) was purified as described for the purification of Compound (±)-7t (see Example 1, Step H) to give Compound 28 as a white solid (57 mg, 76% recovery); MS (CI) 152 (M + 1).

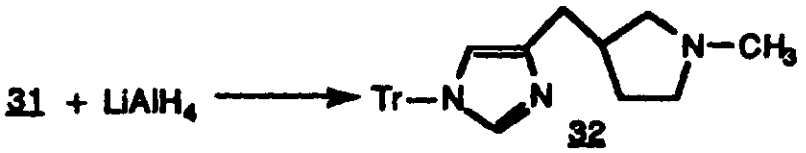
EXAMPLE 5

A.



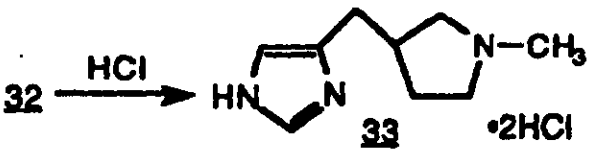
To a solution of 1.08 mL of freshly distilled N,N-diisopropylamine in 1 mL of anhydrous THF was added 3.1 mL of 2.5 M n-butyllithium at 0°C under nitrogen. The resulting solution was stirred at 0°C for 40 minutes (resulting in the production of lithium diisopropylamide ($LiN(i\text{-}Pr)_2$)). cooled to -23°C and then 0.672 mL of N-methyl-2-pyrrolidinone 29 was added slowly. The solution was stirred for 0.5 hours at -23°C and an additional 1 hour at -78°C. A solution of 2.69 g of 4-chloromethyl-(N-trityl)imidazole 30 in 14 mL of anhydrous THF was then added dropwise. The resulting solution was stirred for 4 hours at -78°C and slowly warmed to room temperature. After a couple of hours of stirring at room temperature, the reaction mixture was quenched by water and extracted with ethyl acetate. The combined organic extracts were washed with brine, dried over anhydrous $MgSO_4$ and concentrated to give crude product. The crude product was purified by flash chromatography on SiO_2 (1% to about 5% of ammonia saturated methanol in CH_2Cl_2) to give 1.77 (60% yield) of compound 31.

B.



To a solution of 1.54 g of 31 in 8 mL of anhydrous THF was added 11.34 mL of lithium aluminum hydride solution (1.0 M in diethyl ether) slowly. The resulting solution was stirred at room temperature for 2 hours, and 110 mL of diethyl ether was added. Saturated aqueous Na_2SO_4 solution was carefully added to the above mixture till hydrogen evolution ceased. The organic fraction was separated, and the aqueous solution was basified with K_2CO_3 and extracted with ethyl acetate many times. The combined organic solutions were washed with brine, dried over anhydrous K_2CO_3, and then concentrated to give a crude product. The crude product was purified by flash chromatography on SiO_2 (5% CH_3OH (NH_3) in CH_2Cl_2) to give 1.273 g (85% yield) of compound 32.

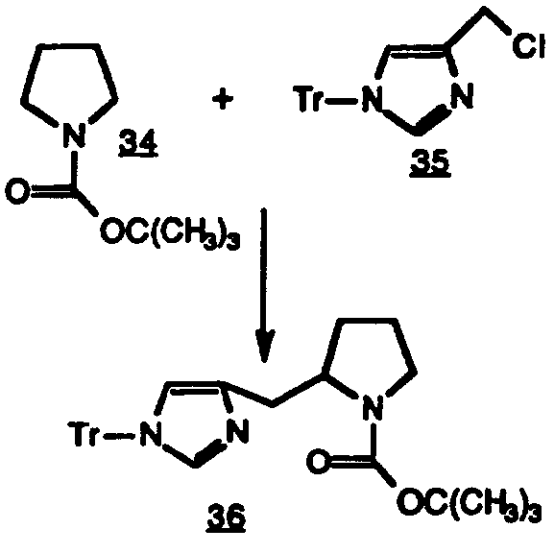
C.



A solution of 1.2 g of 32 in 100 mL of 0.5N aqueous hydrochloric acid was heated in a 90°C oil bath for 30 minutes. After the solution was cooled to room temperature, the mixture was extracted with diethyl ether (4 x 50 mL). The aqueous solution was concentrated under vacuum to yield crude product which was then recrystallized from 2-propanol/diethyl ether to give 0.5 g (85%) of compound 33; MS (FAB) 166 (M + 1).

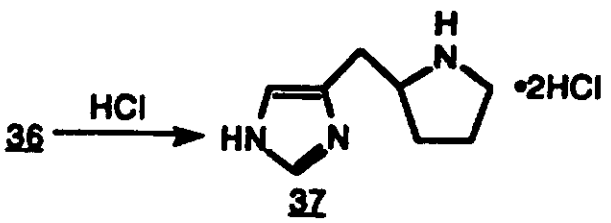
EXAMPLE 6

A.



To a solution of 1.194 g of compound of formula 34 and 2.49 mL of tetramethylethylenediamine in 7.5 ml of anhydrous diethyl ether was added 6.06 ml of 1.3 N sec-butyllithium at -78°C. The resulting solution was stirred for 3 hours 45 minutes at -78°C, and a solution of 1.074 g of chloromethyl (N-trityl)imidazole 35 in 4 ml of tetrahydrofuran was added dropwise over 15 minutes. After 15 minutes of stirring at -78°C, the reaction mixture was slowly warmed to room temperature for over 1 hour. Saturated aqueous NH_4Cl solution was added. The mixture was extracted with ethyl acetate. The organic layer was separated, washed with brine, dried over anhydrous sodium sulfate and then concentrated. The residue was purified by flash chromatography on SiO_2 to give 0.23 g (17%) of product 36.

B.

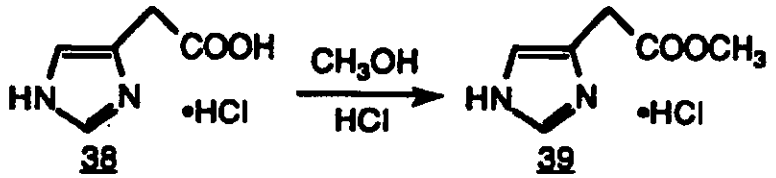


A solution of 0.23 g of 36 in 20 mL of 0.5 N HCl was heated to reflux for 45 minutes. After cooling to room tem-

perature, the mixture was extracted with diethyl ether three times. The aqueous solution was then concentrated and the crude product was crystallized with CH_3OH/diethyl ether to give 0.075 g (70% yield) of the product 37; MS (CI)152 (M+ 1).

EXAMPLE 7

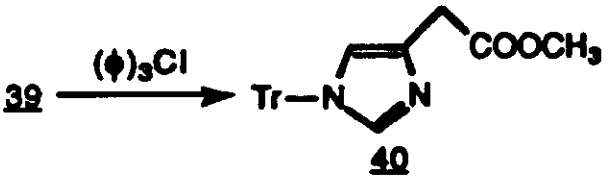
A.



38 39

To a solution of 11.59 g of imidazole acetic acid hydrochloride 38 in 100 mL of anhydrous methanol was added 1 mL of concentrated HCl. The resulting mixture was refluxed for 5.5 hours, and then cooled to room temperature. After concentration of the solvent, 11.9 g (95%) of the product 39 was isolated.

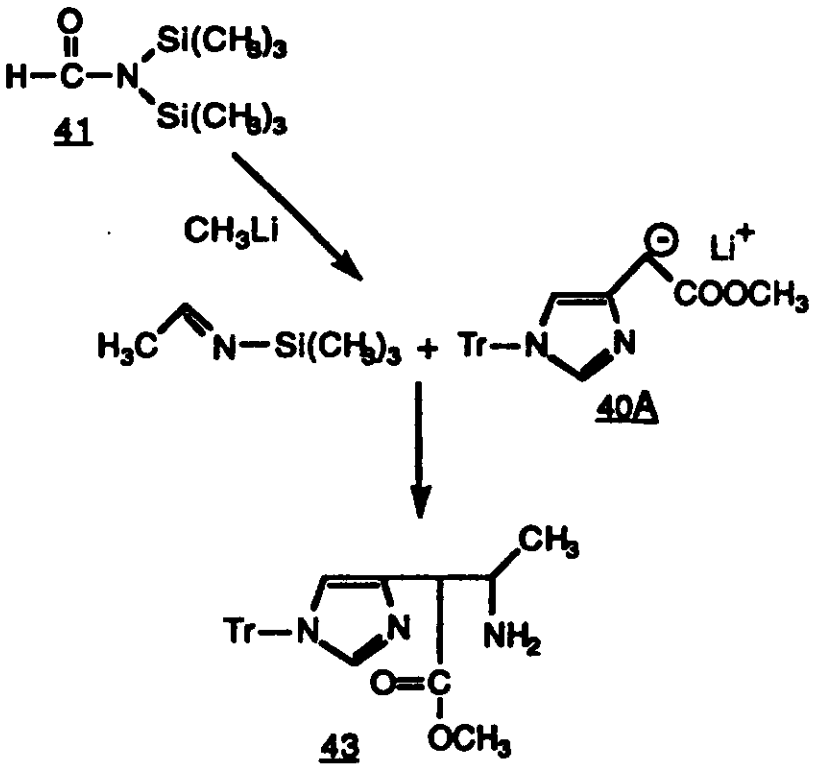
B.



40

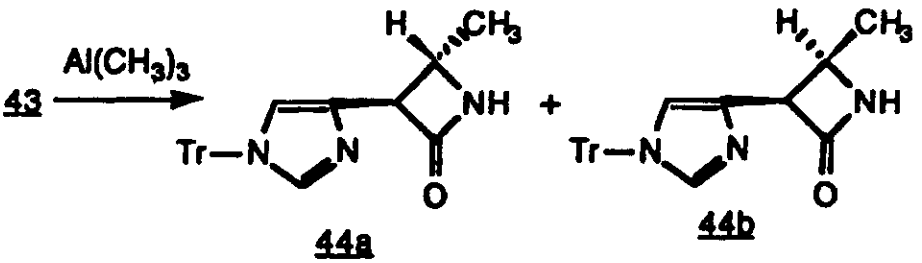
To a solution of 7.8 g of 39 in 70 mL of anhydrous DMF at 0°C was added 12.94 g of trityl chloride ($(\phi)_3Cl$) and 18.4 mL of triethyl amine. The resulting solution was stirred at room temperature for 24 hours, and the solvent was removed under vacuum. The residue was purified by flash chromatography on SiO_2 (eluting solvent: CH_2Cl_2 and increase polarity slowly by addition of ethyl acetate) to give 16.1 g of product 40 (95% yield).

C.



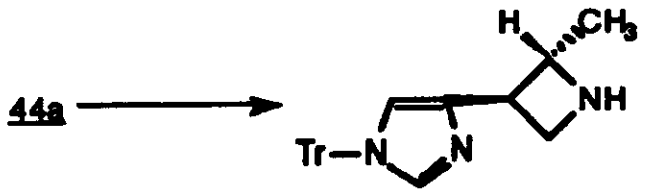
To a solution of 8.15 mL of compound 41 in 50 mL of anhydrous THF was added 26.25 mL of 1.4M methyllithium at -78°C. The above solution was stirred for 1 hour at -78°C, and a solution of 40A (prepared by the addition of 25 mL of 1M $LiN(Si(CH_3)_3)_2$ to a solution of 9.55 g of 40 in 100 mL of anhydrous THF at -78°C and stirring the solution for 2 hours at -78°C before transferring) was added by cannula over 30 minutes. Ten minutes later, 4.6 mL of $BF_3 \cdot (C_2H_5)_2O$ was added to the above mixture, and the resulting solution was stirred at -78°C for 2 hours. The reaction mixture was slowly warmed up to room temperature (over 2 hours 45 minutes), and then saturated aqueous $NaHCO_3$ solution was added. The organic layer was separated and the aqueous layer was extracted with EtOAc. The organic layer and EtOAc extracts were combined and the combined organic solution was washed with brine, dried over $MgSO_4$ and then concentrated. The residue was purified by flash chromatography (silica gel was deactivated with triethylamine, eluting solvent: 1 to 10 % of CH_3OH in EtOAc) to give compound 43 (6.4 g; 60% yield).

D.



To a solution of 6.4 g of 43 in 250 mL of anhydrous methylene chloride was added 11.3 mL of 2.OM trimethyl aluminum. The resulting mixture was stirred at room temperature for 45 minutes, heated to reflux (5 hours), cooled to 0°C, and to this mixture was added saturated aqueous $NaHCO_3$ solution. The organic layer was separated, washed with brine, dried over Na_2SO_4 and concentrated. The residue was purified by flash chromatography (silica gel deactivated with triethylamine; eluting solvent EtOAc to 1 to about 2% CH_3 OH in EtOAc) to give 0.91 g of 44a (trans isomer) and 0.39 g of 44b (cis isomer).

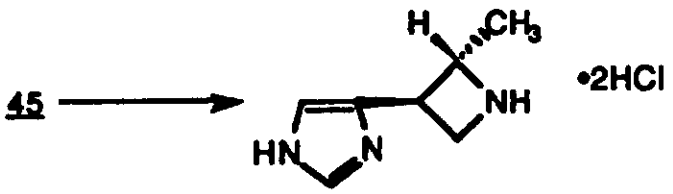
E.



45

To a solution of 0.3225 g of 44a in 8 mL of anhydrous THF was added 3.28 mL of 1M solution of diisobutylaluminum hydride in toluene dropwise at room temperature. After the addition was complete, the solution was refluxed for 2 hours and cooled to room temperature. Water (2 mL) was added slowly to the above solution and 20 ml of methylene chloride was added to the resulting mixture. The mixture was vigorously stirred until a white solid precipitated out. Filtration and concentration gave crude product, which was purified by preparative TLC (deactivated with triethylamine; eluting solvent 7.5% CH_3OH in CH_2Cl_2) to give 0.187 g (60% yield) of 45.

F.



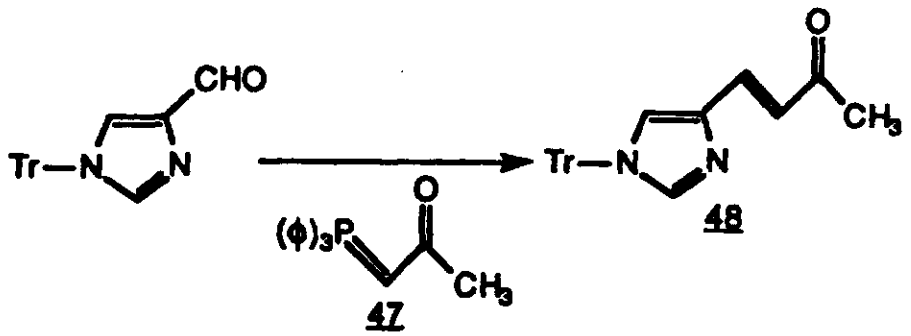
46

A solution of 0.148 g of 45 in 12 mL of 0.5N HCl was heated in an oil bath at 90°C for 0.5 hours. The solution was then cooled to room temperature. The mixture was extracted with diethyl ether three times, and the aqueous solution was concentrated to give a crude product. The crude product was recrystallized in CH_3OH/diethyl ether to give 70 mg (85%) of 46; MS (CI) 138 (M + 1).

By following the procedures set forth in Example 7, Steps E and F, compound 44b can be converted to the cis isomer of 46.

EXAMPLE 8

A.



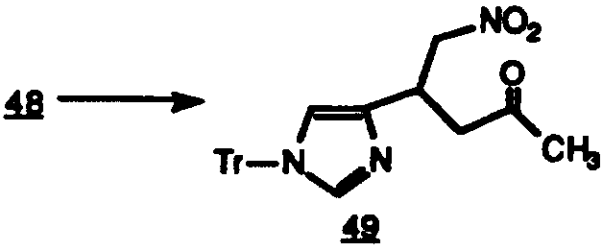
47

48

A mixture of 9.78 g of 4-(N-tritylimidazoyl) carboxaldehyde and 9.55 g of Wittig reagent 47 in 30 mL of anhydrous

THF was refluxed for 21 hours. An additional 4.8 g of Wittig reagent 47 and 10 mL of THF were added to the above mixture; the resulting mixture was continually refluxed for 30 hours. The solvent was concentrated. The residue was dissolved in CH_2Cl_2 and washed with water. The organic layer was separated and concentrated. The residue was purified by flash chromatography on SiO_2(CH_2Cl_2/EtOAc) to give 6.14 g (81% yield) of 48.

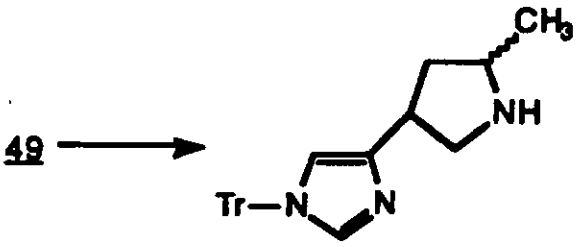
B.



49

To a mixture of 4.5 g of ketone 48 in 18 mL of CH_3CN was added 6.62 mL of nitromethane and 75 mL of THF. To the above homogenous solution was added 1.835 mL of DBU (1,8-diazabicyclo[5.4.0]undec-7-ene) and the resulting solution was stirred at room temperature overnight (18 hours). The reaction mixture was poured into ice cold 0.1 N HCl solution and the mixture was extracted with EtOAc. The combined EtOAc extracts were washed with brine, dried over $MgSO_4$ and concentrated to give 4.54 g (87%) of product 49.

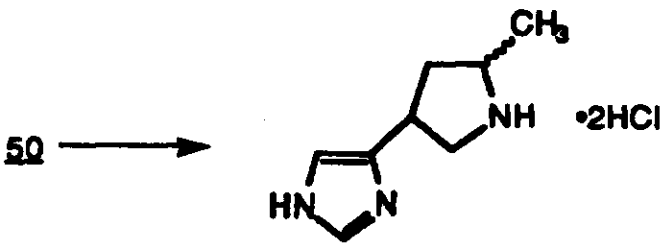
C.



50

Compound 49 was reduced by mixing 1.5 g of 49, 1.5 g of Raney-Ni and 1.5 g of anhydrous Na_2SO_4 in 50 mL of absolute ethanol and subjecting the resulting mixture to 60 psi. of H_2 for 26 hours. The reaction mixture was filtered through a pad of celite and the pad was washed with ethanol and CH_2Cl_2. The filtrate was concentrated to yield 0.83 g of 50 (62%).

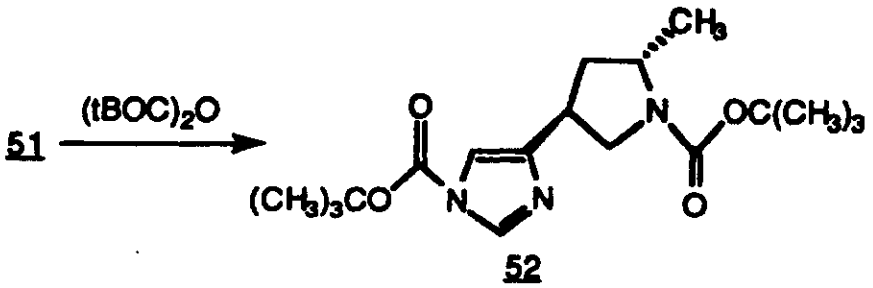
D.



51

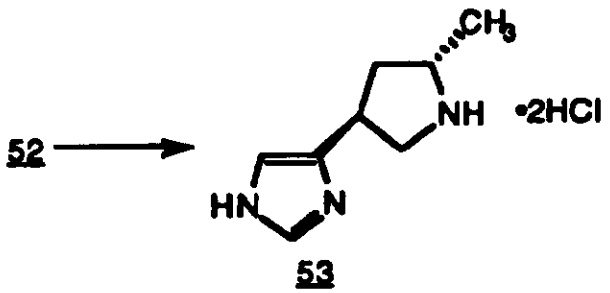
A solution of 0.83 g of 50 in 30 mL of 0.5N HCl was heated to reflux for 45 minutes. After the mixture was cooled to room temperature, it was extracted with diethyl ether. The aqueous layer was evaporated to dryness to give 0.43 g of crude product 51.

E.



To a mixture of 0.34 g of 51 in 5 mL of anhydrous DMF was added 1.69 mL of triethylamine; the mixture was stirred for 5 minutes and 0.77 mL of di-tert-butyldicarbonate ($(tBOC)_2O$)was added. The reaction mixture was stirred for 18 hours at room temperature, filtered and concentrated. The residue was dissolved in water and extracted with EtOAc. The combined organic extracts were washed with brine, dried over anhydrous Na_2SO_4 and concentrated. The residue was purified by preparative TLC (1:1 EtOAc/hexane) to give 0.13 g (24% yield) of 52; MS (m/e) 352 (M+1).

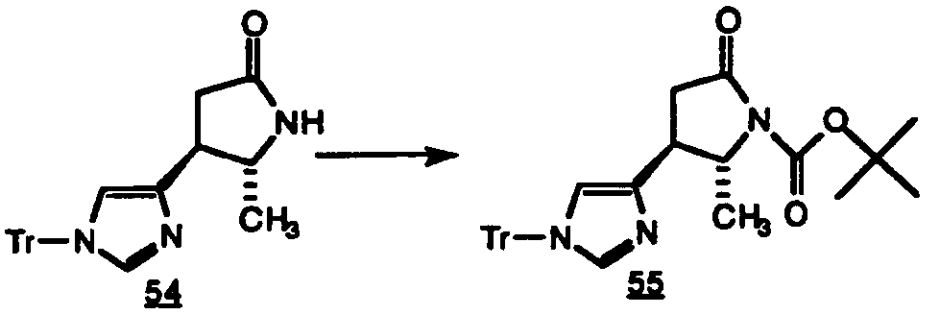
F.



A solution of 0.13 g of 52 in 6 mL of EtOAc (saturated with HCl) was stirred for 45 minutes at 0°C, then the solvent was evaporated under vacuum. The residue was recrystallized in 2-propanol/diethyl ether to give 0.067 (81% yield) of 53; MS (CI) 152 (M+1).

EXAMPLE 9

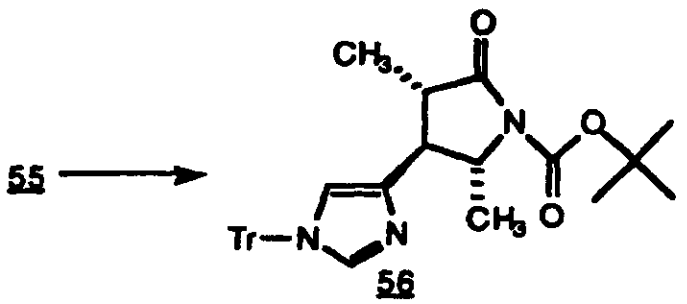
A.



To a solution of lactam 54 (10 mmole; 4.07g) (synthesized in a manner similar to 5t) in dry THF (55mL) at -78°C was added a solution of LDA (11 mmol, 1.18g) in THF (15 mL). After 45 minutes at this temperature, the reaction was warmed to room temperature for 20 minutes and then recooled to -78°C. A solution of $(tBOC)_2O$ (11 mmol, 2.41g) in THF (15mL) was added and the reaction was slowly warmed to room temperature. The reaction was then quenched with water and extracted into diethyl ether. The combined ether extracts were washed with brine and dried ($MgSO_4$).

Concentration yielded a solid that was recrystallized from hexane: 2-propanol. Compound 55, 3.5 g (69%), was obtained as an off-white solid.

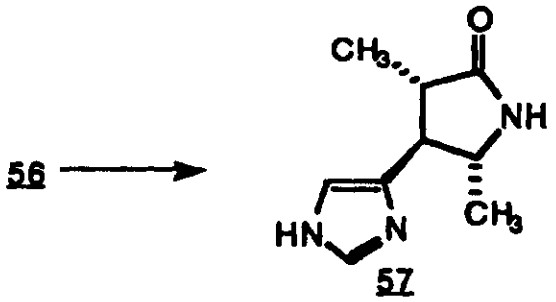
B.



56

To a solution of 55 (6.9 mmol, 3.5g) in dry THF (50 mL) at -78°C was added a solution of $KN(Si(CH_3)_3)_2$ (8.63 mmol, 1.72g) in THF (20 mL) over 10 minutes. An additional 10 mL THF was used to rinse the flask and syringe. After one hour at -78°C, neat CH_3I (8.63 mmol, 1.22g, filtered through basic alumina) was added, and the reaction was warmed to room temperature. After 2.5 hours, the reaction was recooled to -78°C, quenched with saturated NH_4Cl (pH = 7.3) and extracted into diethyl ether. The combined ether extracts were washed with brine and dried ($MgSO_4$). Concentration and purification via flash column chromatography (400 g SiO_2; 90:10 hexane: 2-propanol) yielded 56 (2.35 g; 65%).

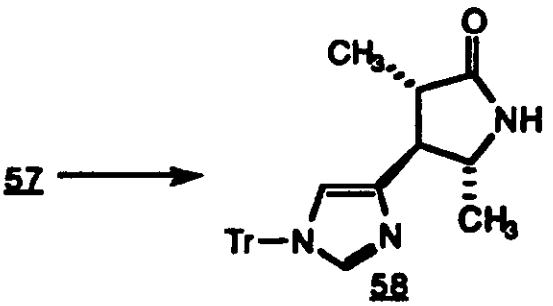
C.



57

To a solution of 56 (4.2 mmol, 2.19g) in dry $CHCl_3$ (40 mL) at room temperature was added iodotrimethylsilane (10.51 mmol, 2.1g). After one hour at 40°C, the reaction was diluted with methanol and concentrated on the rotary evaporator. Purification via flash chromatography (150 g, SiO_2, 80:10:10 CH_2Cl_2:2-propanol: methanol/ammonia) gave 600 mg (80%) of 57.

D.

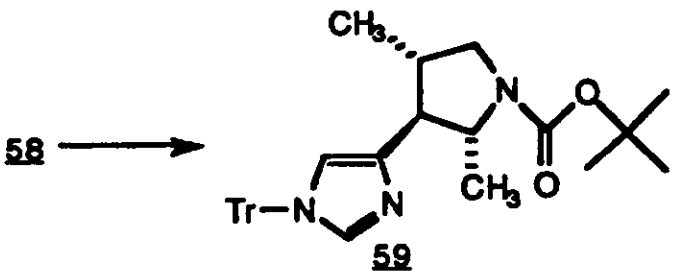


58

Compound 57 (3.6 mmol, 640 mg) was combined with trityl chloride (3.9 mmol, 1.48 g) and triethylamine (3.9 mmol, 0.39 g) in dry CH_2Cl_2 (25 mL) at room temperature under nitrogen. After 6 hours, the reaction was quenched with water and extracted with EtOAc/CH_2Cl_2 (4:1) (EtOAc represents ethyl acetate). The combined organic layers were

washed with saturated aqueous sodium metabisulfite and dried ($MgSO_4$). The crude material was purified on a flash column (175g SiO_2, 95:5 CH_2Cl_2 : methanol/ammonia) and yielded 900 mg (59%) of 58.

E.

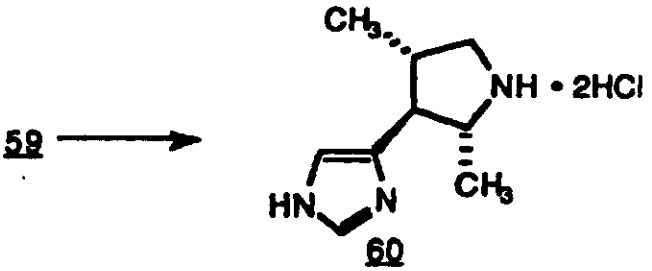


59

To a solution of 58 (2.14 mmol, 900mg) in dry THF (30 mL) was added a solution of LAH in diethyl ether (5.34 mL of a 1M solution). The reaction was heated to reflux for 2 hours, cooled to room temperature, diluted with diethyl ether, and quenched with saturated aqueous Na_2SO_4. Solid Na_2SO_4 was added and the mixture was filtered. The filter cake was washed with 150 mL of boiling THF. Removal of the solvent on the rotary evaporator yielded 920 mg of a crude solid.

To a solution of the crude solid (920 mg) from the previous reaction in THF (15 mL) was added $(t\text{-}BOC)_2O$ (2.7 mmol, 0.59g). After 30 minutes, the reaction was diluted with CH_2Cl_2, washed with water, and dried ($MgSO_4$). Concentration yielded a crude solid which was purified on a flash column (200 g SiO_2, 80:20 hexane : acetone). This material was further purified via HPLC (SiO_2, 97:3 hexane : 2-propanol) to give 230 mg (21%) of 59.

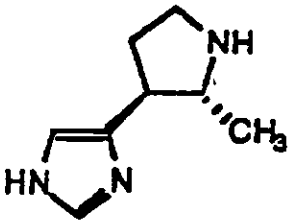
F.



60

Compound 59 (0.47 mmol, 230 mg) was combined with 15 mL 1N HCl and heated to 90°C for one hour. The reaction was cooled, filtered, and extracted with diethyl ether. The aqueous layer was concentrated in vacuo to give 60 (110 mg, 100%). MS (CI) 166 (M + 1).

The following are examples of pharmaceutical dosage forms which contain a compound of the invention. As used therein, the term "active compound" is used to designate the compound



Any compound of structural formula I can be used as active compound the pharmaceutical composition examples which follow.

Pharmaceutical Dosage Form Examples

EXAMPLE A

Tablets			
No.	Ingredients	mg/tablet	mg/tablet
1.	Active compound	100	500
2.	Lactose USP	122	113
3.	Corn Starch, Food Grade, as a 10% paste in Purified Water	30	40
4.	Corn Starch, Food Grade	45	40
5.	Magnesium Stearate	3	7
	Total	300	700

Method of Manufacture

Mix Item Nos. 1 and 2 in a suitable mixer for 10-15 minutes. Granulate the mixture with Item No. 3. Mill the damp granules through a coarse screen (e.g., 1/4", 0.63 cm) if necessary. Dry the damp granules. Screen the dried granules if necessary and mix with Item No. 4 and mix for 10-15 minutes. Add Item No. 5 and mix for 1-3 minutes. Compress the mixture to appropriate size and weigh on a suitable tablet machine.

EXAMPLE B

Capsules			
No.	Ingredient	mg/capsule	mg/capsule
1.	Active compound	100	500
2.	Lactose USP	106	123
3.	Corn Starch, Food Grade	40	70
4.	Magnesium Stearate NF	4	7
	Total	250	700

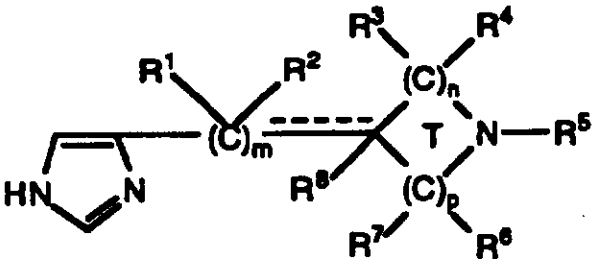
Method of Manufacture

Mix Item Nos. 1, 2 and 3 in a suitable blender for 10-15 minutes. Add Item No. 4 and mix for 1-3 minutes. Fill the mixture into suitable two-piece hard gelatin capsules on a suitable encapsulating machine.

While the present invention has been described in conjunction with the specific embodiments set forth above, many alternatives, modifications and variations thereof will be apparent to those of ordinary skill in the art. All such alternatives, modifications and variations are intended to fall within the spirit and scope of the present invention.

Claims

1. A compound of the formula:



(I)

or a pharmaceutically acceptable salt or solvate thereof, wherein:

(A) m is an integer selected from the group consisting of: 0, 1, and 2;
(B) n and p are integers and are each independently selected from the group consisting of: 0, 1, 2, and 3 such that the sum of n and p is 2 or 3 such that when the sum of n and p is 2, T is a 4-membered ring and when the sum of n and p is 3, T is a 5-membered ring;
(C) each R^1, R^2, R^3, R^4, R^6, R^7, and R^8 is independently selected from the group consisting of:

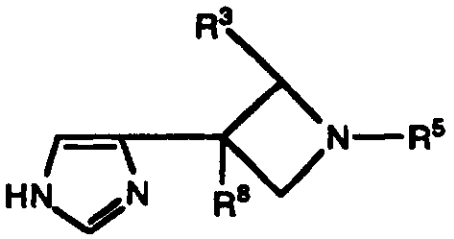
(1) H;
(2) C_1 to C_6 alkyl;
(3) C_3 to C_6 cycloalkyl; and
(4) $-(CH_2)_q-R^9$ wherein q is an integer of: 1 to 7, and R^9 is selected from the group consisting of: phenyl, substituted phenyl, $-OR^{10}$, $-C(O)OR^{10}$, $-C(O)R^{10}$, $-OC(O)R^{10}$, $-C(O)NR^{10}R^{11}$, CN and $-SR^{10}$ wherein R^{10} and R^{11} are as defined below, and wherein the substituents on said substituted phenyl are each independently selected from the group consisting of: -OH, -O-(C_1 to C_6)alkyl, halogen, C_1 to C_6 alkyl, $-CF_3$, -CN, and $-NO_2$, and wherein said substituted phenyl contains from 1 to 3 substituents;

(D) R^5 is selected from the group consisting of:

(1) H;
(2) C_1 to C_{20} alkyl;
(3) C_3 to C_6 cycloalkyl;
(4) $-C(O)OR^{10'}$; wherein $R^{10'}$ is the same as R^{10} defined below except that $R^{10'}$ is not H;
(5) $-C(O)R^{10}$;
(6) $-C(O)NR^{10}R^{11}$;
(7) allyl;
(8) propargyl; and
(9) $-(CH_2)_q-R^9$, wherein q and R^9 are as defined above with the proviso that when q is 1 then R^9 is not -OH or -SH;

(E) R^{10} and R^{11} are each independently selected from the group consisting of: H, C_1 to C_6 alkyl, and C_3 to C_6 cycloalkyl; and, for the substituent $-C(O)NR^{10}R^{11}$, R^{10} and R^{11}, together with the nitrogen to which they are bound, can form a ring having 5, 6, or 7 atoms;
(F) the dotted line (----) represents a double bond that is optionally present when m is 1, and T is a 5-membered ring, and n is not 0, and p is not 0, and when said double bond is present then R^2 and R^8 are absent;
(G) when m is 2, each R^1 is the same or different substituent for each m, and each R^2 is the same or different substituent for each m;
(H) when n is 2 or 3, each R^3 is the same or different substituent for each n, and each R^4 is the same or different substituent for each n; and
(I) when p is 2 or 3, each R^6 is the same or different substituent for each p, and each R^7 is the same or different substituent for each p.

2. The compound of Claim 1 wherein said compound is selected from the group consisting of compounds having the formula:



(II-1)

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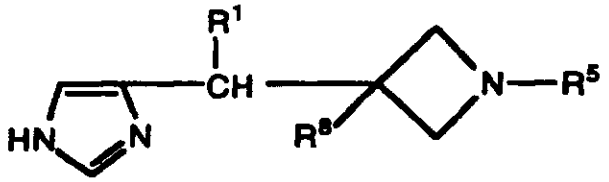

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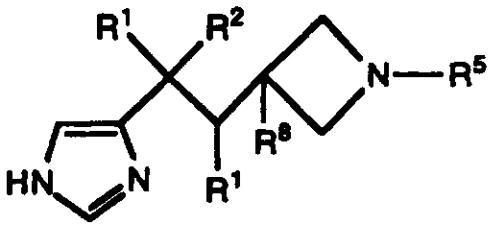

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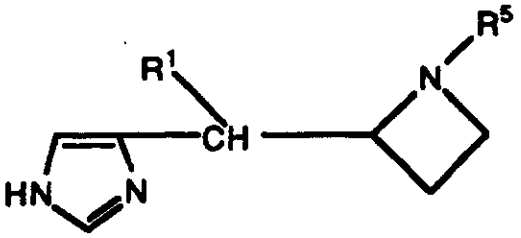

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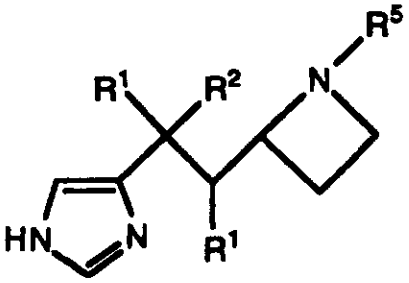
;

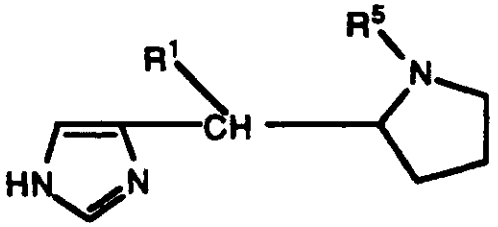
and



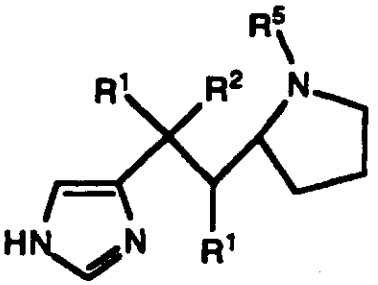
(IIA-2)

wherein R^1, R^2, R^3, R^5, and R^8 are as defined for Formula I.

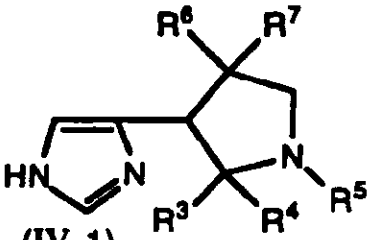
3. The compound of Claim 1 wherein said compound is selected from the group consisting of compounds having the formula:



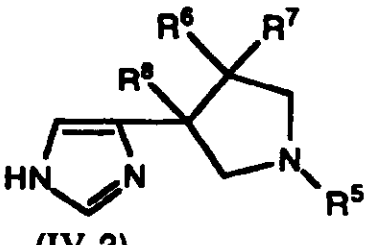
(III-1) ;



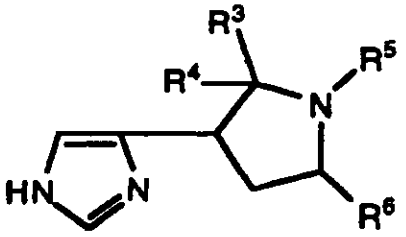
(III-2) ;



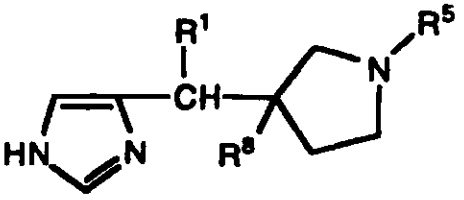
(IV-1) ;



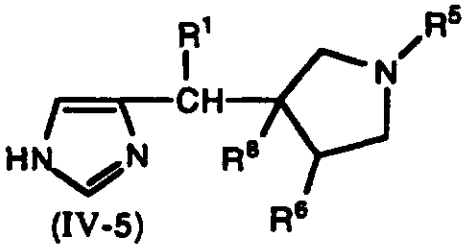
(IV-2) ;



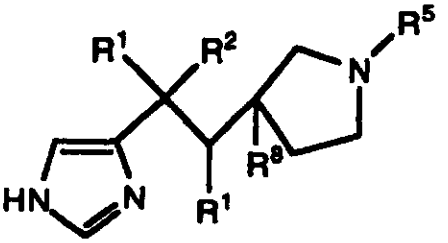
(IV-3) ;



(IV-4) ;

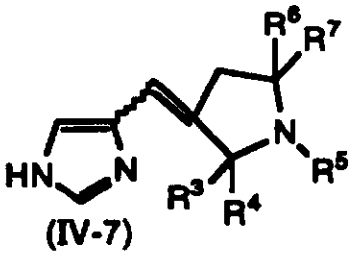


(IV-5) ;



(IV-6) ;

and



(IV-7)

wherein R^1, R^2, R^3, R^4, R^5, R^6, R^7, and R^8 are as defined for Formula I.

4. The compound of Claim 1 wherein m is 0 or 1.

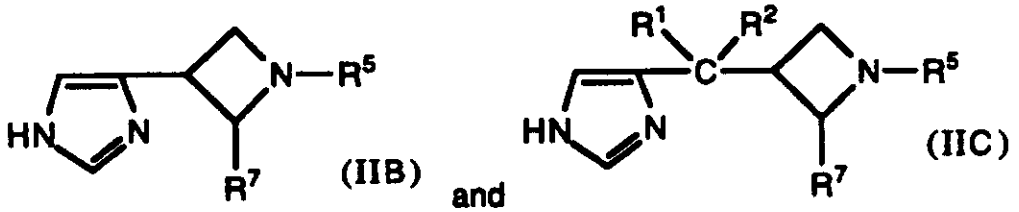
5. The compound of Claim 4 wherein R^5 is selected from the group consisting of H, C_1 to C_{20} alkyl and $(CH_2)_q$-R^9 wherein R^9 is phenyl.

6. The compound of Claim 5 wherein R^1 to R^4 and R^6 to R^8 are each independently selected from the group consisting of H, C_1 to C_6 alkyl, and -$(CH_2)_q$-R^9 wherein R^9 is phenyl.

7. The compound of Claim 6 wherein each R^1 to R^4 and R^6 to R^8 are independently selected from the group consisting of H, methyl, ethyl, pentyl, benzyl, and 2-phenylethyl.

8. The compound of Claim 7 wherein R^5 is H or methyl.

9. The compound of Claim 1 having the formula selected from the group consisting of:

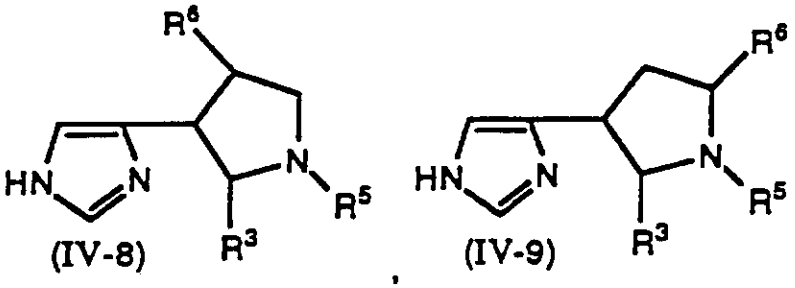


(IIB) and (IIC)

wherein R^7 is selected from the group consisting of H, C_1 to C_6 alkyl, and -$(CH_2)_q$-R^9 wherein R^9 is phenyl.

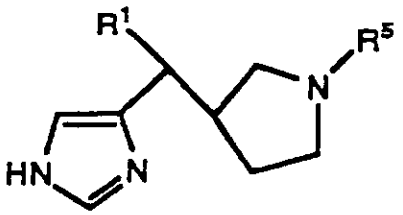
10. The compound of Claim 9 wherein R^7 is C_1 to C_6 alkyl, R^1 is H, and R^2 is H.

11. The compound of Claim 1 having the formula selected from the group consisting of:



(IV-8) (IV-9)

and



(IV-10)

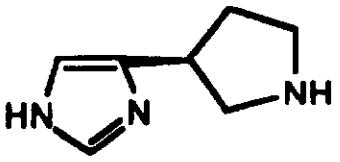
wherein R^5 is as defined in Claim 1 and R^1, R^3 and R^6 are each independently selected from the group consisting of H, C_1 to C_6 alkyl and $-(CH_2)_q-R^9$ wherein R^9 is phenyl.

12. The compound of Claim 11 wherein R^5 is selected from the group consisting of H and methyl.

13. The compound of Claim 12 wherein R^1 is H.

14. The compound of Claim 1 wherein said compound is selected from the group consisting of:

(A1)



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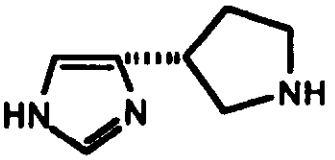
(A2)



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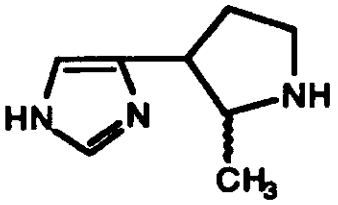
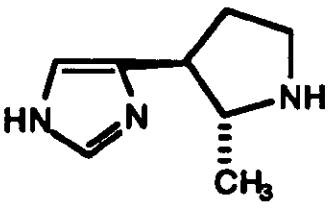
(B)



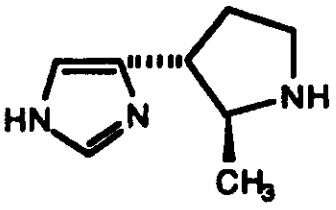
;

(B1)



;

(B2)



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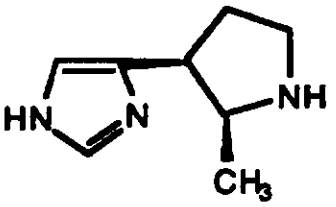
(B3)



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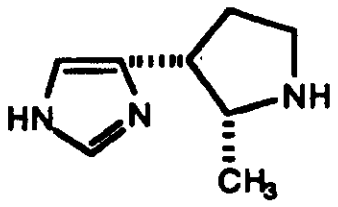
(B4)



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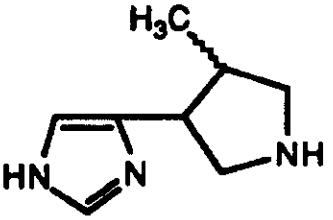
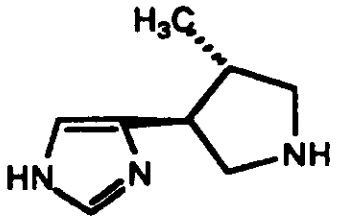
(C)



;

(C1)



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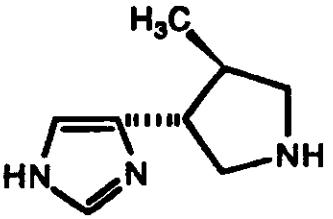
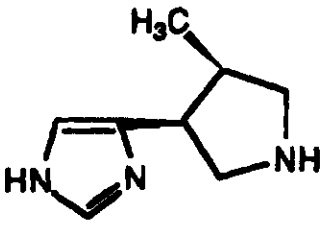
(C2)



;

(C3)



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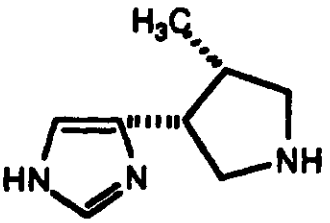
(C4)



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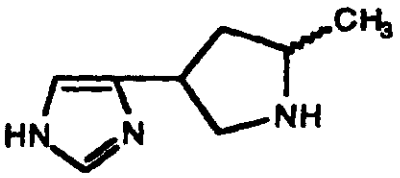
(D)



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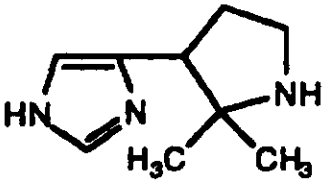
(E)



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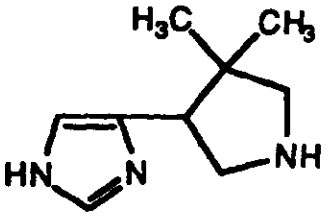
(F)



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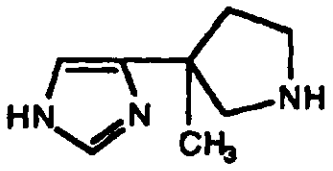
(G)



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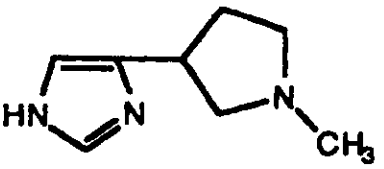
(H)



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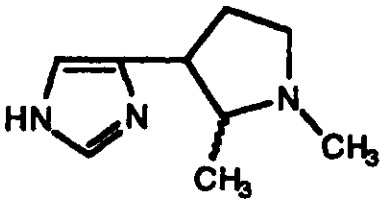
(I)



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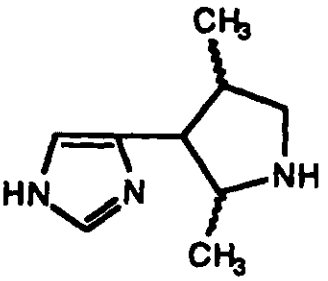
(J)



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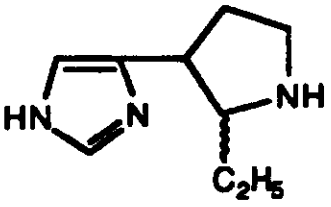
(K)



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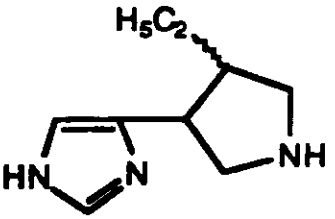
(L)



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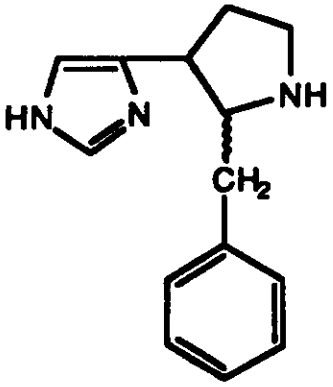
(M)



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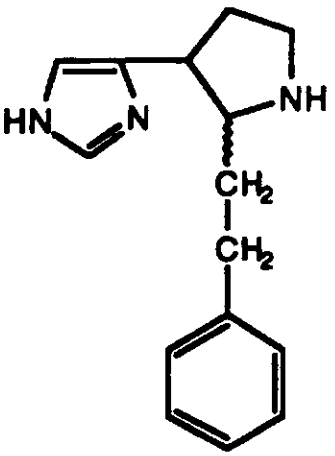
(N)



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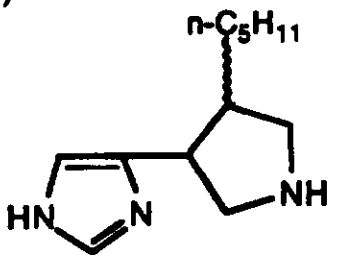
(O)



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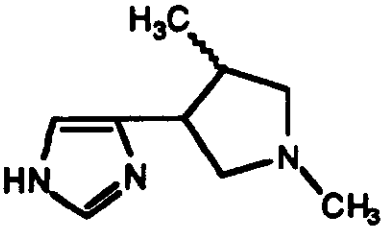
(P)



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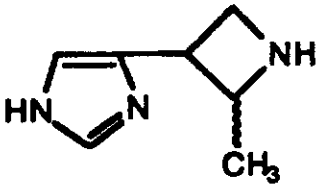
(Q)



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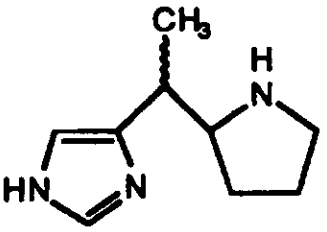
(R)



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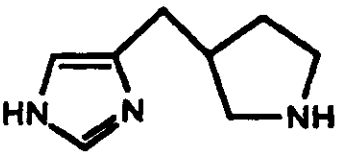
(S)



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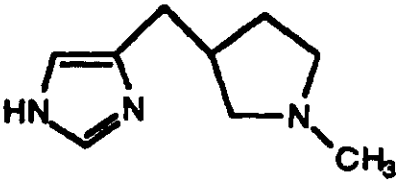
(T)



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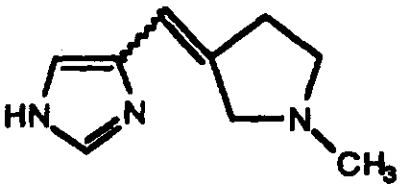
(U)



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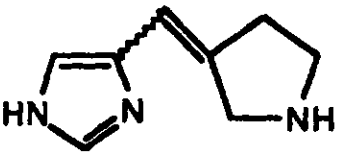
(V)



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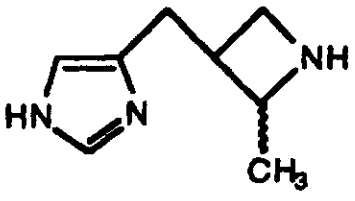
(W)



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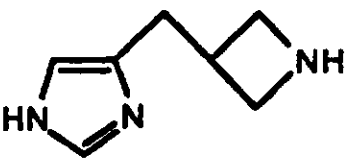
(X)



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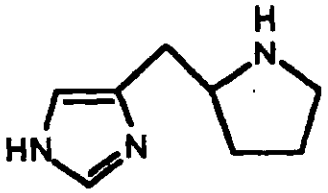
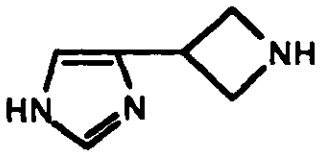
(Y)



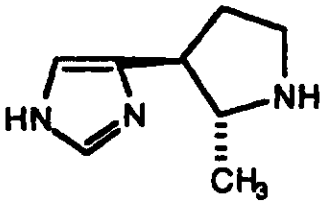
; and

(Z)



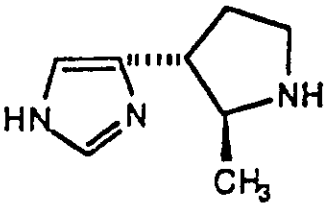
15. The compound of Claim 14 having the formula:

(B1)



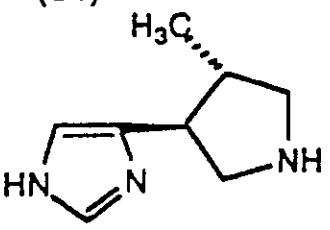
16. The compound of Claim 14 having the formula:

(B2)



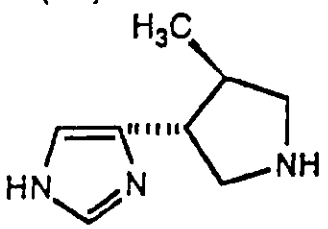
17. The compound of Claim 14 having the formula:

(C1)



18. The compound of Claim 14 having the formula:

(C2)

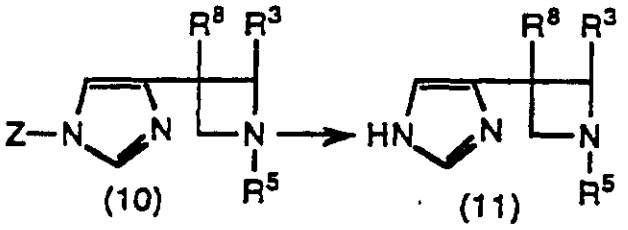


19. A pharmaceutical composition, for use as an H_3 receptor agonist or antagonist, comprising a pharmaceutically acceptable carrier and an effective amount of a Compound of Claim 1.

20. A method of preparing a pharmaceutical composition comprising admixing a compound of Claim 1 with a pharmaceutically acceptable carrier.

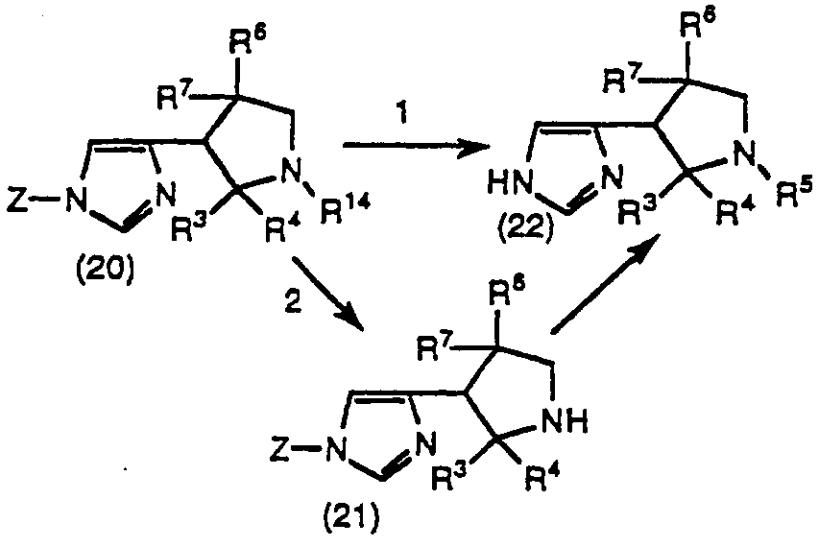
21. A process for preparing a compound of Claim 1 of the formula indicated , comprising a procedure selected from the following Procedures (I) to (IX):

(I)



1) deprotecting compound (10) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (11);

(II)



1) deprotecting compound (20) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (22), said reaction following reaction path 1 when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or

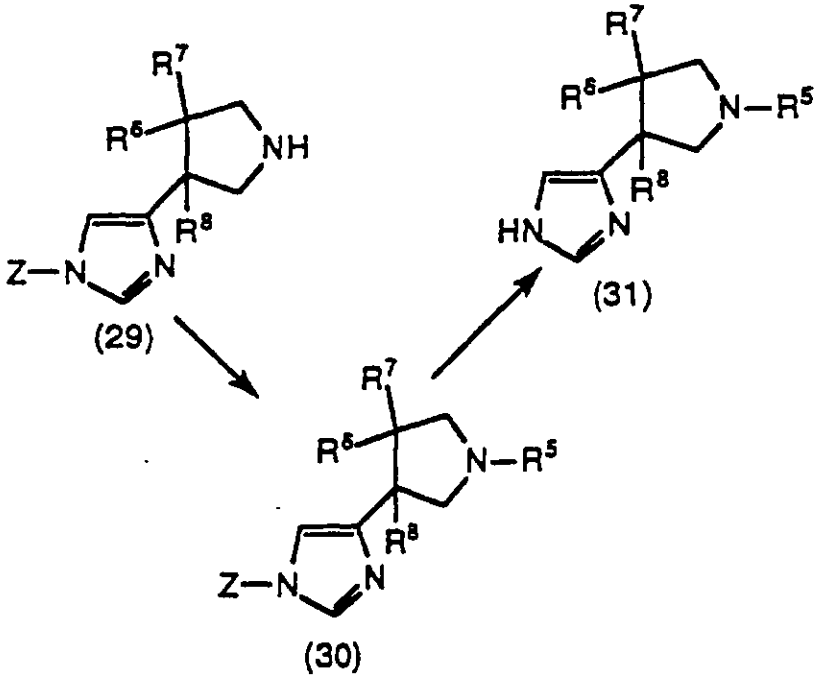
2)

(a) treating compound (20), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C to produce compound (21); or treating compound (20), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid to produce compound (21);

(b) reacting compound (21) with (i) R^5-X ,when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

(c) deprotecting the compound produced in 2)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (22);

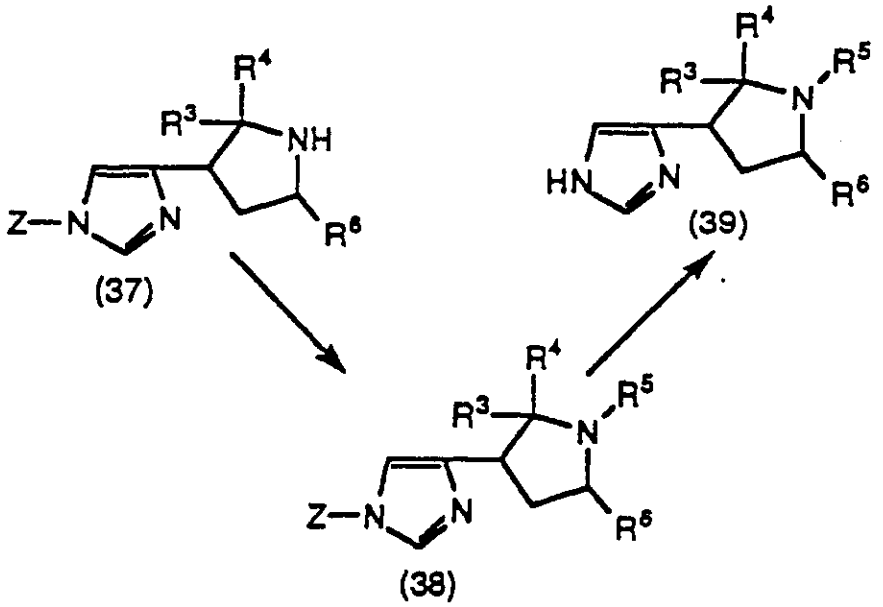
(III)



1) reacting compound (29) with (i) R^5-X ,when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C, to produce compound (30); and

2) deprotecting compound (30) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (31);

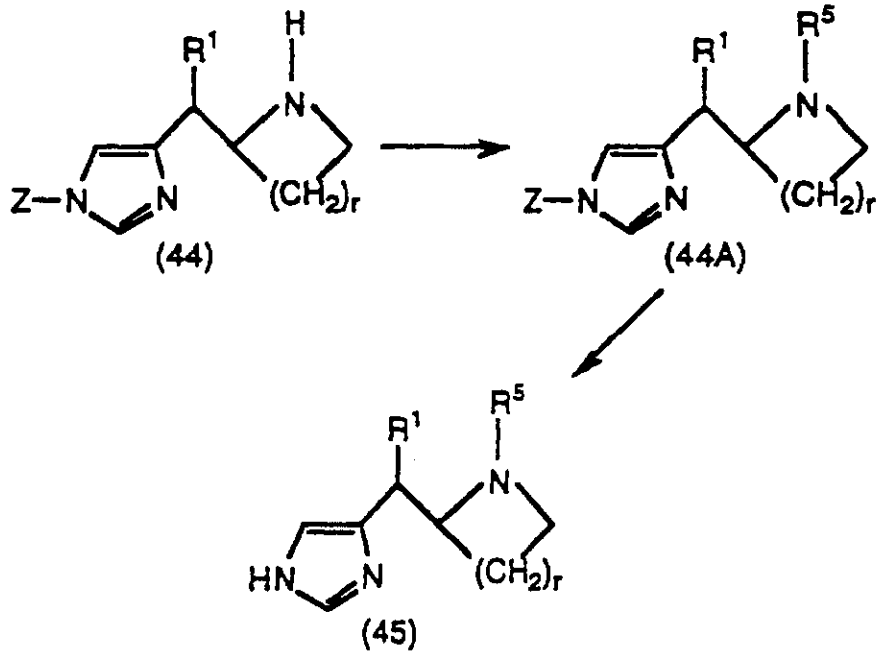
(IV)



1) reacting compound (37) with (i) R^5-X ,when R^5 is -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C, to produce compound (38); and

2) deprotecting compound (38) by treatment with dilute aqueous acid at a temperature of 25 to 100°C to produce compound (39);

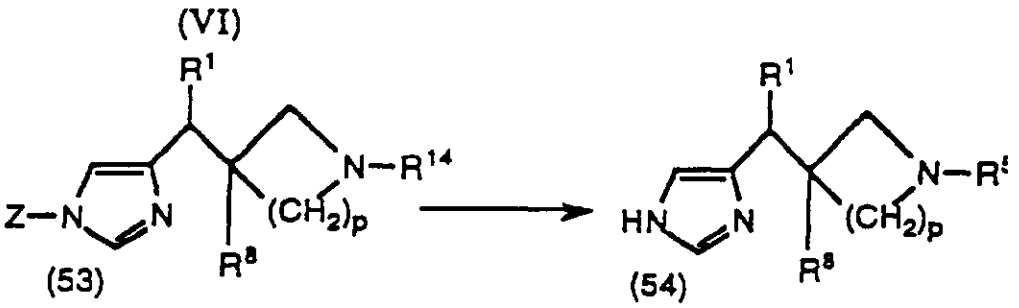
(V)



1) reacting compound (44), wherein r is 1 or 2, with (i) R^5-X,when R^5 is -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$

or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C, to produce compound (44A); and

2) deprotecting compound (44A) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (45);



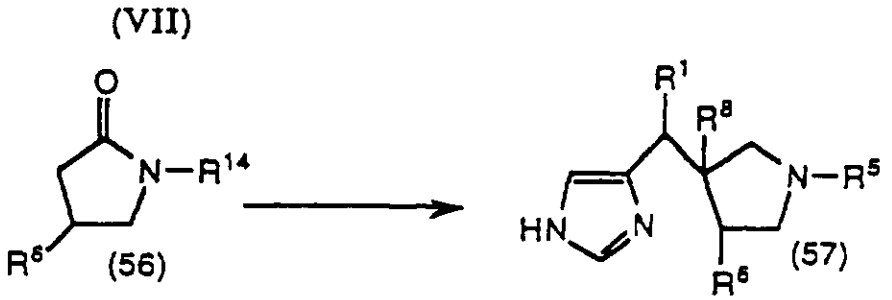
1) deprotecting compound (53), wherein p is 1 or 2, by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (54), said reaction being used when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or

2)

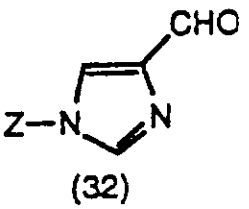
(a) treating compound (53), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C; or treating compound (53), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid;

(b) reacting the compound produced in 2)(a) with (i) R^5-X ,when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a sutable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and

(c) deprotecting the compound produced in 2)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (54);



1) preparing the anion of compound (56) by reacting compound (56) with a suitable base at a temperature of -20 to 20°C, and reacting said anion with compound (32)

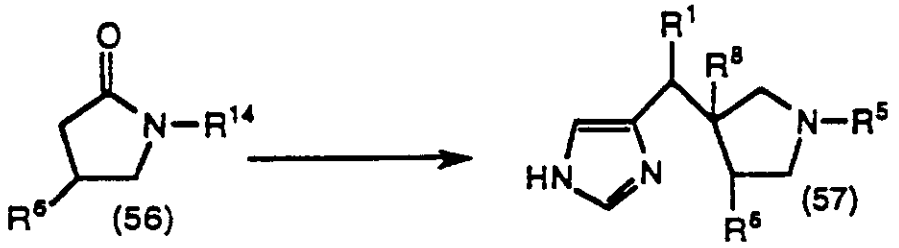


in an organic solvent at a temperature of -78 to 25°C;

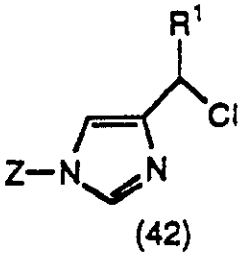
2) reacting the product of 1) with R^1-Q, wherein Q is Li or MgBr, in a suitable solvent containing CuCN and a Lewis acid, said reaction is conducted at a temperature of -78 to 20°C;
3) reacting the enolate of the product of 2) with R^8-L wherein L represents a suitable leaving group, in an organic solvent, said reaction is conducted at a temperature of 0 to 50°C;
4) reducing the resulting R^8 substituted compound from 3) with $LiAlH_4$ at a temperature of 25 to 65°C in an organic solvent;
5) deprotecting the reaction product of 4) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (57), said reaction being used when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or
6)

(a) treating the reaction product of 4), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C; or treating the reaction product of 4), when R^{14} is -C(O)O(t-butyl), with dilute aqueous acid;
(b) reacting the compound produced in 6)(a) with (i) R^5-X ,when R^5 is $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less $-CH_2-$ group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and
(c) deprotecting the compound produced in 6)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (57);

(VIII)



1) preparing the anion of compound (56) by reacting compound (56) with a suitable base at a temperature of -20 to 20°C, and reacting said anion with compound 42

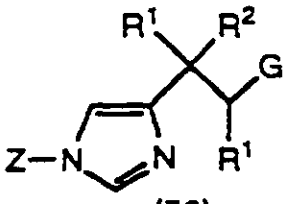


in a suitable solvent at a temperature of -78 to 25°C
2) reacting the enolate of the product of 1) with R^8-L, wherein L represents a suitable leaving group, in an organic solvent, said reaction is conducted at a temperature of 0 to 50°C;
3) reducing the resulting R^8 substituted compound from 2) with $LiAlH_4$ at a temperature of 25 to 65°C in an organic solvent;
4) deprotecting the reaction product of 3) by treatment with dilute aqueous acid, at a temperature of 25 to 90°C, to produce compound (57), said reaction being used when R^{14} is alkyl, cycloalkyl, benzyl, substituted benzyl, allyl or propargyl; or
5)

(a) treating the reaction product of 3), when R^{14} is $-Si(CH_3)_2C(CH_3)_3$, with tetrabutylammonium fluoride in tetrahydrofuran at a temperature of 0 to 50°C; or treating the reaction product of 3), when R^{14} is -C(O)

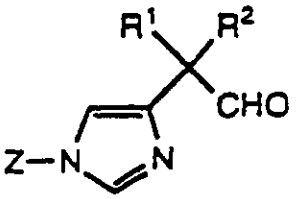
O(t-butyl), with dilute aqueous acid;
(b) reacting the compound produced in 5)(a) with (i) R^5-X ,when R^5 is -C(O)R^{10}, -C(O)$OR^{10'}$, -C(O)$NR^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CHO, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and
(c) deprotecting the compound produced in 5)(b) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (57);

(IX) using compound (58):



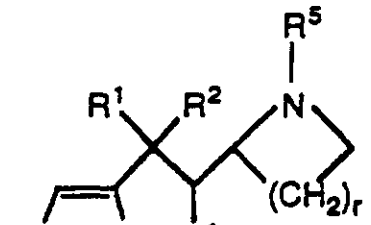
(58)

in place of compound (42) and compound (59):



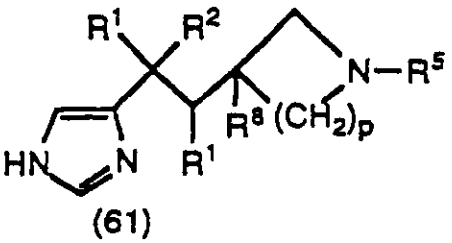
(59)

in place of compound (32) to produce compound (60):



(60)

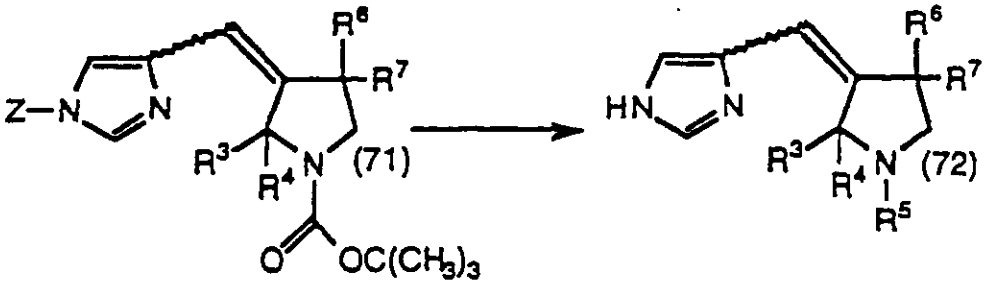
by following the steps in (V) above, or to produce compound (61)



(61)

by following the steps in (VI) above, wherein for compound (60) r is 1 or 2 and for compound (61) p is 1 or 2, and wherein G in compound (58) represents a suitable leaving group;

(X)



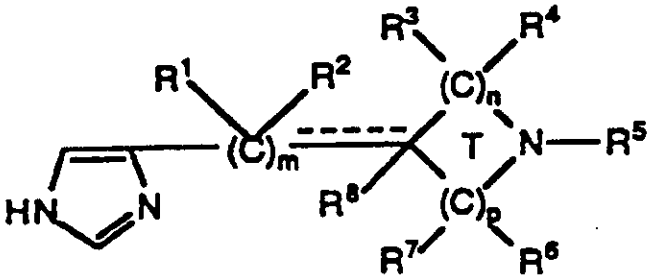
1) treating compound (71) with acid in an inert organic solvent at a temperature of 0°C to cause selective deprotection of the pyrrolidine ring;
2) reacting the reaction product of 1) with (i) R^5-X, when R^5 is -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ or alkyl in an organic solvent optionally in the presence of a suitable base; or (ii) with R^{5A}-CH, when R^5 is alkyl, cycloalkyl, allyl, propargyl, benzyl or substituted benzyl, under hydrogenating conditions, or in the presence of $NaBH_3(CN)$, in an organic solvent; wherein R^{5A} represents an R^5 group that has one less -CH_2- group and X represents a suitable leaving group; said reaction (i) or (ii) being performed at a temperature within the range of -30 to 80°C; and
2) deprotecting the reaction product of 2) by treatment with dilute aqueous acid at a temperature of 25 to 90°C to produce compound (72); or

(XI) Preparing compounds of Claim 1, wherein R^5 is H, by reacting an intermediate compound of one of the above process steps (I), (II), (III), (IV), (V), (VI), (VII), (VII), (VIII), (IX), or (X), with aqueous acid, at a temperature of 25 to 100°C, said intermediate compound having the imidazole nitrogen protected by Z and having the nitrogen of the cyclic four or five membered amine substituted with -C(O)O(t-butyl) or unsubstituted.

22. Use of a compound or formula I according to any of Claims 1-18 in the manufacture of a medicament for use as an H_3 receptor agonist or antagonist.

Patentansprüche

1. Verbindung der Formel:



(I)

oder ein pharmazeutisch annehmbares Salz oder Solvat derselben, worin:

(A) m eine aus der aus 0, 1 und 2 bestehenden Gruppe ausgewählte ganze Zahl ist,
(B) n und p ganze Zahlen sind und jeweils unabhängig derart aus der aus 0, 1, 2 und 3 bestehenden Gruppe ausgewählt sind, daß die Summe von n und p 2 oder 3 ist, so daß wenn die Summe von n und p 2 ist, T ein 4-gliedriger Ring ist und wenn die Summe von n und p 3 ist, T ein 5-gliedriger Ring ist,
(C) R^1, R^2, R^3, R^4, R^6, R^7 und R^8 jeweils unabhängig aus der Gruppe ausgewählt sind, die aus

(1) H,
(2) C_1- bis C_6-Alkyl,
(3) C_3- bis C_6-Cycloalkyl und

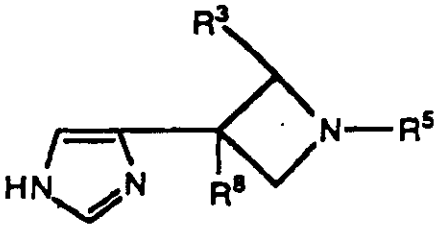
(4) -$(CH_2)_q$-R^9 besteht, worin q eine ganze Zahl von 1 bis 7 ist, und R^9 aus der Gruppe ausgewählt ist, die aus Phenyl, substituiertem Phenyl, -OR^{10}, -$C(O)OR^{10}$, -$C(O)R^{10}$, -$OC(O)R^{10}$, -$C(O)NR^{10}R^{11}$, CN und -SR^{10} besteht, worin R^{10} und R^{11} wie nachstehend definiert sind und worin die Substituenten an dem substituierten Phenyl jeweils unabhängig aus der Gruppe ausgewählt sind, die aus - OH, -O-(C_1- bis C_6-) Alkyl, Halogen, C_1- bis C_6-Alkyl, - CF_3, -CN und -NO_2 besteht, und wobei das substituierte Phenyl 1 bis 3 Substituenten enthält,

(D) R^5 aus der Gruppe ausgewählt ist, die aus

(1) H,
(2) C_1- bis C_{20}-Alkyl,
(3) C_3- bis C_6-Cycloalkyl,
(4) -$C(O)OR^{10'}$, worin R^{10} das gleiche wie das nachstehend definierte R^{10} ist, ausgenommen, daß $R^{10'}$ nicht H ist,
(5) -$C(O)R^{10}$,
(6) -$C(O)NR^{10}R^{11}$,
(7) Allyl,
(8) Propargyl und
(9) -$(CH_2)_q$-R^9 besteht, worin q und R^9 wie vorstehend definiert sind, mit der Maßgabe, daß wenn q 1 ist, R^9 nicht -OH oder -SH ist,

(E) R^{10} und R^{11} jeweils unabhängig aus der Gruppe ausgewählt sind, die aus H, C_1- bis C_6-Alkyl und C_3- bis C_6-Cycloalkyl besteht und worin bei dem Substituenten -$C(O)NR^{10}R^{11}$ R^{10} und R^{11} zusammen mit dem Stickstoff, an den sie gebunden sind, einen Ring mit 5, 6 oder 7 Atomen bilden können,
(F) die gepunktete Linie (•••••) eine Doppelbindung darstellt, die gegebenenfalls vorhanden ist, wenn m 1 ist und T ein 5-gliedriger Ring ist und n nicht 0 ist und p nicht 0 ist, und wenn die Doppelbindung vorhanden ist, R^2 und R^8 dann abwesend sind,
(G) wenn m 2 ist, R^1 für jedes m jeweils der gleiche oder ein unterschiedlicher Substituent ist und R^2 für jedes m jeweils der gleiche oder ein unterschiedlicher Substituent ist,
(H) wenn n 2 oder 3 ist, R^3 für jedes n jeweils der gleiche oder ein unterschiedlicher Substituent ist und R^4 für jedes n jeweils der gleiche oder ein unterschiedlicher Substituent ist und
(I) wenn p 2 oder 3 ist, R^6 für jedes p jeweils der gleiche oder ein unterschiedlicher Substituent ist und R^7 für jedes p jeweils der gleiche oder ein unterschiedlicher Substituent ist.

2. Verbindung von Anspruch 1, wobei die Verbindung aus der Gruppe ausgewählt ist, die aus Verbindungen mit der Formel:



(II-1)

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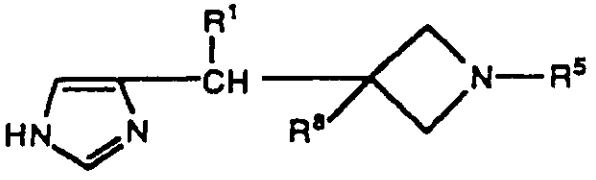

(II-2)

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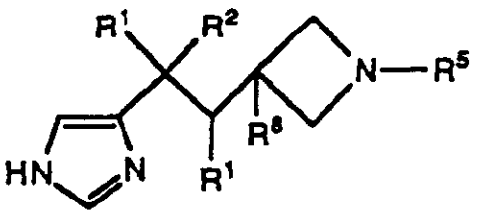

(II-3)

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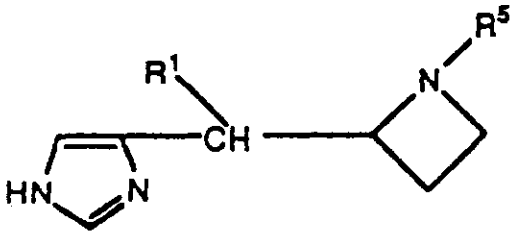
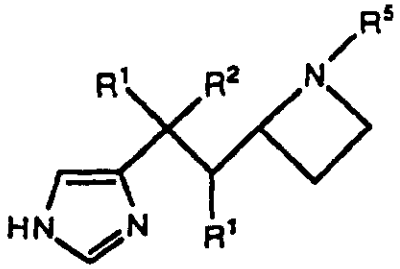


(IIA-1)

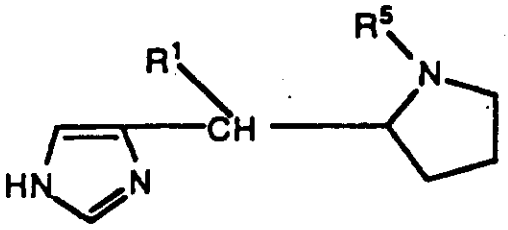
und



(IIA-2)

besteht, worin R^1, R^2, R^3, R^5 und R^8 wie für Formel I definiert sind.

3. Verbindung von Anspruch 1, wobei die Verbindung aus der Gruppe ausgewählt ist, die aus Verbindungen mit der Formel:



(III-1)

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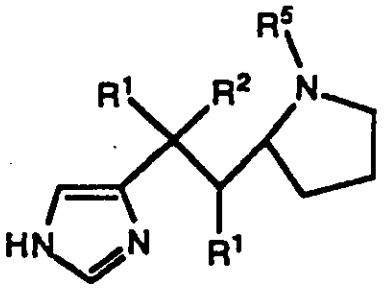

(III-2)

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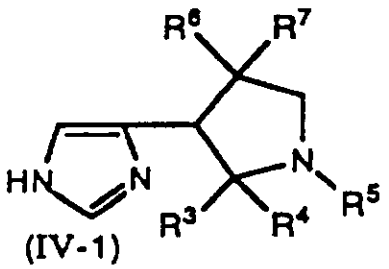
(IV-1)

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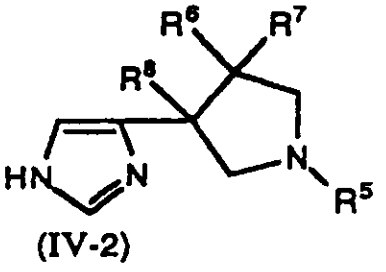
(IV-2)

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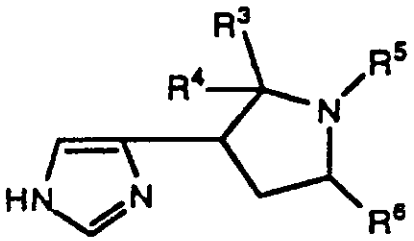
(IV-3)

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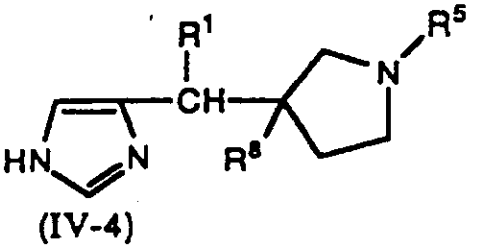
(IV-4)

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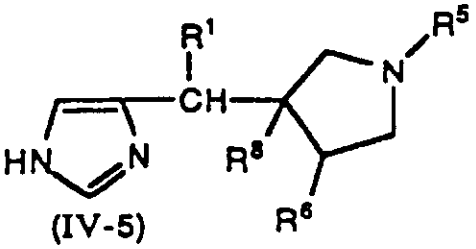
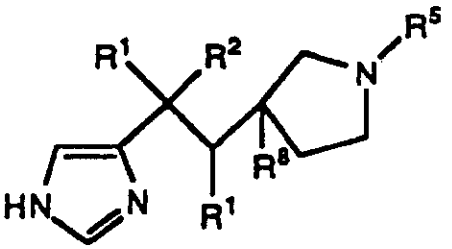
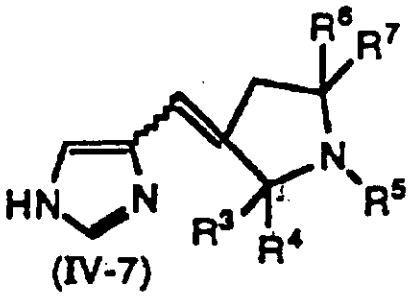

(IV-5)

;


(IV-6)

;

und


(IV-7)

besteht, worin R^1, R^2, R^3, R^4, R^5, R^6, R^7 und R^8 wie für Formel I definiert sind.

4. Verbindung von Anspruch 1, worin m 0 oder 1 ist.

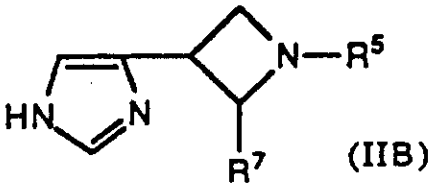
5. Verbindung von Anspruch 4, worin R^5 aus der Gruppe ausgewählt ist, die aus H, C_1- bis C_{20}-Alkyl und $(CH_2)_q$-R^9 besteht, worin R^9 Phenyl ist.

6. Verbindung von Anspruch 5, worin R^1 bis R^4 und R^6 bis R^8 jeweils unabhängig aus der Gruppe ausgewählt sind, die aus H, C_1-bis C_6-Alkyl und -$(CH_2)_q$-R^9 besteht, worin R^9 Phenyl ist.

7. Verbindung von Anspruch 6, worin R^1 bis R^4 und R^6 bis R^8 unabhängig aus der Gruppe ausgewählt sind, die aus H, Methyl, Ethyl, Pentyl, Benzyl und 2-Phenylethyl besteht.

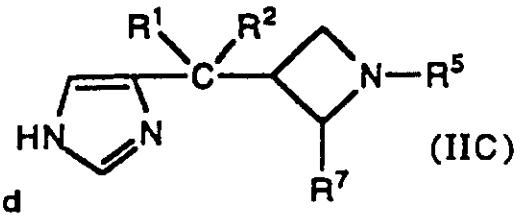
8. Verbindung von Anspruch 7, worin R^5 H oder Methyl ist.

9. Verbindung von Anspruch 1 mit der Formel, die aus der Gruppe ausgewählt ist, welche aus:



(IIB)

und

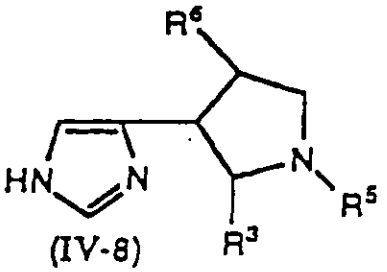


(IIC)

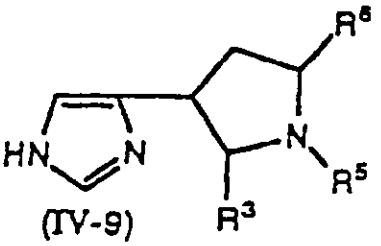
besteht, worin R^7 aus der Gruppe ausgewählt ist, die aus H, C_1-bis C_6-Alkyl und $-(CH_2)_q-R^9$ besteht, worin R^9 Phenyl ist.

10. Verbindung von Anspruch 9, worin R^7 C_1- bis C_6-Alkyl ist, R^1 H ist und R^2 H ist.

11. Verbindung von Anspruch 1 mit der Formel, die aus der Gruppe ausgewählt ist, die aus



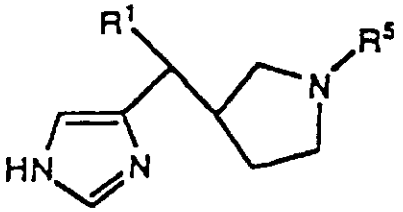
(IV-8)



(IV-9)

;

und



(IV-10)

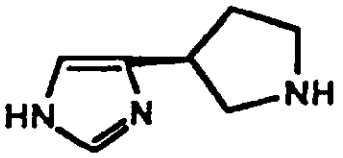
besteht, worin R^5 wie in Anspruch 1 definiert ist und R^1, R^3 und R^6 jeweils unabhängig aus der Gruppe ausgewählt sind, die aus H, C_1- bis C_6-Alkyl und $-(CH_2)_q-R^9$ besteht, worin R^9 Phenyl ist.

12. Verbindung von Anspruch 11, worin R^5 aus der aus H und Methyl bestehenden Gruppe ausgewählt ist.

13. Verbindung von Anspruch 12, worin R^1 H ist.

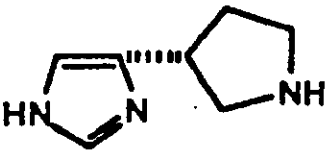
14. Verbindung von Anspruch 1, wobei die Verbindung aus der Gruppe ausgewählt ist, die aus:

(A1)



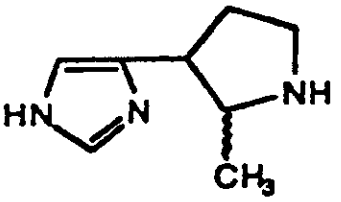
;

(A2)



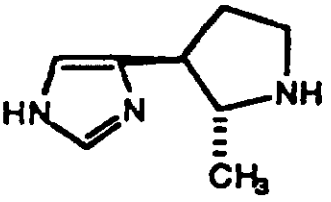
;

(B)



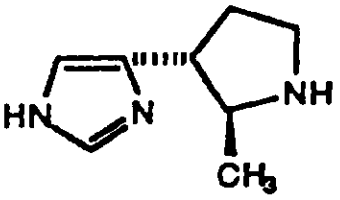
;

(B1)



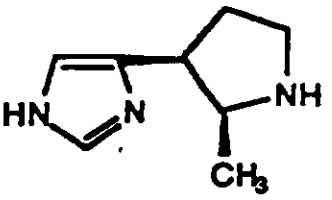
;

(B2)



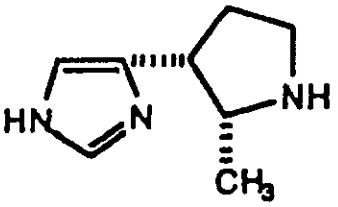
;

(B3)



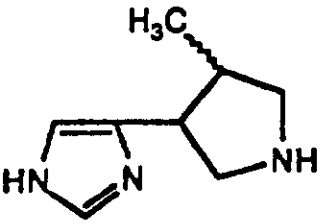
;

(B4)



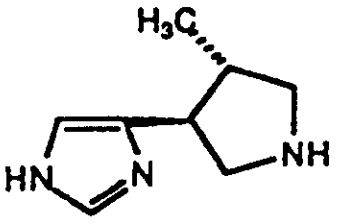
;

(C)



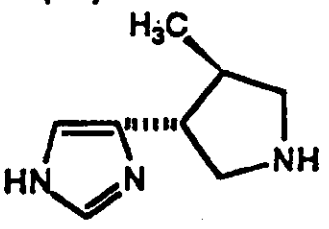
;

(C1)



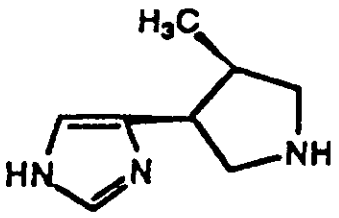
;

(C2)



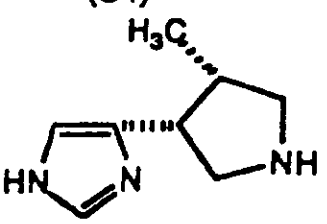
;

(C3)



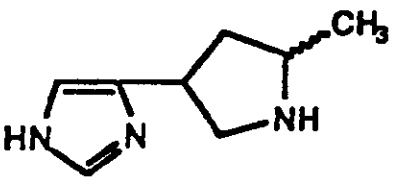
;

(C4)



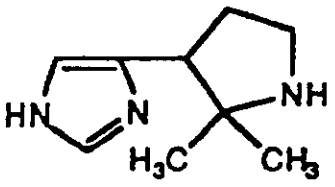
;

(D)



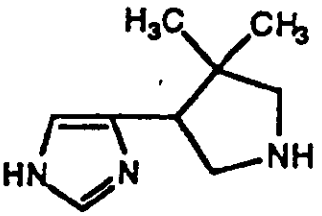
;

(E)



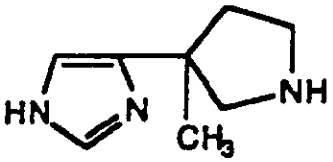
;

(F)



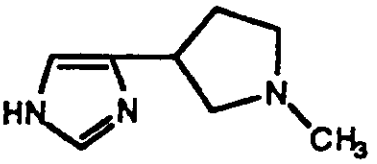
;

(G)



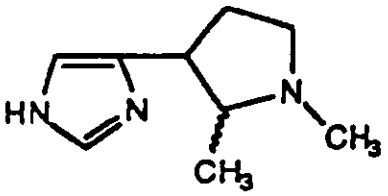
;

(H)



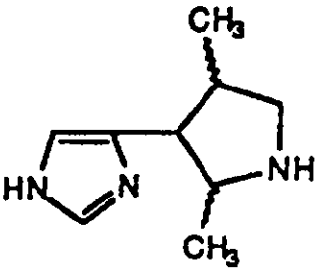
;

(I)



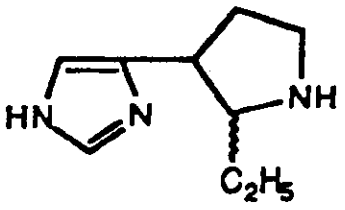
;

(J)



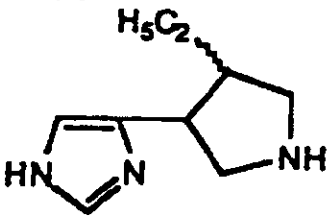
;

(K)



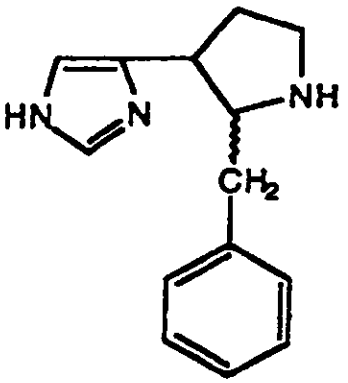
;

(L)



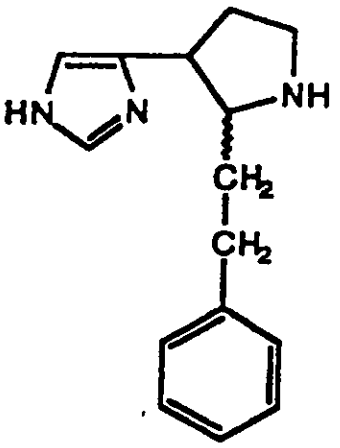
;

(M)



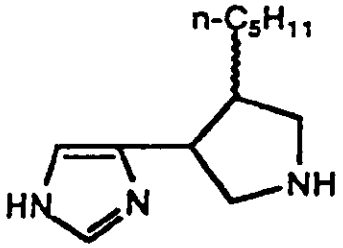
;

(N)



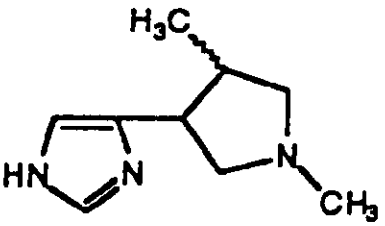
;

(O)



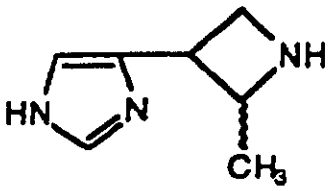
;

(P)



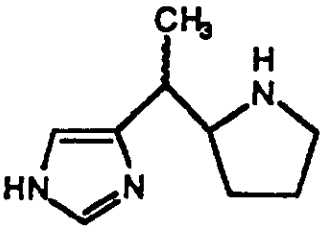
;

(Q)



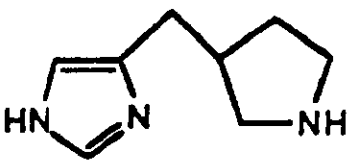
;

(R)



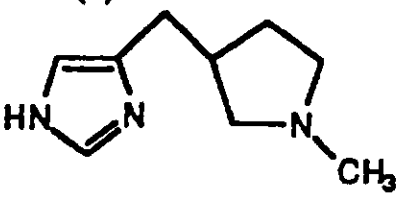
;

(S)



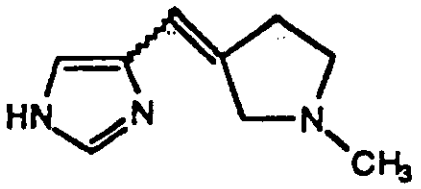
;

(T)



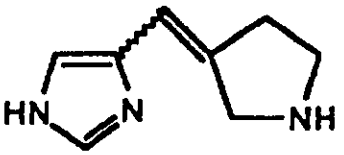
;

(U)



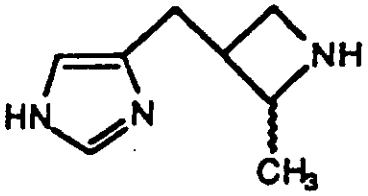
;

(V)



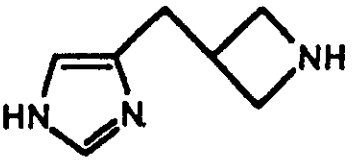
;

(W)



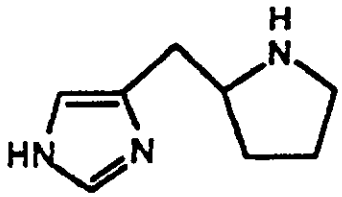
;

(X)



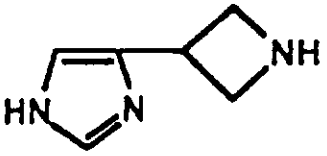
;

(Y)



und

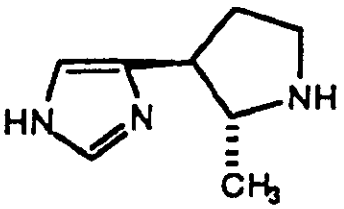
(Z)



besteht.

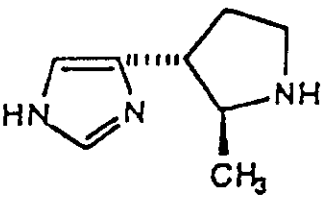
15. Verbindung von Anspruch 14 mit der Formel

(B1)



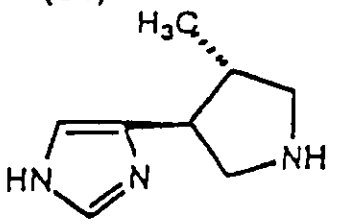
16. Verbindung von Anspruch 14 mit der Formel

(B2)



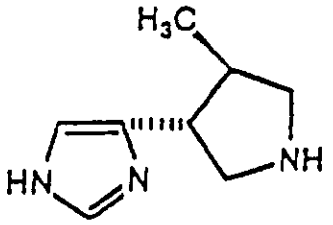
17. Verbindung von Anspruch 14 mit der Formel

(C1)



18. Verbindung von Anspruch 14 mit der Formel

(C2)

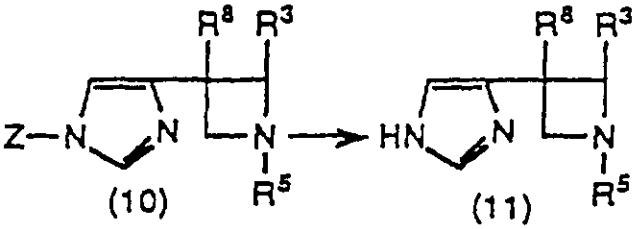


19. Pharmazeutische Zusammensetzung zur Verwendung als H_3-Rezeptoragonist oder -antagonist, welche einen pharmazeutisch annehmbaren Träger und eine wirksame Menge einer Verbindung von Anspruch 1 umfaßt.

20. Verfahren zum Herstellen einer pharmazeutischen Zusammensetzung, welches das Vermischen einer Verbindung von Anspruch 1 mit einem pharmazeutisch annehmbaren Träger umfaßt.

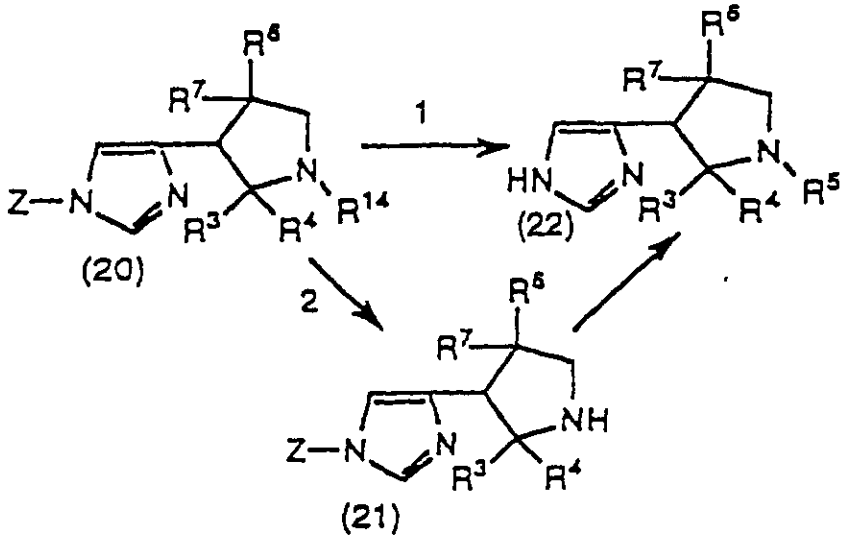
21. Verfahren zum Herstellen einer Verbindung von Anspruch 1 der angegebenen Formel, welches ein Verfahren umfaßt, das aus den folgenden Verfahren (I) bis (IX) ausgewählt ist:

(I)



1) Entschützen von Verbindung (10) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (11),

(II)



1) Entschützen von Verbindung (20) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (22), wobei diese Reaktion Reaktionsweg 1 folgt, wenn R^{14} Alkyl, Cycloalkyl, Benzyl, substituiertes Benzyl, Allyl oder Propargyl ist, oder

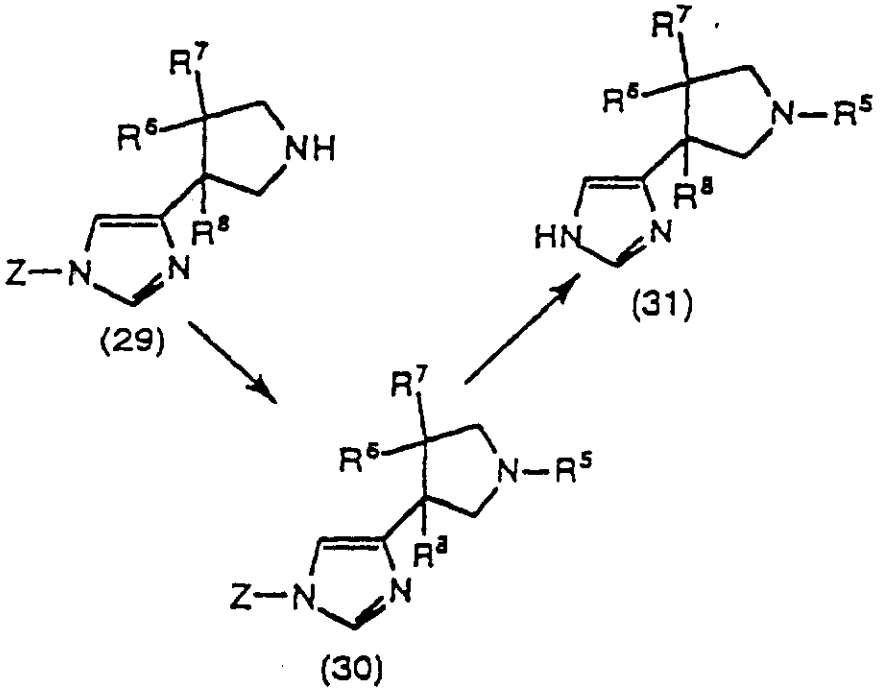
2)

(a) Behandeln von Verbindung (20), wenn R^{14} $-Si(CH_3)_2C(CH_3)_3$ ist, mit Tetrabutylammoniumfluorid in Tetrahydrofuran bei einer Temperatur von 0 bis 50°C unter Herstellen von Verbindung (21) oder Behandeln von Verbindung (20), wenn R^{14} -C(O)O(t-Butyl) ist, mit verdünnter wäßriger Säure unter Herstellen von Verbindung (21),

(b) Umsetzen von Verbindung (21) mit (i) R^5-X, wenn R^5 $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3(CN)$ in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine $-CH_2$-Gruppe weniger besitzt ,und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C durchgeführt wird, und

(c) Entschützen der in 2) (b) hergestellten Verbindung durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (22),

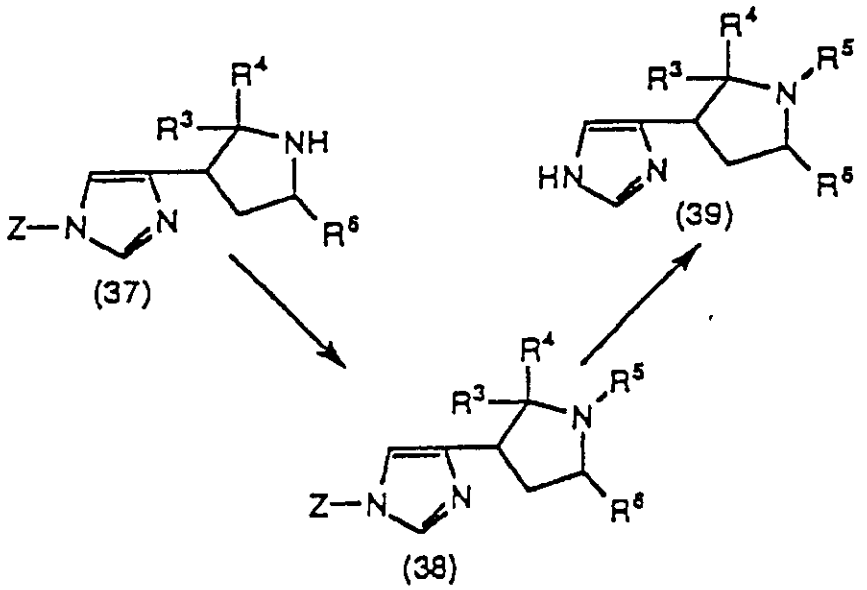
(III)



1) Umsetzen von Verbindung (29) mit (i) R^5-X, wenn R^5 -C(O)R^{10}, -C(O)$OR^{10'}$, -C(O)$NR^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3(CN)$ in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine -CH_2-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C unter Herstellen von Verbindung (30) durchgeführt wird, und

2) Entschützen von Verbindung (30) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (31),

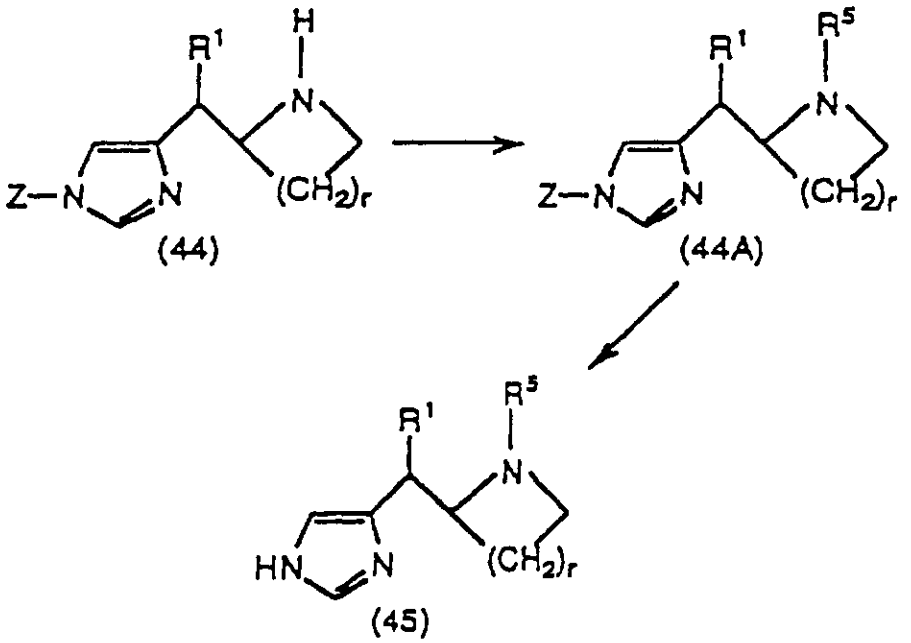
(IV)



1) Umsetzen von Verbindung (37) mit (i) R^5-X, wenn R^5 -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3(CN)$ in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine -CH_2-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C unter Herstellen von Verbindung (38) durchgeführt wird, und

2) Entschützen von Verbindung (38) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 100°C unter Herstellen von Verbindung (39),

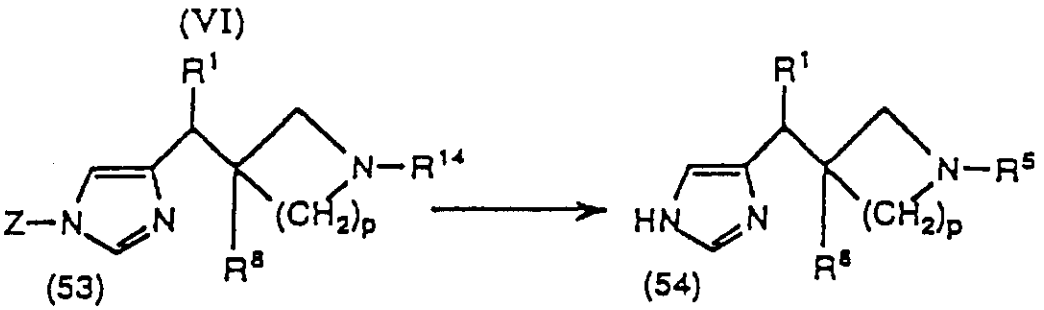
(V)



1) Umsetzen von Verbindung (44), worin r'1 oder 2 ist, mit (i) R^5-X, wenn R^5 -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3$(-CN) in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine -CH_2-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C unter Herstellen von Verbindung (44A) durchgeführt wird, und

2) Entschützen von Verbindung (44A) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (45),

(VI)



1) Entschützen von Verbindung (53), worin p 1 oder 2 ist, durch Behandlung mit verdünnter wäßriger Säure

bei einer Temperatur von 25 bis 90 C unter Herstellen von Verbindung (54), wobei die Reaktion angewendet wird, wenn R^{14} Alkyl, Cycloalkyl, Benzyl, substituiertes Benzyl, Allyl oder Propargyl ist, oder

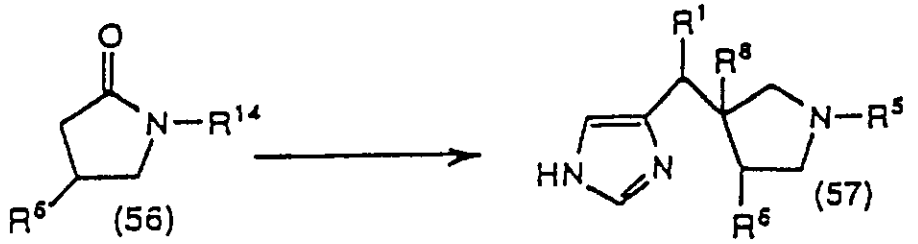
2)

(a) Behandeln von Verbindung (53), wenn R^{14} $-Si(CH_3)_2C(CH_3)_3$ ist, mit Tetrabutylammoniumfluorid in Tetrahydrofuran bei einer Temperatur von 0 bis 50°C oder Behandeln von Verbindung (53), wenn R^{14} -C(O)O(t-Butyl) ist, mit verdünnter wäßriger Säure,

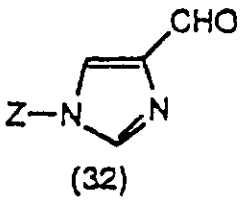
(b) Umsetzen der in 2) (a) hergestellten Verbindung mit (i) R^5-X, wenn R^5 $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3$-(CN) in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine $-CH_2$-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C durchgeführt wird, und

(c) Entschützen der in 2) (b) hergestellten Verbindung durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (54),

(VII)



1) Herstellen des Anions von Verbindung (56) durch Umsetzen von Verbindung (56) mit einer geeigneten Base bei einer Temperatur von -20 bis 20°C und Umsetzen des Anions mit Verbindung (32)



(32)

in einem organischen Lösungsmittel bei einer Temperatur von -78 bis 25°C,

2) Umsetzen des Produkts von 1) mit R^1-Q, worin Q Li oder MgBr ist, in einem geeigneten, CuCN und eine Lewissäure enthaltenden Lösungsmittel, wobei die Reaktion bei einer Temperatur von -78 bis 20°C ausgeführt wird,

3) Umsetzen des Enolats des Produkts von 2) mit R^8-L, worin L eine geeignete Abgangsgruppe darstellt, in einem organischen Lösungsmittel, wobei die Reaktion bei einer Temperatur von 0 bis 50°C ausgeführt wird,

4) Reduzieren der sich daraus ergebenden, durch R^8 substituierten Verbindung aus 3) mit $LiAlH_4$ bei einer Temperatur von 25 bis 65°C in einem organischen Lösungsmittel,

5) Entschützen des Reaktionsprodukts von 4) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (57), wobei die Reaktion angewendet wird, wenn R^{14} Alkyl, Cycloalkyl, Benzyl, substituiertes Benzyl, Allyl oder Propargyl ist, oder

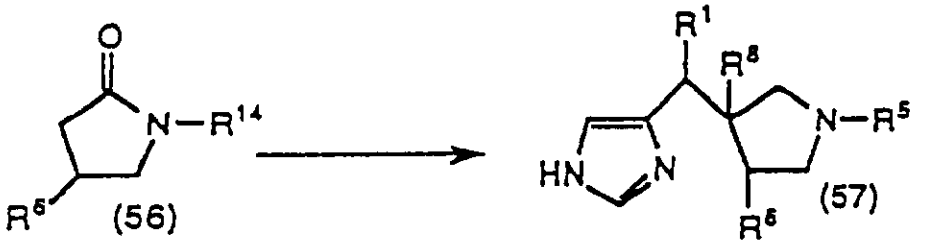
6)

(a) Behandeln des Reaktionsprodukts von 4), wenn R^{14} -Si(C-H_3)$_2$C(CH_3)$_3$ ist, mit Tetrabutylammoniumfluorid in Tetrahydrofuran bei einer Temperatur von 0 bis 50°C oder Behandeln des Reaktionsprodukts von 4), wenn R^{14} -C(O)O(t-Butyl) ist, mit verdünnter wäßriger Säure,

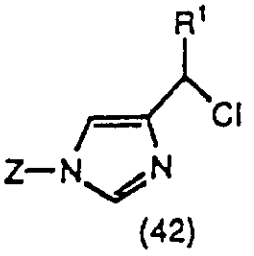
(b) Umsetzen der in 6) (a) hergestellten Verbindung mit (i) R^5-X, wenn R^5 -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3$(-CN) in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine -CH_2-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C durchgeführt wird, und

(c) Entschützen der in 6) (b) hergestellten Verbindung durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (57),

(VIII)



1) Herstellen des Anions von Verbindung (56) durch Umsetzen von Verbindung (56) mit einer geeigneten Base bei einer Temperatur von -20 bis 20°C und Umsetzen des Anions mit Verbindung 42



in einem geeigneten Lösungsmittel bei einer Temperatur von -78 bis 25°C,

2) Umsetzen des Enolats des Produkts von 1) mit R^8-L, worin L eine geeignete Abgangsgruppe darstellt, in einem organischen Lösungsmittel, wobei die Reaktion bei einer Temperatur von 0 bis 50°C ausgeführt wird,

3) Reduzieren der sich daraus ergebenden, durch R^8 substituierten Verbindung aus 2) mit $LiAlH_4$ bei einer Temperatur von 25 bis 65°C in einem organischen Lösungsmittel,

4) Entschützen des Reaktionsprodukts von 3) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (57), wobei die Reaktion angewendet wird, wenn R^{14} Alkyl, Cycloalkyl, Benzyl, substituiertes Benzyl, Allyl oder Propargyl ist, oder

5)

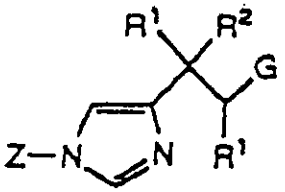
(a) Behandeln des Reaktionsprodukts von 3), wenn R^{14} -Si(C-H_3)$_2$C(CH_3)$_3$ ist, mit Tetrabutylammoniumfluorid in Tetrahydrofuran bei einer Temperatur von 0 bis 50°C oder Behandeln des Reaktionsprodukts von 3), wenn R^{14} -C(O)O(t-Butyl) ist, mit verdünnter wäßriger Säure,

(b) Umsetzen der in 5) (a) hergestellten Verbindung mit (i) R^5-X, wenn R^5 -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeig-

neten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3(-CN)$ in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine -CH_2-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C durchgeführt wird, und

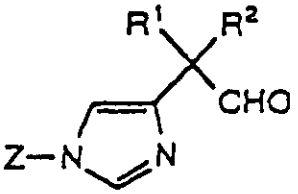
(c) Entschützen der in 5) (b) hergestellten Verbindung durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (57),

(IX) Verwenden von Verbindung (58)



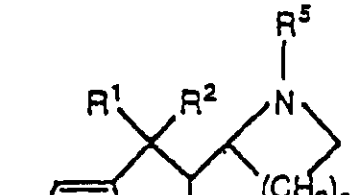
(58)

anstelle von Verbindung (42) und von Verbindung (59)



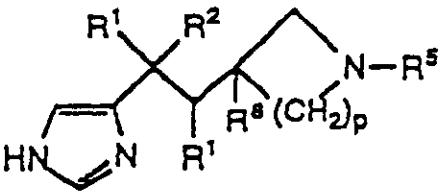
(59)

anstelle von Verbindung (32) unter Herstellen von Verbindung (60)



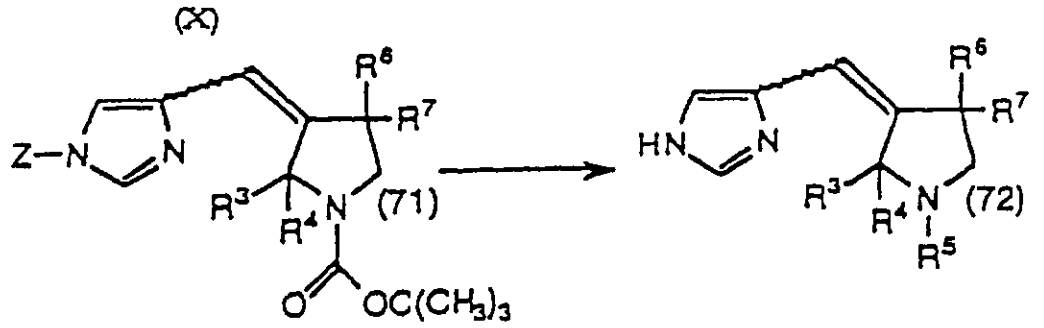
(60)

nach den Schritten in (V) vorstehend oder unter Herstellen von Verbindung (61)



(61)

nach den Schritten in (VI) vorstehend, worin in Verbindung (60) r 1 oder 2 ist und in Verbindung (61) p 1 oder 2 ist und worin G in Verbindung (58) eine geeignete Abgangsgruppe darstellt,



1) Behandeln von Verbindung (71) mit Säure in einem inerten organischen Lösungsmittel bei einer Temperatur von 0°C unter Bewirken des selektiven Entschützens des Pyrrolidinrings,

2) Umsetzen des Reaktionsprodukts von 1) mit (i) R^5-X, wenn R^5 -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ oder Alkyl ist, in einem organischen Lösungsmittel gegebenenfalls in Anwesenheit einer geeigneten Base oder (ii) mit R^{5A}-CHO, wenn R^5 Alkyl, Cycloalkyl, Allyl, Propargyl, Benzyl oder substituiertes Benzyl ist, unter Hydrierungsbedingungen oder in Anwesenheit von $NaBH_3(CN)$ in einem organischen Lösungsmittel, wobei R^{5A} eine Gruppe R^5 darstellt, die eine -CH_2-Gruppe weniger besitzt, und X eine geeignete Abgangsgruppe darstellt, wobei die Reaktion (i) oder (ii) bei einer Temperatur im Bereich von -30 bis 80°C durchgeführt wird, und

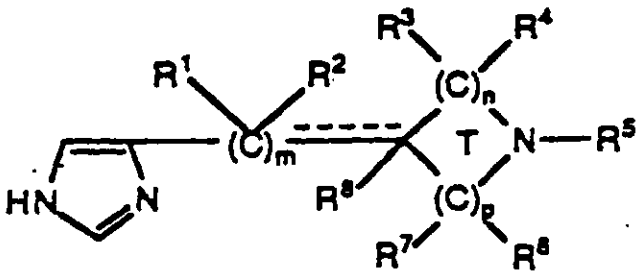
2) Entschützen des Reaktionsprodukts von 2) durch Behandlung mit verdünnter wäßriger Säure bei einer Temperatur von 25 bis 90°C unter Herstellen von Verbindung (72) oder

(XI) Herstellen von Verbindungen von Anspruch 1, worin R^5 H ist, durch Umsetzen einer Zwischenverbindung eines der vorstehenden Verfahrensschritte (I), (II), (III), (IV), (V), (VI), (VII), (VIII), (IX) oder (X) mit wäßriger Säure bei einer Temperatur von 25 bis 100°C, wobei bei der Zwischenverbindung der Imidazolstickstoff durch Z geschützt ist und der Stickstoff des cyclischen vier- oder fünfgliedrigen Amins mit -C(O)O(t-Butyl) substituiert oder unsubstituiert ist.

22. Verwendung einer Verbindung der Formel I gemäß einem der Ansprüche 1-18 bei der Herstellung eines Arzneimittels zur Verwendung als H_3-Rezeptoragonist oder -antagonist.

Revendications

1. Composé de la formule :



(I)

ou un sel ou solvate pharmaceutiquement acceptable, où:

(A) m est un nombre entier sélectionné dans le groupe consistant en : 0, 1, et 2;
(B) n et p sont des nombres entiers et chacun est indépendamment sélectionné dans le groupe consistant en : 0, 1, 2, et 3 de façon que la somme de n et p soit 2 ou 3 de façon que quand la somme de n et p est 2, T soit un cycle à 4 membres et quand la somme de n et p est 3, T soit un cycle à 5 membres;
(C) chacun de R^1, R^2, R^3, R^4, R^6, R^7, et R^8 est indépendamment sélectionné dans le groupe consistant en :

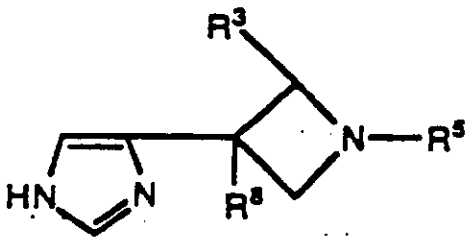
(1) H;
(2) alkyle C_1 à C_6;
(3) cycloalkyle C_3 à C_6; et
(4) $-(CH_2)_q-R^9$ où q est un nombre entier de : 1 à 7, et R^9 est sélectionné dans le groupe consistant en phényle, phényle substitué, $-OR^{10}$, $-C(O)OR^{10}$, $-C(O)R^{10}$, $-OC(O)R^{10}$, $-C(O)NR^{10}R^{11}$, CN et $-SR^{10}$ où R^{10} et R^{11} sont tels que définis ci-dessous et où chacun des substituants sur ledit phényle substitué est indépendamment sélectionné dans le groupe consistant en : -OH, -O-(alkyle C_1 C_6), halogène, alkyle C_1 à C_6, $-CF_3$, -CN, et $-NO_2$, et où lesdits phényles substitués contiennent 1 à 3 substituants;

(D) R^5 est sélectionné dans le groupe consistant en :

(1) H;
(2) alkyle C_1 à C_{20};
(3) cycloalkyle C_3 à C_6;
(4) $-C(O)OR^{10'}$; où $R^{10'}$ est le même que R^{10} défini ci-dessous à l'exception que $R^{10'}$ n'est pas H;
(5) $-C(O)R^{10}$;
(6) $-C(O)NR^{10}R^{11}$;
(7) allyle;
(8) propargyle; et
(9) $-(CH_2)q-R^9$, où q et R^9 sont tels que définis ci-dessus à condition que quand q est 1, R^9 ne soit pas -OH ni -SH;

(E) chacun de R^{10} et R^{11} est indépendamment sélectionné dans le groupe consistant en : H, alkyle C_1 à C_6, et cycloalkyle C_3 à C_6; et, pour le substituant $-C(O)NR^{10}R^{11}$, R^{10} et R^{11}, avec l'azote auquel ils sont liés, peuvent former un cycle ayant 5, 6 ou 7 atomes;
(F) la ligne en pointillé (-----) représente une double liaison qui est facultativement présente quand m est 1, et T est un cycle à 5 membres et n n'est pas 0, et p n'est pas 0, et quand ladite double liaison est présente, alors R^2 et R^8 sont absents;
(G) quand m est 2, chaque R^1 est un substituant identique ou différent pour chaque m, et chaque R^2 est un substituant identique ou différent pour chaque m;
(H) quand n est 2 ou 3, chaque R^3 est un substituant identique ou différent pour chaque n, et chaque R^4 est un substituant identique ou différent pour chaque n; et
(I) quand p est 2 ou 3, chaque R^6 est un substituant identique ou différent pour chaque p, et chaque R^7 est un substituant identique ou différent pour chaque p.

2. Composé de la revendication 1 où ledit composé est sélectionné dans le groupe consistant en composés ayant pour formule :



(II-1)

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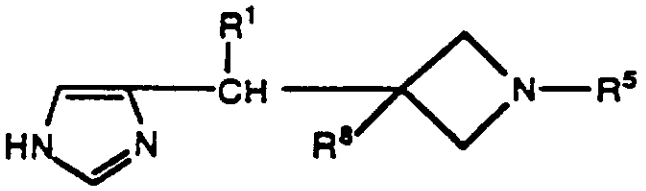

(II-2)

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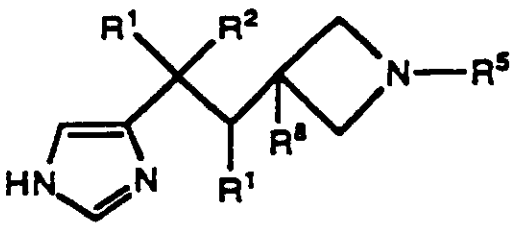

(II-3)

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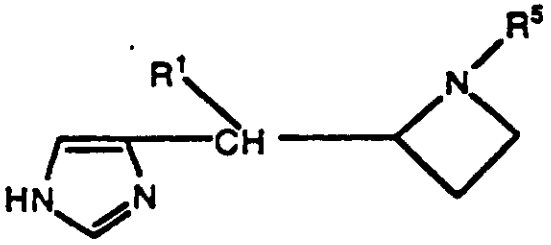
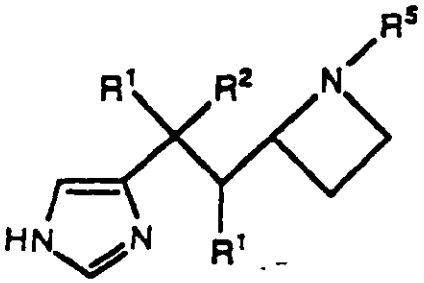


(IIA-1)

;

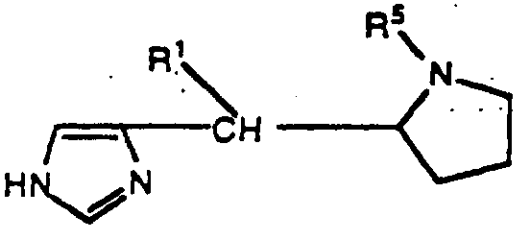
et



(IIA-2)

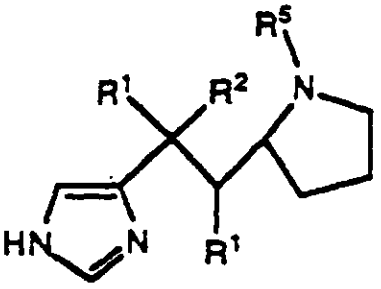
où R^1, R^2, R^3, R^5, et R^8 sont tels que définis pour la Formule I;

3. Composé de la revendication 1 où ledit composé est sélectionné dans le groupe consistant en composés ayant la formule :



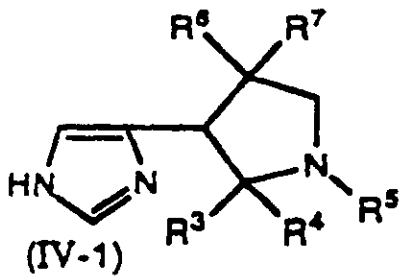
(III-1)

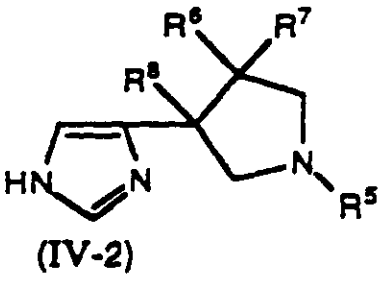
;

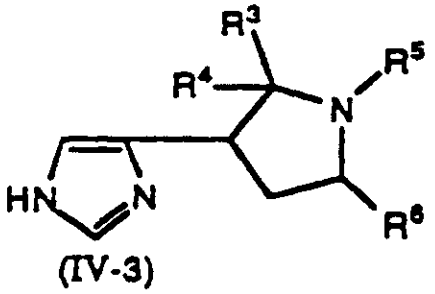


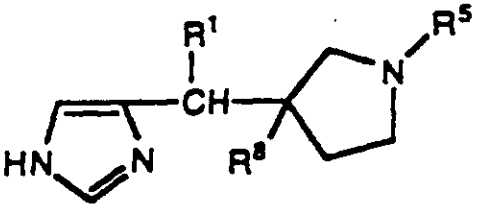
(III-2)

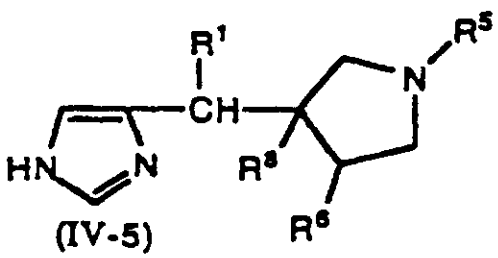
;

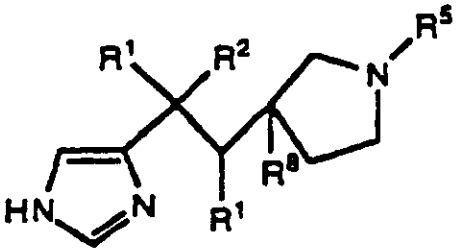

(IV-1) ;


(IV-2) ;

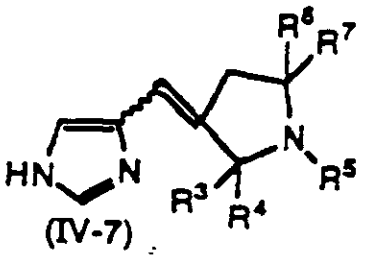

(IV-3) ;


(IV-4) ;


(IV-5) ;


(IV-6) ;

et


(IV-7) .

où R^1, R^2, R^3, R^4, R^5, R^6, R^7, et R^8 sont tels que définis pour la Formule I.

4. Composé de la revendication 1 où m est 0 ou 1.

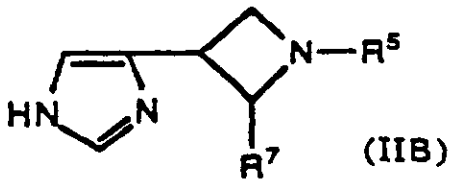
5. Composé de la revendication 4 où R^5 est sélectionné dans le groupe consistant en H, alkyle C_1 à C_{20} et $(CH_2)_q$-R^9 où R^9 est phényle.

6. Composé de la revendication 5 où R^1 à R^4 et R^6 à R^8 sont indépendamment sélectionnés dans le groupe consistant en H, alkyle C_1 à C_6, et -$(CH_2)_q$-R^9 où R^9 est phényle.

7. Composé de la revendication 6 où chaque R^1 à R^4 et R^6 à R^8 sont indépendamment sélectionnés dans le groupe consistant en H, méthyle, éthyle, pentyle, benzyle, et 2-phényléthyle.

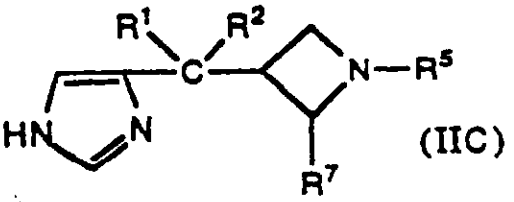
8. Composé de la revendication 7 où R^5 est H ou méthyle.

9. Composé de la revendication 1 ayant la formule sélectionnée dans le groupe consistant en :



(IIB)

et

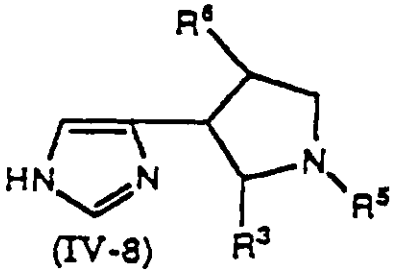


(IIC)

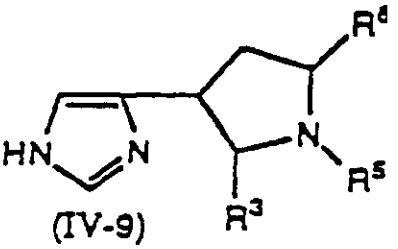
où R^7 est sélectionné dans le groupe consistant en H, alkyle C_1 à C_6 et $-(CH_2)_q-R^9$ où R^9 est phényle.

10. Composé de la revendication 9 où R^7 est alkyle C_1 à C_6, R^1 est H, et R^2 est H.

11. Composé de la revendication 1 ayant la formule sélectionnée dans le groupe consistant en :

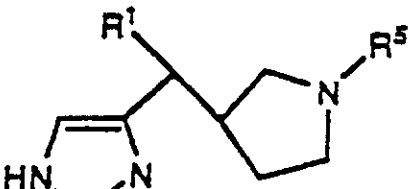


(IV-8)



(IV-9)

et



(IV-10)

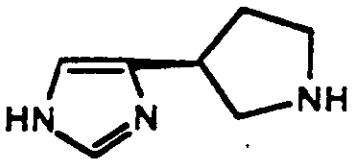
où R^5 est tel que défini à la revendication 1 et chacun de R^1, R^3 et R^6 est indépendamment sélectionné dans le groupe consistant en H, alkyle C_1 à C_6 et-(CH_2)q-R^9 où R^9 est phényle.

12. Composé de la revendication 11 où R^5 est sélectionné dans le groupe consistant en H et méthyle.

13. Composé de la revendication 12 où R^1 est H.

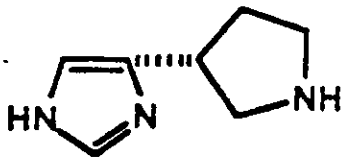
14. Composé de la revendication 1 où ledit composé est sélectionné dans le groupe consistant en :

(A1)



;

(A2)



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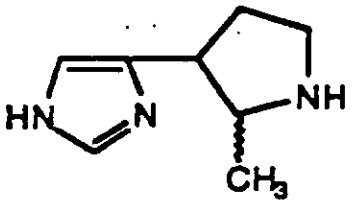
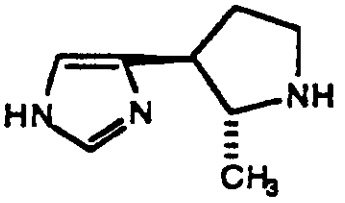
(B)



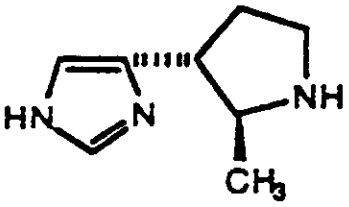
;

(B1)



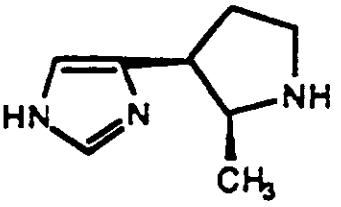
;

(B2)



;

(B3)



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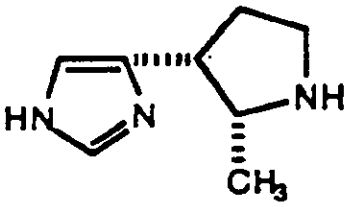
(B4)



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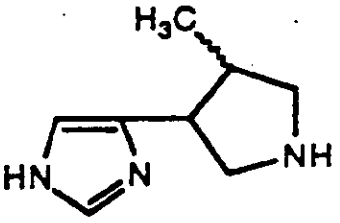
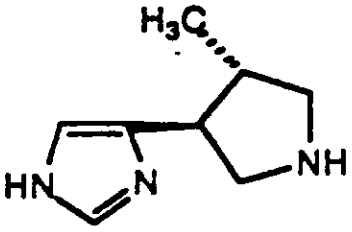
(C)



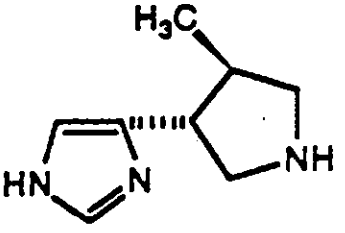
;

(C1)



;

(C2)



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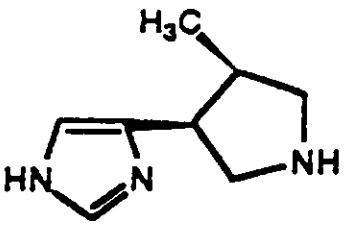
(C3)



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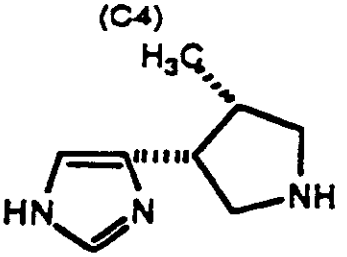
(C4)



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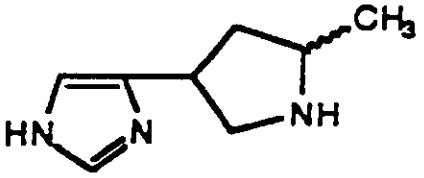
(D)



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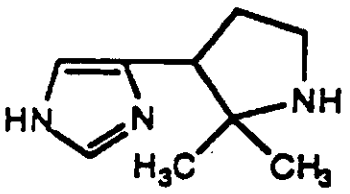
(E)



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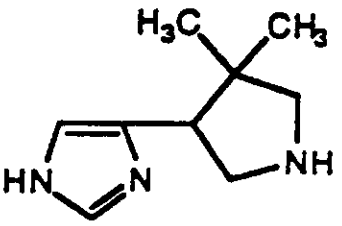
(F)



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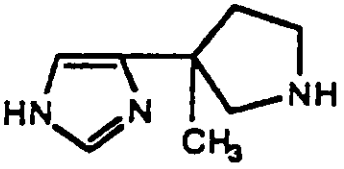
(G)



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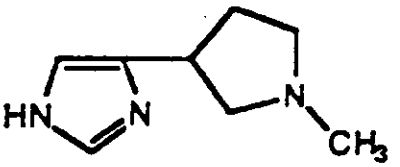
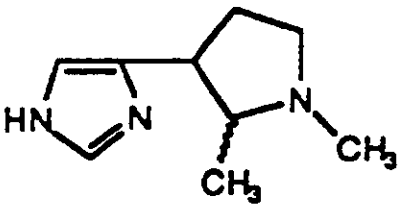
(H)



;

(I)



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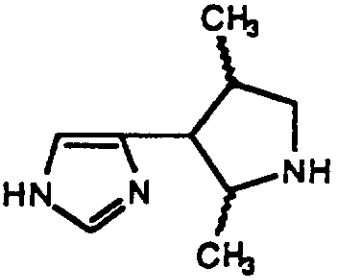
(J)



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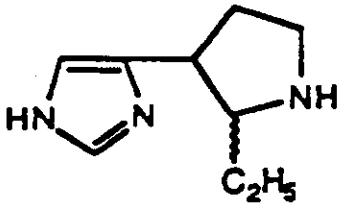
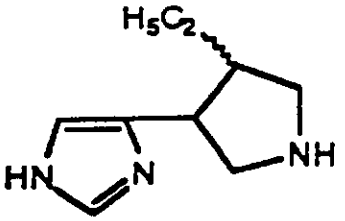
(K)



;

(L)



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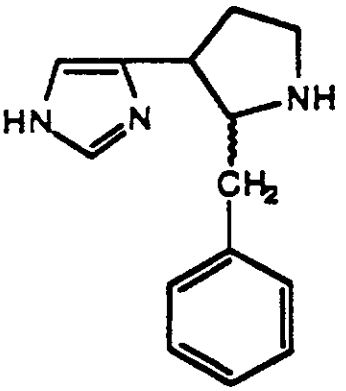
(M)



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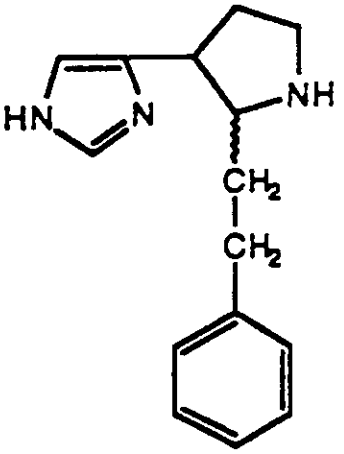
(N)



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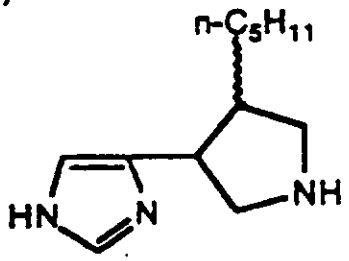
(O)



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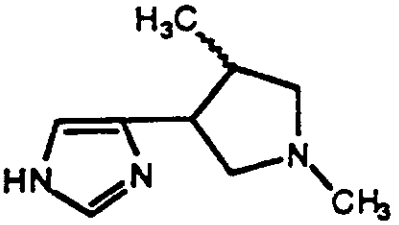
(P)



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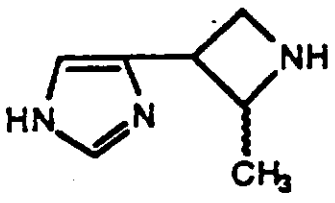
(Q)



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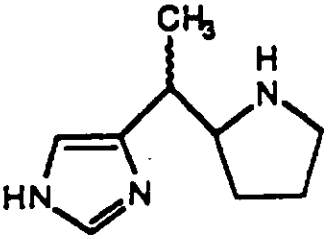
(R)



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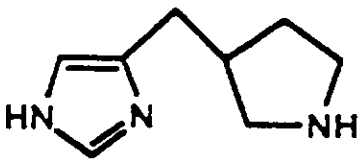
(S)



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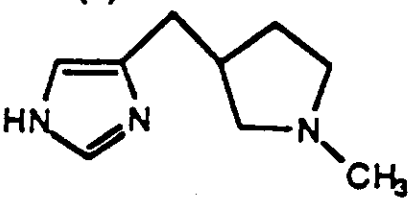
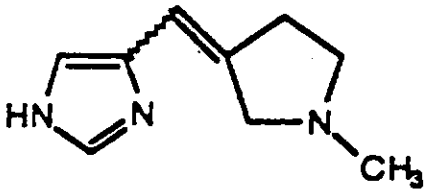
(T)



;

(U)



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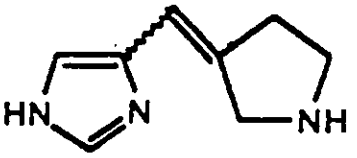
(V)



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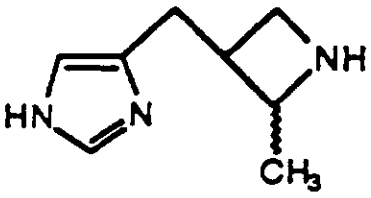
(W)



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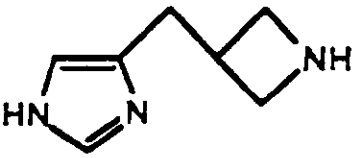
(X)



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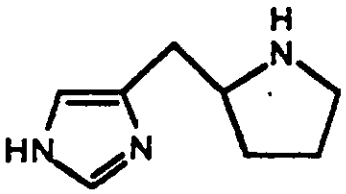
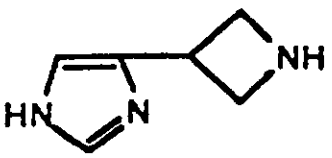
(Y)



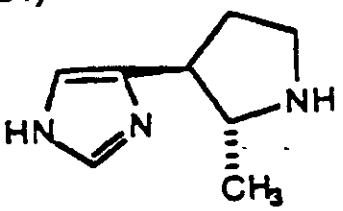
; et

(Z)



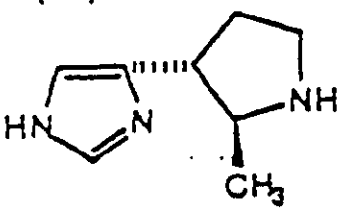
15. Composé de la revendication 14 ayant pour formule :

(B1)



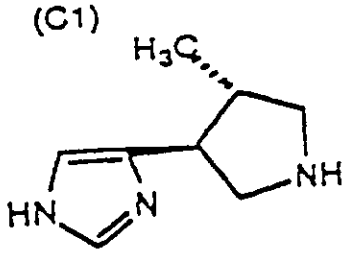
16. Composé de la revendication 14 ayant pour formule :

(B2)



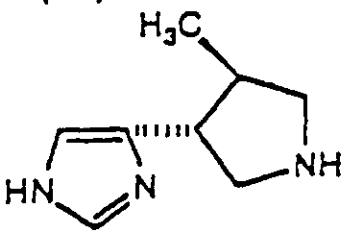
17. Composé de la revendication 14 ayant pour formule :

(C1)



18. Composé de la revendication 14 ayant pour formule

(C2)

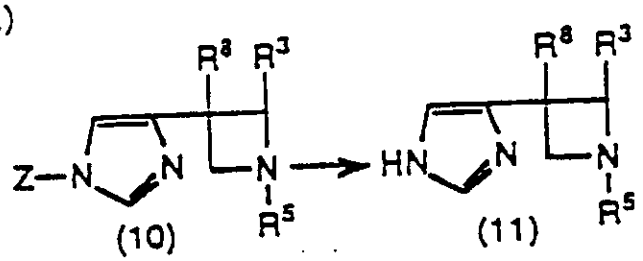


19. Composition pharmaceutique, à utiliser comme agoniste du récepteur de H_3 ou antagoniste comprenant un support pharmaceutiquement acceptable et une quantité efficace d'un Composé de la revendication 1.

20. Méthode de préparation d'une composition pharmaceutique consistant à mélanger un composé de la revendication 1 avec son support pharmaceutiquement acceptable.

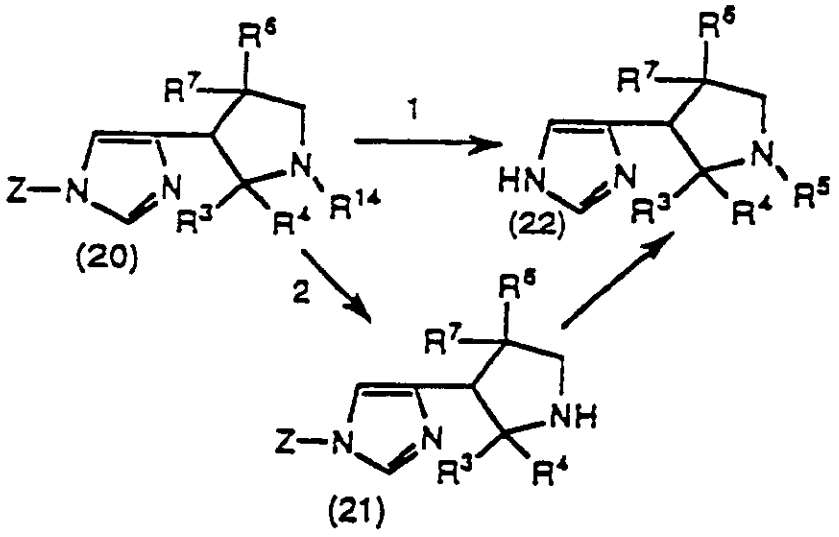
21. Procédé de préparation d'un composé de la revendication 1 de la formule indiquée, comprenant un processus sélectionné parmi les Processus (I) à (IX) qui suivent :

(I)



1) suppression de la protection du composé (10) par traitement avec un acide aqueux dilué à une température de 25 à 90°C, pour produire le composé (11);

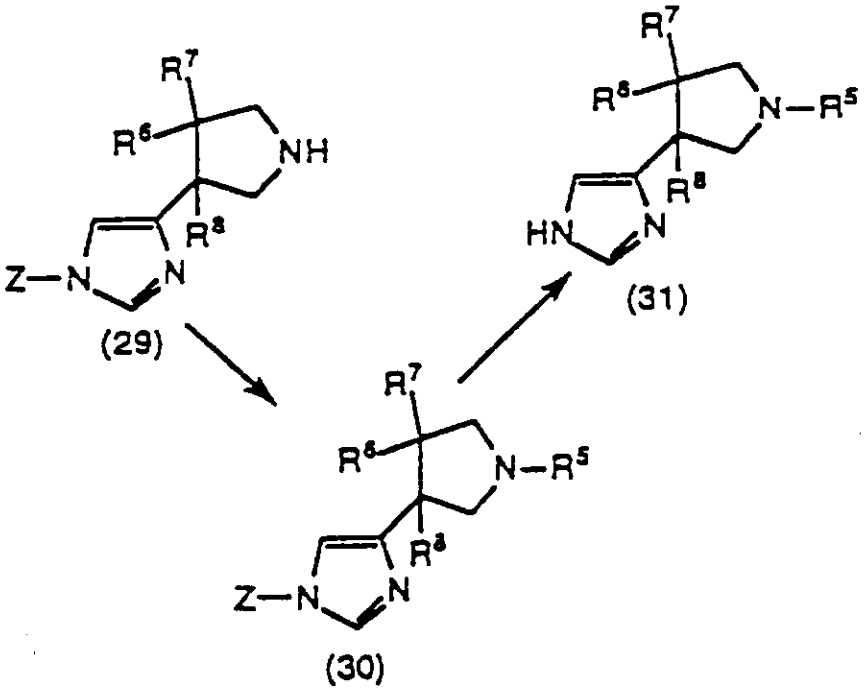
(II)



1) suppression de la protection du composé (20) par traitement avec un acide aqueux dilué, à une température de 25 à 90°C, pour produire le composé (22), ladite réaction suivant le trajet réactionnel 1 quand R^{14} est alkyle, cycloalkyle, benzyle, benzyle substitué, allyle ou propargyle; ou
2)

(a) traitement du composé (20), quand R^{14} est $-Si(CH_3)_2C(CH_3)_3$, avec du fluorure de tétrabutylammonium dans le tétrahydrofuranne à une température de 0 à 50°C pour produire le composé (21); ou le traitement du composé (20), quand R^{14} est -C(O)O(t-butyl), avec un acide aqueux dilué pour produire le composé (21);
(b) réaction du composé (21) avec (i) R^5-X, où R^5 est $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ ou alkyle dans un solvant organique facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe $-CH_2-$ de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C; et
(c) suppression de la protection du composé produit en 2)(b) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (22);

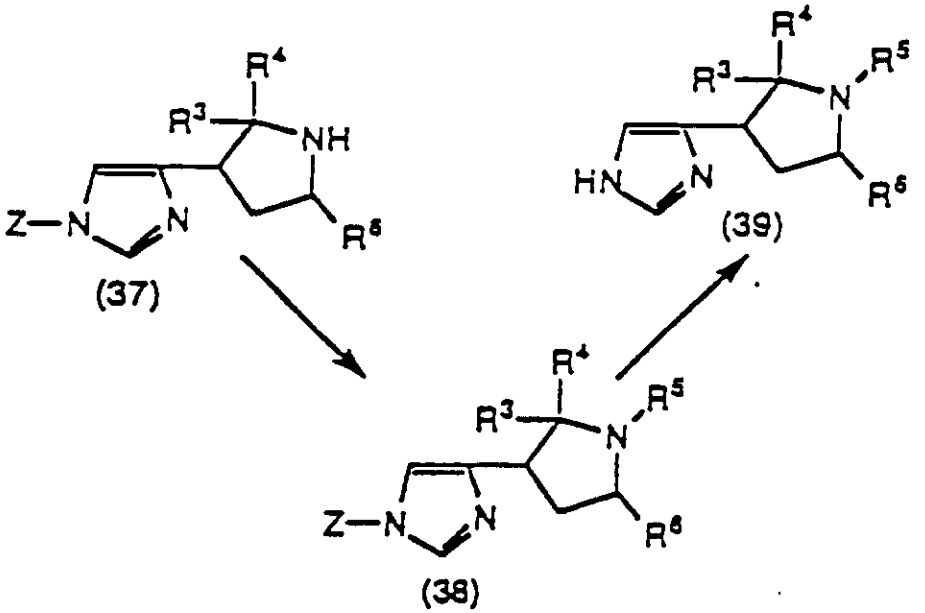
(III)



1) réaction du composé (29) avec (i)R5-X, quand R^5 est -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ ou alkyle dans un solvant organique, facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$ dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe -CH_2- de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C, pour produire le composé (30); et

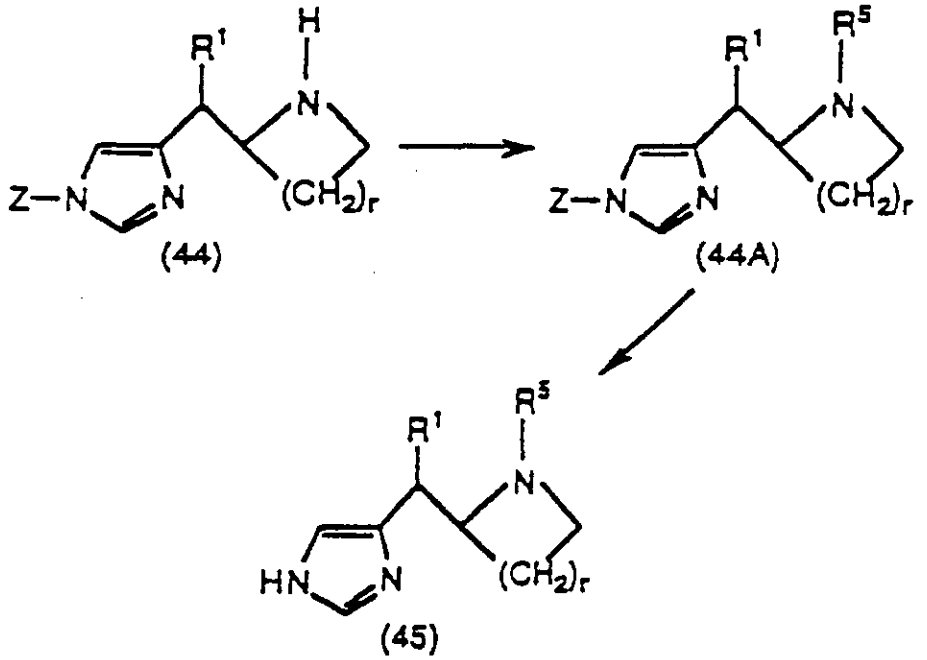
2) suppression de la protection du composé (30) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (31);

(IV)



1) réaction du composé (37) avec (i) R^5-X, quand R^5 est -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ ou alkyle dans un solvant organique, facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe -CH_2- de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C, pour produire le composé (38); et
2) suppression de la protection du composé (38) par traitement avec un acide aqueux dilué à une température de 25 à 100°C pour donner le composé (39);

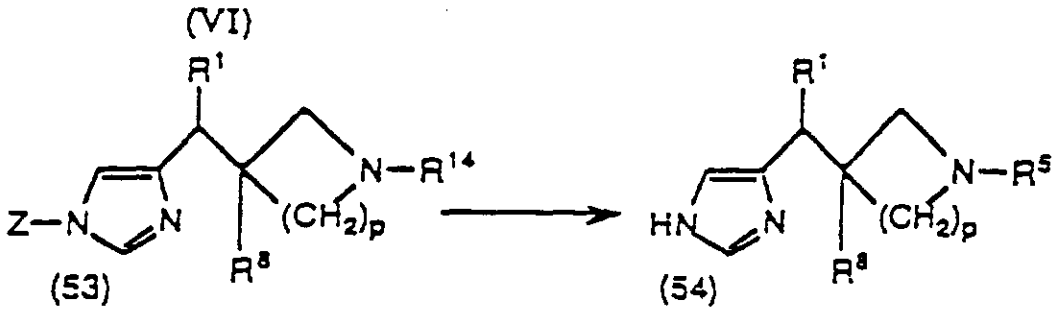
(V)



(44) (44A) (45)

1) réaction du composé (44), où r est 1 ou 2, avec (i) R^5-X, quand R^5 est -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ ou alkyle, dans un solvant organique facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH^3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe -CH_2- de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C, pour produire le composé (44A); et
2) suppression de la protection du composé (44A) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (45);

(VI)

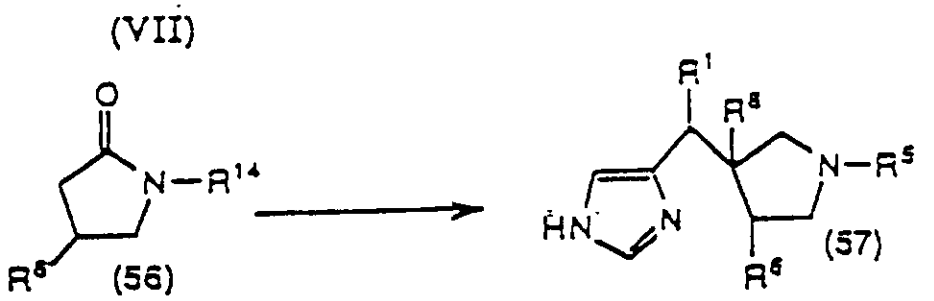


(53) (54)

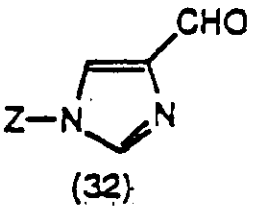
1) suppression de la protection du composé (53), où p est 1 ou 2, par traitement avec un acide aqueux dilué, à une température de 25 à 90°C, pour produire le composé (54), ladite réaction étant utilisée quand R^{14} est alkyle, cycloalkyle, benzyle, benzyle substitué, allyle ou propargyle; ou

2)

(a) traitement du composé (53), quand R^{14} est $-Si(CH_3)_2C(CH_3)_3$, avec du fluorure de tétrabutylammonium dans le tétrahydrofuranne à une température de 0 à 50°C; ou traitement du composé (53), quand R^{14} est -C(O)O(t-butyl), avec un acide aqueux dilué;
(b) réaction du composé produit en 2)(a) avec (i) R^5-X, quand R^5 est $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ ou alkyle dans un solvant organique facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe $-CH_2-$ de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C; et
(c) suppression de la protection du composé produit en 2)(b) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (54);



1) préparation de l'anion du composé (56) par réaction du composé (56) avec une base appropriée à une température de -20 à 20°C et réaction dudit anion avec le composé (32)

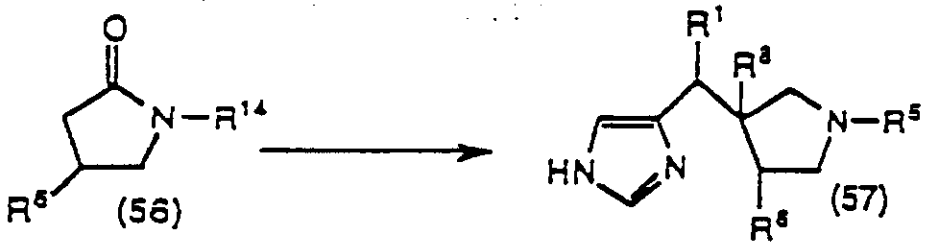


(32)

dans un solvant organique à une température de -78 à 25°C;
2) réaction du produit de 1) avec R^1-Q, où Q est Li ou MgBr, dans un solvant approprié contenant CuCN et un acide de Lewis, ladite réaction est entreprise à une température de -78 à 20°C;
3) réaction de l'énolate du produit de 2) avec R^8-L, où L représente un groupe partant approprié, dans un solvant organique, ladite réaction est entreprise à une température de 0 à 50°C;
4) réduction du composé R^8 substitué résultant de 3) avec $LiAlH_4$ à une température de 25 à 65°C dans un solvant organique;
5) suppression de la protection du produit réactionnel de 4) par traitement avec un acide aqueux dilué, à une température de 25 à 90°C, pour produire le composé (57), ladite réaction étant utilisée quand R^{14} est alkyle, cycloalkyle, benzyle, benzyle substitué, allyle ou propargyle; ou
6)

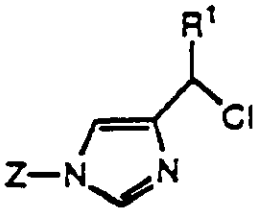
(a) traitement du produit réactionnel de (4), quand R^{14} est $-Si(CH_3)_2C(CH_3)_3$, avec du fluorure de tétrabutylammonium dans le tétrahydrofuranne à une température de 0 à 50°C; ou bien traitement du produit de la réaction de 4), quand R^{14} est -C(O)O(t-butyl), avec un acide aqueux dilué;
b) réaction du composé produit en 6)(a) avec (i) R^5-X, quand R^5 est $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ ou alkyle dans un solvant organique facultativement en présence d'une base appropriée; ou bien (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe $-CH_2-$ de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C; et
c) suppression de la protection du composé produit en 6)(b) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (57);

(VIII)



(56) (57)

1) préparation de l'anion du composé (56) par réaction du composé (56) avec une base appropriée à une température de -20 à 20°C, et réaction dudit anion avec le composé 42



(42)

dans un solvant approprié à une température de -78 à 25°C.

2) réaction de l'énolate du produit de 1) avec R^8-L, où L représente un groupe partant approprié, dans un solvant organique, ladite réaction est entreprise à une température de 0 à 50°C;

3) réduction du composé R^8 substitué résultant de 2) avec $LiAlH_4$ à une température de 25 à 65°C dans un solvant organique;

4) suppression de la protection du produit réactionnel de 3) par traitement avec un acide aqueux dilué à une température de 25 à 90°C, pour produire le composé (57), ladite réaction étant utilisée quand R^{14} est alkyle, cycloalkyle, benzyle, benzyle substitué, allyle ou propargyle; ou

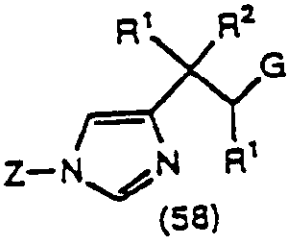
5)

(a)traitement du produit réactionnel de 3), quand R^{14} est $-Si(CH_3)_2C(CH_3)_3$, avec du fluorure de tétrabutylammonium dans le tétrahydrofuranne à une température de 0 à 50°C; ou bien traitement du produit réactionnel de 3), quand R^{14} est -C(O)O(t-butyl), avec un acide aqueux dilué;

(b) réaction du composé produit en 5)(a) avec (i) R^5-X, quand R^5 est $-C(O)R^{10}$, $-C(O)OR^{10'}$, $-C(O)NR^{10}R^{11}$ ou alkyle dans un solvant organique, facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe $-CH_2-$ de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C; et

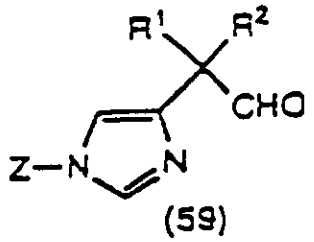
(c) suppression de la protection du composé produit en 5)(b) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (57);

(IX) utilisation du composé (58) :



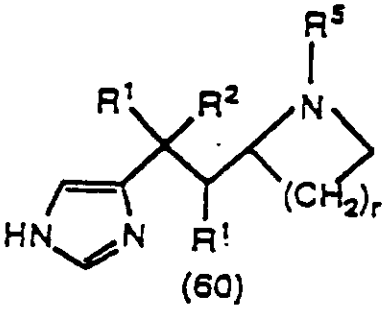
(58)

à la place du composé (42) et du composé (59) :



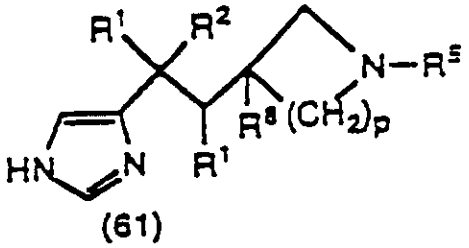
(59)

à la place du composé (32) pour produire le composé (60) :



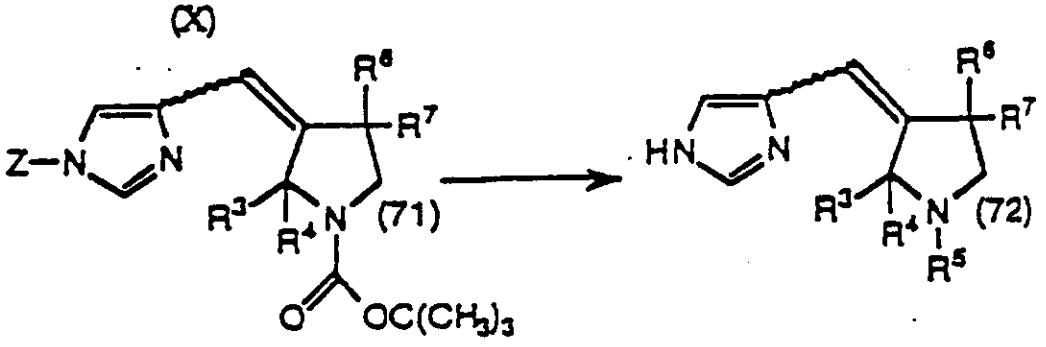
(60)

en suivant les étapes en (V) ci-dessus, ou pour produire le composé (61)



(61)

en suivant les étapes en (VI) ci-dessus, où pour le composé (60), r est 1 ou 2 et pour le composé (61), p est 1 ou 2, et où G dans le composé (58) représente un groupe partant approprié;



1) traitement du composé (71) avec un acide dans un solvant organique inerte à une température de 0°C pour provoquer la suppression sélective de la protection du cycle de pyrrolidine;
2) réaction du produit réactionnel de 1) avec (i)R^5-X, quand R^5 est -C(O)R^{10}, -C(O)O$R^{10'}$, -C(O)N$R^{10}R^{11}$ ou alkyle dans un solvant organique, facultativement en présence d'une base appropriée; ou (ii) avec R^{5A}-CHO, quand R^5 est alkyle, cycloalkyle, allyle, propargyle, benzyle ou benzyle substitué, en conditions d'hydrogénation, ou en présence de $NaBH_3(CN)$, dans un solvant organique; où R^{5A} représente un groupe R^5 qui a un groupe -CH_2- de moins et X représente un groupe partant approprié; ladite réaction (i) ou (ii) étant accomplie à une température entre -30 et 80°C; et
2) suppression de la protection du produit réactionnel de 2) par traitement avec un acide aqueux dilué à une température de 25 à 90°C pour produire le composé (72); ou

(XI) Préparation des composés de la revendication 1, où R^5 est H, par réaction d'un composé intermédiaire

de l'une des étapes de procédé ci-dessus (I), (II), (III), (IV), (V), (VI), (VII), (VIII), (IX), ou (X), avec un acide aqueux, à une température de 25 à 100°C, ledit composé intermédiaire ayant l'azote de l'imidazole protégé par Z et ayant l'azote de l'amine cyclique à quatre ou cinq membres substitué par - C(O)O(t-butyl) ou non substitué.

22. Utilisation d'un composé de formule I selon l'une quelconque des revendications 1 à 18 dans la fabrication d'un médicament pour une utilisation comme agoniste du récepteur de H_3 ou antagoniste.

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European Application No EP93901329.8 filing date 17.12.1992

Priority claimed:
18.12.1991 in United States of America - doc: 809781

PCT EUROPEAN PHASE
PCT Application PCT/US92/10743 Publication No WO93/12108 on 24.06.1993

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Title IMIDAZOLYL OR IMIDAZOYLALKYL SUBSTITUTED WITH A FOUR OR FIVE MEMBERED NITROGEN CONTAINING HETEROCYCLIC RING.

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22.03.1996 MATHYS & SQUIRE, 100 Grays Inn Road, LONDON, WC1X 8AL, United Kingdom [ADP No. 00001081001]
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Entry Type 8.11 Staff ID. LW1 Auth ID. AA

12.07.1996 Notification from EPO of change of EPO Representative details from
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